FOREWORD

An analytical and experimental research program on plasma core reactor technology was conducted by United Technologies Research Center (UTRC) under Contract NAS1-13291 with the National Aeronautics and Space Administration (NASA) Langley Research Center. The Technical Monitor of the Contract for NASA during the Contract period was Dr. F. Hohl. The Technical Program Manager for UTRC during the Contract period was Mr. T. S. Latham. The following three reports comprise the required Final Technical Report under the Contract:


Report R76-912205

Laboratory-Scale Uranium RF Plasma Confinement Experiments

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SUMMARY

An experimental investigation was conducted using the United Technologies Research Center (UTRC) 80 kW and 1.2 MW rf induction heater facilities to aid in developing the technology necessary for designing a self-critical fissioning uranium plasma core reactor (PCR). Pure uranium hexafluoride ($\text{UF}_6$) was injected into argon-confined, steady-state, rf-heated plasmas in different uranium plasma confinement tests to investigate the characteristics of plasma core nuclear reactors. The objectives were: (1) to confine as high a density of uranium vapor as possible within the plasma while simultaneously minimizing the uranium compound wall deposition; (2) to develop and test materials and handling techniques suitable for use with high-temperature, high-pressure gaseous $\text{UF}_6$; and (3) to develop complementary diagnostic instrumentation and measurement techniques to characterize the uranium plasma and residue deposited on the test chamber components. One of the diagnostic techniques which was developed was an optical scanning method for uranium plasma emission and absorption (cw single-frequency tunable dye laser system) measurements yielding radial profiles of temperature and uranium atom number density and x-ray absorption methods for measuring the total amount of confined uranium.

In all tests, the plasma was a fluid-mechanically-confined vortex-type contained within a fused-silica cylindrical test chamber. The test chamber peripheral wall was 5.7-cm-1D by 10-cm-long. Exploratory tests were conducted using the 80 kW rf induction heater ($f = 13.56$ MHz) with the test chamber at approximately atmospheric pressure and discharge power levels on the order of 10 kW. Four different test chamber flow configurations were tested to permit selection of the configuration demonstrating the best uranium vapor confinement characteristics and minimum wall coating for subsequent tests at higher power and pressure in the 1.2 MW rf induction heater ($f = 5.4$ MHz) facility.

The test configuration selected for use in the more extensive rf plasma tests using the 1.2 MW rf induction heater employed a radial-inflow vortex, driven by injectors located on only one of the water-cooled endwalls. In addition to exhaust thru-flow ducts located at the center of each endwall, an axial bypass annulus was located near the periphery of the endwall opposite the vortex injectors. A concentric set of water-cooled, fused-silica tubes formed the peripheral wall. The cylindrical test chamber was 5.7-cm-1D by 10-cm-long. This test chamber flow configuration was designed to operate at pressures up to approximately 20 atm and rf
diagnostic levels up to about 100 kW. In the majority of tests, a single UF₆ injector protruded 2.0 cm into the test chamber; the injector was located on the centerline axis within the thru-flow duct of one endwall. UF₆ was supplied to the injector from a heated canister system capable of supplying the gaseous UF₆ at temperatures up to 450 K and pressures up to 20 atm. The rf plasma tests in the 1.2 MW rf induction heater were conducted over a range of test chamber pressures from 1 to 12 atm and rf discharge power levels from about 10 to 85 kW. The UF₆ mass flow rate ranged from 0.01 to 0.21 g/s.

Diagnostic measurements included: plasma physical and electrical characteristics; calorimetric power losses; total radiation intensity and radiation intensity in different wavelength bands; on-axis spectral emission scans between 300-700 nm; side-on absorption measurements using both an argon-ion laser system (λ = 514.51 nm) and a cw single-frequency tunable dye laser system (λ = 591.54 nm); side-on chordal emission and absorption measurements (λ = 591.54 nm) using an optical scanning system; diagonal end-on 8 Kev x-ray absorption measurements; and, analysis and identification of the residue deposited on the test chamber components from selected tests using six different complementary analysis techniques; electron diffraction, x-ray diffraction, scanning electron microprobe, IR spectrophotometer, surface profilometer, and secondary ion mass spectrometer instrumentation.

Uranium compound reference standards were developed at UTRC to permit post-test characterization and identification of the residue coatings deposited on the various components of the test chamber. Modifications made to the test chamber configuration and flow control schemes and evaluation by these analysis techniques resulted in further reduction in the residue material deposited on the components of the test chamber. The whitish "mist-like" residue found on the inside diameter of the fused-silica tubes during post-test analysis was identified to be principally uranyl fluoride (UO₂F₂).

At UF₆ mass flow rates of 2.2 x 10⁻² g/s, test times up to 41.5 minutes were achieved with less than approximately 20 mg of uranium compound residue wall coating (< 0.04% of total UF₆ mass flow). If required, longer test times would be possible subject to additional radiation shielding and cooling modifications to the 1.2-MW rf induction heater test tank and resonator section. The introduction of the UF₆ into the rf plasma resulted in a significant increase in the emitted radiation, particularly in the visible and near-UV wavelength bands. At comparable and greater UF₆ mass flow rates (up to 3.2 x 10⁻² g/s), optical chordal scans of the absorption by and the emission from the uranium rf plasma discharge were successfully conducted. These measurements provided input to a computer program (optically thick case) which calculated the spectral emission and absorption coefficients and the corresponding radial temperature profile using Kirchhoff's law. Uranium plasma centerline temperatures of approximately 9800 K with a distinct off-axis peak (∼ 8700 K occurring at r/R = 0.6) were determined. Edge of plasma temperatures were approximately 6000 K. From these data and additional experimental measurements of the uranium neutral atom
(UI) absorption line width (≈3.5 GHz at λ = 591.5 nm), the radial variation of total uranium atom (UI + UII + UIII) number density within the rf plasma was determined. (Approximately 10^{16} U atoms/cm^3 at the axial midplane centerline of the rf plasma discharge.) To complement these measurements, x-ray absorption measurements were conducted to determine the total amount of uranium confined within the test chamber. Depending on the optical path length chosen, total uranium number density levels up to approximately 4 x 10^{17} atoms/cm^3 were determined. The uranium atom density required to sustain criticality in a typical plasma core reactor is 2 x 10^{19} atoms/cm^3 at an operating pressure of approximately 500 atm. Since the rf plasma tests were run at approximately 2 atm, scaling by pressure alone would indicate that a uranium number density of 8 x 10^{16} atoms/cm^3 in the rf plasma tests would correspond to a uranium vapor partial pressure ratio of the approximate magnitude required for criticality.

In separate tests to maximize the UF_{6} mass injection flow rate, up to an order of magnitude increase in the mass flow rate of UF_{6} was achieved (2.1 x 10^{-1} g/s) while still maintaining the plasma in a confined mode of operation; the corresponding test time was 1.2 minutes.

The overall test results demonstrated applicable flow schemes and associated diagnostic techniques have been developed for the fluid-mechanical confinement and characterization of uranium vapor within an rf plasma discharge when pure UF_{6} is injected under steady-state conditions for long test times into an argon-confined, high-temperature, high-pressure, rf-heated plasma.
RESULTS AND CONCLUSIONS

RF plasma exploratory tests employing the UTRC 80 kW rf induction heater system with pure UF₆ injection yielded the following results:

1. Based on approximately forty tests using four different types of test chamber configurations and flow schemes, an optimum test chamber configuration and flow scheme was identified for use in extended uranium plasma confinement tests employing the UTRC 1.2 MW rf induction heater facility. The test chamber configuration selected was 10-cm-long; the peripheral wall was an externally gas-cooled 5.7-cm-ID x 6.1-cm-OD fused-silica tube. The configuration incorporated endwall-driven vortex injection and a combination of on-axis thru-flow exhaust (both endwalls) and a single annular axial bypass exhaust located in the endwall assembly opposite the vortex injectors.

The above tests were conducted at chamber pressures of 1 atm, rf discharge power levels of approximately 10 kW, argon vortex mass flow rates up to 2 g/s, estimated UF₆ mass flow rates (based on weighing) of hundredths of grams per second, and discharge diameters at the axial midplane of about 5 cm. The discharge power and pressure levels were limited by the safety aspects of the 2-mm-thick gas-cooled fused-silica peripheral wall.

2. With the above configuration and flow scheme, light uranium-compound-coatings on the fused-silica peripheral wall and endwall assemblies accompanied the moderate UF₆ injection flow rate. The rf plasma discharge was relatively well-confined and stable throughout the majority of test conditions. Occasional discharge oscillations were noted (f ≈ 1-5 Hz); the discharge was also susceptible to extinguishment by rapid changes in the flow conditions (particularly injection of UF₆).

3. A UF₆ handling and feeder system previously designed to provide a controlled and steady flow of heated UF₆ at temperatures up to 450 K was modified and adapted for these tests. The system was designed to provide UF₆ mass flow rates up to about 5 g/s and subsequent possible injection of UF₆ into test chambers operating at pressures up to 20 atm. The system was tested (no rf plasma present) at UF₆ flow rates up to 5.8 g/s.

4. A multiple-concentric-tube UF₆ injector assembly was developed which could be located concentrically (at different axial positions) within the test chamber endwall assembly and subsequently provide a steady-state flow of gaseous UF₆ into the rf plasma test chamber. High pressure water (20 atm) heated to approximately 350 K via a steam heat exchanger and flowing at 0.14 l/s between the concentric tubes of the UF₆ injector was required to alleviate possible condensation/solidification in the UF₆ transfer line.
RF plasma tests employing the 1.2 MW rf induction heater system with pure UF₆ injection yielded the following results:

1. Based on the prior 80 kW rf plasma exploratory tests, a new test chamber configuration was fabricated. As in the prior tests, the test chamber was 10-cm-long; the peripheral wall, however, was formed by a concentric set of water-cooled fused-silica tubes. The inner tube was 5.7-cm-ID x 6.1-cm-OD and the outer tube was 6.5-cm-ID x 7.3-cm-OD. This test chamber was designed for steady-state operation at rf plasma power levels up to about 100 kW and chamber pressure levels up to approximately 20 atm. The test chamber incorporated a single endwall driven vortex injection scheme and a combination of on-axis exhaust thru-flow and axial-bypass exhaust on the opposing endwall only. This test chamber was operated over a wide range of test conditions including: chamber pressures 1-12 atm, rf plasma discharge power levels 10-85 kW, argon vortex mass flow rates 1-10 g/s, discharge diameters at the axial midplane from 1.5-3.5 cm, and UF₆ injection mass flow rates from 0.01 to 0.21 g/s.

2. An rf plasma test series was conducted with pure UF₆ injection incorporating additional modifications to the test chamber and flow control scheme which further enhanced, within the operating range tested, the uranium vapor confined within the plasma while simultaneously minimizing the deposition of uranium and/or uranium compounds on the walls of the test chamber. Included were changes to the argon vortex injectors, location and size of the UF₆ injector, rf work coil and operating frequency, and cooling in peripheral wall annulus and endwall assemblies.

3. Supporting diagnostic equipment, instrumentation, and analysis techniques were developed applicable to characterizing the uranium rf plasma experiments. These included:

   (a) A calorimetric technique for determining the total power deposited into the uranium rf plasma;

   (b) A radiometric technique for determining the total radiation emitted from the uranium rf plasma and its distribution within selected wavelength bands;

   (c) A spectral emission measurement technique for comparing the spectral emission characteristics of argon-only and uranium/argon rf plasma discharges over a wavelength range from 300-700 nm;

   (d) Optical scanning equipment and techniques for obtaining side-on chordal scan measurements of the emission from and absorption by uranium rf plasmas. This technique, combined with additional uranium neutral atom absorption line ($\lambda = 591.54$ nm) width measurements using a cw single-frequency tunable dye laser system, permitted estimates of the radial
distribution of the uranium atom (UI + UII + UIII) number density within the rf plasma (approximately $10^{16}$ uranium atoms/cm$^3$ at the axial midplane centerline of the rf plasma discharge);

(e) A modified Abel inversion method for rotationally symmetric, local thermodynamic equilibrium, optically thick ($0.2 \leq t/l_0 \leq 0.8$) plasmas was adapted to the chordal scan measurements to permit determination of the radial profile of the volume emission and absorption coefficients from the chordal emission and absorption measurements. From these and application of Kirchhoff's law, the radial temperature profile within the uranium rf plasma was determined. The uranium plasma centerline temperatures were approximately 9800 K with a distinct off-axis peak of approximately 8700 K occurring at $r/R = 0.6$. The edge of plasma temperatures were approximately 6000 K. The uranium rf plasma temperature conditions determined (6000-10,000 K range) were representative of those expected in future self-critical fissioning uranium plasma core reactor experiments.

(f) An x-ray absorption technique for determining the total uranium mass contained in the rf plasma test chamber was established. This measurement technique supplemented the optical scanning emission and absorption scheme and is applicable within the $3 \times 10^{16}$ to $3 \times 10^{18}$ uranium atoms/cm$^3$ range. Depending on the optical path chosen, total uranium number density levels up to $4 \times 10^{17}$ atoms/cm$^3$ were determined from the measurements.

4. Various complementary diagnostic techniques for identifying and characterizing small (milligram) quantities of residue were integrated into a detailed post-test examination of the individual components comprising the test chamber (i.e., fused-silica tube peripheral wall, endwalls, UF$_6$ injector, on-axis thru-flow exhaust duct, axial bypass exhaust duct). The diagnostic techniques included use of x-ray diffractometer, electron microscope, scanning electron microprobe, IR spectrophotometer, profilometer, and ion scattering spectrometer/secondary ion mass spectrometer instrumentation. A complete catalog of all uranium and/or other compounds possible as residue on the various components was established. These techniques and catalog of compounds aided in minimizing the uranium compound wall deposition, e.g., indicated that silicone grease is unacceptable as a sealant material on the O-rings of the test chamber and the oxygen content of the argon buffer gas supply is high enough to require filtering of the gas supply to reduce one of the sources of oxygen leading to the formation of undesirable uranium oxides on the peripheral wall.

5. A test series was conducted to demonstrate minimum coating of uranium compounds on the peripheral wall of the test chamber after a long sustained operating period. An approximately 50 kW rf plasma with pure UF$_6$ injected, at a mass flow rate of 0.022 g/s, into the test chamber at 2 atm was operated steady-state for 41.5 minutes. After this extended test time (limited only by radiation loading and water cooling to several existing rf induction heater electrical components), 30.4 mg of
residue (primary UO$_2$P$_2$ with a trace of SiO$_2$) was deposited on the fused-silica peripheral wall. This included approximately 10 mg of silicone grease initially deposited on the ends of the fused-silica tube for sealing the O-rings. The residue was located primarily toward the vortex injector end of the fused-silica tube. The residue represented less than 0.04% of the total UF$_6$ mass flow.

6. A test series was conducted to determine the maximum mass flow rate of UF$_6$ that could be injected into the rf plasma (regardless of wall coating) while still maintaining the discharge in a confined, steady-state mode of operation. An approximately 70 kW rf plasma was operated for 1.2 minutes at a chamber pressure of 2 atm; the UF$_6$ mass flow rate was 0.21 g/s (greater than an order of magnitude increase over that of previous tests). Approximately 135 mg of residue (primarily UO$_2$P$_2$ with a trace of UO$_3$ and SiO$_2$) was deposited on the fused-silica peripheral wall primarily near the vortex injector end of the tube. Additional changes to the argon vortex injection system, UF$_6$ injector scheme and O-ring shielding should permit still further increases in the UF$_6$ mass flow rates attainable.

A principal technology required to establish the feasibility of fissioning uranium plasma core reactors is the fluid mechanical confinement of the hot fissioning uranium plasma with sufficient containment to both sustain nuclear criticality and minimize deposition of uranium or uranium compounds on the confinement chamber peripheral walls. The laboratory-scale rf uranium plasma experiments conducted to date have aided in developing some of the long lead time technologies required to proceed with the PCR experiments. Included has been the development of a test chamber and flow control scheme together with the associated diagnostic instrumentation required to determine the density of uranium vapor within the plasma. In a typical PCR, the uranium atom density required to sustain criticality is 2 x 10$^{19}$ atoms/cm$^3$ at an operating pressure of approximately 500 atm; since the rf plasma tests were run at about 2 atm, scaling by pressure alone would indicate that a uranium number density of 8 x 10$^{16}$ atoms/cm$^3$ in the rf uranium plasma tests would correspond to a uranium vapor partial pressure ratio of the approximate magnitude required for criticality.

Throughout the entire test series, valuable experimental data were also accumulated on the corrosion aspects of hot, pressurized UF$_6$. These data will be applicable to future tests, particularly in the initial transfer, handling, filtering, feeding, flow control, flow monitoring, and safety aspects of UF$_6$.

In addition to continued rf uranium plasma confinement tests, future experiments will include the development of techniques for reconstituting the gaseous compounds in the plasma exhaust mixture and separating the UF$_6$ from the buffer gas such that it is in a form suitable for reinjection into the plasma.
INTRODUCTION

Fissioning uranium plasma core reactors (PCR's) based on the utilization of fissile nuclear fuel in the gaseous state could be used as a prime energy source for many space and terrestrial applications. In addition to aerospace propulsion applications, several new space power and/or terrestrial options are being considered; these include:

1. Direct pumping of lasers by fission fragment energy deposition in UF₆ and lasing gas mixtures.
2. Optical pumping of lasers by thermal and/or nonequilibrium electromagnetic radiation from fissioning UF₆ and/or fissioning uranium plasmas.
3. Photochemical or thermochemical processes such as dissociation of hydrogenous materials to produce hydrogen.
4. MHD power conversion systems for generating electricity.
5. Advanced closed-cycle gas turbine driven electrical generators.

Power extraction from the fission process with nuclear fuel in the gaseous state allows operation at much higher temperatures than those of conventional solid core nuclear reactors. Higher operating temperatures result in more efficient thermodynamic cycles and, in the case of fissioning uranium PCR's, result in applications using direct coupling of energy in the form of electromagnetic radiation. The continuous reprocessing of gaseous nuclear fuel also leads to a low steady-state fission product inventory in the reactor and limits the buildup of long half-life transuranium elements.

Reference 1 discusses the overall status of plasma core reactor technology, the various energy conversion concepts, conceptual designs of various configurations, and a summary of all current research directed toward demonstrating the feasibility of fissioning uranium PCR's.

A principal technology required to establish the feasibility of fissioning uranium plasma core reactors is the fluid mechanical confinement of the hot fissioning uranium plasma with sufficient containment to both sustain nuclear criticality and minimize deposition of uranium or uranium compounds on the confinement chamber peripheral walls. Figure 1 is a sketch of one unit cell configuration of a PCR. The reactor would consist of one or more such cells imbedded in beryllium oxide and/or heavy-water moderator and surrounded by a pressure vessel. In the central plasma fuel zone, gaseous uranium (injected in the form of UF₆ or other uranium compound) is confined by argon buffer gas injected tangentially at the
periphery of the cell. In applications in which it is desired to couple thermal radiation from the fissioning uranium plasma to a separate working fluid, the thermal radiation is transmitted through the argon buffer gas layer and subsequently through internally-cooled transparent walls to a working fluid channel such as shown in Fig. 1. The channels would contain particles, graphite fins, or opaque gases to absorb the radiation. The mixture of nuclear fuel and argon buffer gas is withdrawn from one or both endwalls at the axial centerline. For other applications in which it is desired to extract power in the form of nonequilibrium, fission-fragment-induced short wavelength radiation emissions, the transparent wall would be removed and a medium such as lasing gas mixtures would be mixed with either the fissioning uranium fuel or the buffer gas. The reason for this distinction is that most transparent wall materials have intrinsic radiation absorption characteristics at the short wavelengths expected to be emitted from the plasma in the form of fission-fragment-induced nonequilibrium electromagnetic radiation. Typically, for plasma conditions with an edge-of-fuel-region temperature of approximately 5000 K, operating pressures in the fissioning uranium plasma are on the order of 500 atm. This is dependent upon the combined partial pressures of nuclear fuel required for criticality, dissociation products, electrons from ionized species, and some argon buffer gas present in the fuel region.

A long-range program plan for establishing the feasibility of fissioning gaseous UF₆ and uranium plasma reactors has been formulated by NASA. Reference 2 summarizes the plan which comprises the performance of a series of experiments with reflector-moderator cavity reactors. A review of the past work is contained in Ref. 3. Los Alamos Scientific Laboratory (LASL) is currently performing these cavity reactor experiments.

Briefly, the initial reactor experiments currently being assembled at LASL consist of low-power, self-critical cavity reactor configurations employing undisassociated, nonionized UF₆ fuel at near minimum temperatures required to maintain the fuel in gaseous form. Power level, operating temperature, and pressure will be systematically increased in subsequent experiments to approximately 100 kW, 1800 K, and 20 atm, respectively. The final approximately 5 MW reactor experiment will operate with a fissioning uranium plasma at conditions for which the injected UF₆ will be dissociated and ionized in the active core.

Performance of static UF₆ critical experiments is currently in progress (Ref. 4). Key objectives of the initial static UF₆ and subsequent flowing UF₆ reactor experiments are to facilitate (1) research on gaseous cavity reactor physics and on nonequilibrium optical radiation from fissioning UF₆, (2) demonstrations of physical applications of nonequilibrium optical radiation such as lasers, and (3) demonstrations of methods for heat extraction for power generation and propulsion applications. A key objective of the final approximately 5 MW fissioning uranium PCR experiment is to provide a facility for demonstrating feasibility of high-reactor-power applications using very intense photon fluxes such as described above.
PCR technology studies at UTRC currently consist of several experiments and theoretical investigations directed toward evaluating the feasibility of the PCR concept. Extensive non-nuclear vortex flow and plasma fluid mechanical research has been conducted over the past fifteen years at UTRC. Past fluid mechanics (non-plasma) experiments (Ref. 5) have indicated that a radial inflow vortex is well-suited for applications which require the preferential containment of a heavy gas within a light gas created by the radial inflow vortex. A radial-inflow vortex flow pattern is characterized by an essentially laminar radial stagnation surface across which there is no net inward radial buffer gas flow.

Other previously reported experiments (Ref. 6) have been conducted on the confinement of argon rf plasmas. These tests were directed primarily toward development of a high-intensity, high-power-density plasma energy source (equivalent black-body radiating temperatures > 6000 K). Some of these initial exploratory tests included direct injection of very dilute mixtures of UF6 (typically, 1% UF6 in an argon carrier gas) into the argon rf plasma. Coating of the fused-silica peripheral wall occurred but short-time sustained plasma operation was demonstrated. Particle feeder systems were also developed which permitted steady-state injection of carbon (C), tungsten (W), uranium dioxide (UO2), and uranium oxide (U3O8) into test chambers operating at pressures up to 40 atm. In general, these exploratory test results confirmed that simulated fuels could be confined fluid-mechanically with steep concentration gradients at the edge-of-fuel location.

Reference 7 (see also APPENDIX D) summarizes the results of initial exploratory experiments in which pure UF6 was injected for short times into an argon-confined, steady-state, rf-heated plasma to investigate the characteristics of PCR's.

This research report presents some recent results of the uranium plasma confinement tests together with the associated diagnostics and measurement techniques applicable to PCR's. These tests were conducted using pure UF6 injected for long time periods into steady-state, argon-confined, rf-heated plasmas. The UTRC 1.2-MW rf-induction heater facility was employed in these latter tests.
DESCRIPTION OF PRINCIPAL EQUIPMENT

UTRC 1.2 MW RF Induction Heater Facility

Primary Heater Components and Test Tank

The experiments reported herein were conducted using the 1.2 MW rf induction heater system. Figure 2 is a block diagram of the 1.2 MW rf induction heater. The operating frequency was selected by means of an L-C type variable frequency oscillator whose 0.5 W output is amplified to approximately 2 kW using a neutron amplifier. The rf operating frequency normally used was approximately 5.4 MHz. The 2 kW output was used to provide rf excitation for the basic rf induction heater stages which receive dc power from the common saturable-reactor-controlled power supply. The 2 kW excitation drives a 40 kW output amplifier which in turn drives an 80 kW buffer amplifier. This buffer amplifier was the actual driving stage for the final power amplifiers. All these stages contain controls for tuning the matching circuit at the final power amplifier input. This allows individual adjustments to be made to the various amplifier systems, thus aiding in increasing the overall system efficiency. The rf output power was supplied by two power amplifier tubes which drive a resonant tank circuit (resonator section) of unique design. The output of the two power amplifiers was resonated by a push-pull resonator. All stages were operated class "C" to provide maximum efficiency. The saturable-reactor-controlled power supply for the 40 kW, 80 kW, and final power amplifier stages was continuously variable in dc voltage from 2 kV to approximately 2 h kV. This provided flexibility in selecting power levels compatible with the various experimental test requirements.

A photograph of an assembled test configuration installed concentrically within the set of 9-cm-dia water-cooled rf work coils within the resonator section of the induction heater is shown in Fig. 3. The entire resonator section consisted of two arrays of ten vacuum capacitors, located (as shown in Fig. 3) within a 1.7-m-dia cylindrical aluminum test tank. Each vacuum capacitor array is connected with a single turn work coil. Each work coil consisted of five water-cooled copper tubes which were silver-soldered together to form a single structure. The coils were silver-plated to reduce resistance heating due to the high coil current. The ends of the capacitors were water-cooled and rf chokes were installed in the water cooling lines. All tests reported herein were conducted with atmospheric air in the test tank.

The front of the test tank was a removable dome (shown removed in Fig. 3) containing five (10-cm-dia) view windows for observation of the test section from different angles and/or diagnostic equipment access. An overhead trolley and winch system permitted removal of the dome and allowed rapid access to the test section for inspection of uranium compound residue deposition on different components of the
chamber after completion of a test. A mycalex support system (see Fig. 3) was attached to the base of the aluminum test tank and forward section resonator to hold the endwall assembly of the test configuration concentric within the rf work coils.

All components of the rf induction heater were water-cooled with a total water flow rate of about 3.8 l/s. Measurements were made of all the cooling water and gas flow rates, associated temperature rises, and all electrical quantities necessary for performing a component and overall system power balance on the rf equipment. Meters to monitor the voltage, current, and power in various stages of the rf induction heater were used during the tests. Strip-chart recorders were also used to continuously monitor the plate voltage, plate current, and resonator voltage. The rf voltage supplied to the resonator sections was measured with a capacitor-type voltage probe (see Fig. 3). An automatic twenty-four channel stepping-type temperature recorder was used to monitor all the critical thermocouples located throughout the rf induction heater system, the components of the rf test chamber, and the various cooling water and gas inlet reference temperatures.

The rf input power for the plasma discharge was determined by the rf voltage supplied to the resonator section of the heater and the impedance of the plasma and resonator which, in turn, determined the current level. The impedance of the plasma was determined by its size and electrical conductivity.

Gas and Cooling Water Flow System

Figure 4 is a schematic of the argon gas and high-pressure cooling water flow systems. Commercial grade argon gas was supplied to the test chamber (i.e., to the vortex injectors located on the periphery of the endwall) from a 72.5 scm bottle supply. Flow meters were used to measure the argon mass flow rate during the tests. The exhaust gases (argon plus other volatile uranium compounds) were removed from the endwall through exhaust ducts and routed through an appropriate exhaust system (UF6 condenser system, see Fig. 5). Downstream of the condenser system were flow control valves used to adjust the pressure in the test chamber. The exhaust gases were then ducted to the final neutralizing trap (NaOH + H2O) located on the roof of the laboratory.

To provide the necessary water cooling, two closed-loop, high-pressure cooling systems, each having a total storage capacity of approximately 320 l, were used. Each system employed a positive displacement pump which supplied up to 1.3 l/s of cooling water at approximately 40 atm. A surge suppressor was used in each coolant loop to damp out the pressure pulsations, inherent in these type pumps, to less than 1 percent. Figure 4 shows additional details, including locations of the heat exchangers and flow metering equipment.
Plasma Starting System

A vacuum start technique was used in all the tests, since the UF₆ injector located within the endwall thru-flow duct (see following section entitled TEST CHAMBER CONFIGURATIONS for additional description) precluded the use of auxiliary starter rods. With this technique, the rf plasma was ignited at approximately 10 mm Hg using breakdown of the argon gas which occurred at a resonator voltage of about 4 kV. This technique had the advantage of eliminating the introduction of foreign materials into the test chamber which would be present with dc arc retractable rod starting techniques and also, in conjunction with the argon feed and the exhaust trap system, permitted a partial purge between tests.

UF₆ Transfer System

In support of the rf plasma experiments, a UF₆ handling and feeder system to provide a controlled and steady flow of heated UF₆ at temperatures up to 450 K was developed. Since successful completion of the rf plasma tests, particularly at high power and pressure levels, requires a reproducible, continuous, and safe UF₆ handling and flow monitoring system, considerable effort was devoted toward establishing this capability.

Based on the results of exploratory UF₆ handling and flow metering tests, the need for elimination of as much contamination as possible from the UF₆ supply and flow handling system became apparent. Difficulties experienced in early tests using hot UF₆ included partial clogging of several of the feedlines, total clogging of some small hypotubes, and, on several occasions, complete clogging of 5-mm-ID main transfer lines and valves. The partial and total clogging occurred in some of the tests even when relatively high electrical resistance heater temperatures were employed (≤475 K). Analysis of some of the material collected from the clogged lines revealed it to be a combination of UF₄, UO₂, and occasionally a third unidentified compound. Both electron diffraction and IR spectrophotometer diagnostic techniques were used to identify the compounds. To verify the possible causes of residue in the transfer lines, a separate test was conducted wherein two identical parallel feedlines were used, one prepared with normal cleaning (acetone and argon purge) and the other using an acid-flush technique (0.1 N HCl solution, followed by trichlorethylene, and then a heated bakeout followed by outgassing under vacuum conditions for several hours). The results indicated a minimum amount of residue was present in the acid-flush lines as compared to the normally cleaned lines; thus all tests reported herein include this cleaning procedure.
Figure 5 is a schematic diagram of the UF₆ transfer system. The system was designed to provide UF₆ mass flow rates up to about 5 g/s and subsequent possible injection of UF₆ into the test chambers operating at pressures up to approximately 20 atm. Figure 6 shows the vapor pressure curve for UF₆ for the operating ranges of interest. (Refer to APPENDIX C for additional details on the properties and assay of the as-received UF₆.)

The principal components of the UF₆ transfer system (see Fig. 5) were the UF₆ boiler, the boiler heat supply system, and the UF₆ condenser (exhaust) system. The boiler was a 2 l Monel cylinder rated at 200 atm working pressure. Monel was selected because of its resistance to chemical attack by hot, pressurized UF₆. (Refer to APPENDIX C for additional details on the corrosive aspects of UF₆.) A heat exchanger to provide internal heating was located in the bottom of the boiler. The thermocouple wells, heat exchangers, and UF₆ flow lines were all fabricated from 6.4-mm-OD Monel tubing. As shown in Fig. 5, electrical resistance heater tape was wrapped around the majority of components. An insulated 3.5 kW electrical heater surrounded the boiler and was used to reach the desired equilibrium temperature and pressure prior to flowing the UF₆. A variable powerstat (see Fig. 5) controlled the evaporation rate and temperature within the boiler. Figure 7 is a photograph of the UF₆ supply system and associated instrumentation installed adjacent to the test tank.

In the tests reported herein, use of the electrical heater assembly alone was sufficient to provide the required flow rates; in future tests employing higher UF₆ flow rates for longer time periods, electrically-heated gaseous N₂ will be supplied to the UF₆ boiler heat exchanger. In this case, control of the rate of UF₆ evaporation is accomplished using the bypass loop shown in Fig. 5. To serve as a safety (rapid cool-down) device in the event of a UF₆ leak at or near the boiler assembly, a high-pressure (40 atm) cooling water line and valve assembly was connected to the boiler internal heat exchanger coils. Additional safety was provided by a removable plexiglass enclosure which surrounded the boiler and was connected through a 25-cm-dia flexible metal duct to the exhaust gas scrubber system (1800 cfm) located on the laboratory roof.

Chromel-Alumel thermocouples installed in the wells within the UF₆ boiler and connected to a temperature recorder were used for continuous monitoring of the boiler temperature. The gaseous UF₆ exiting the boiler passed through a dual set of welded-bellows-type shutoff valves. A pressurized argon purge line was connected to the UF₆ transfer line Monel tubing at a tee connection. A pressure transducer, burst disc (refer to APPENDIX C for discussion of UF₆ corrosion effects on the stainless steel burst disc), and a thermocouple were also connected into the transfer line adjacent to the purge line. A micro-meter-type welded bellows needle valve was also located in the UF₆ transfer line, followed by another pressure transducer. The Bell & Howell pressure transducers used were Type 4-317; these were variable-resistance-type and employ unbonded strain-gage windings connected in a four-arm
They had an all-welded internal construction and metal-to-metal bonds welded at temperatures approximately three times higher than the operating limit of 625 K. Application of a thin layer of pure nickel onto the 410 stainless steel substrate was required to protect the end face of the transducer from the hot, pressurized UF₆. (Refer to APPENDIX C for additional details on the corrosion aspects of UF₆.) Therefore, a 2.5 x 10⁻²-mm-thick pure nickel (99.999%) coating was electroplated onto the 1.5-cm-dia face of the pressure transducer.

A Matheson linear mass flow meter (calibrated for UF₆) was located in the transfer line to provide on-line determination of the UF₆ mass flow rate prior to entering the UF₆ injector within the test chamber. Earlier experience with UF₆ and standard rotameter-type flow meters indicated severe etching and corrosion occurs after relatively short operating times. The linear mass flow meter permitted flow metering of hot UF₆ over a flow rate range from approximately 0.003 to 0.5 g/s. The meter was calibrated at Matheson Corporation at equivalent UF₆ flow rates up to 3.39 g/s. By incorporating a Monel transducer, the meter was capable of handling heated UF₆. The meter basically consisted of an electrically-heated tube and an arrangement of thermocouples to measure the differential cooling caused by the UF₆ gas passing through the tube. The thermoelectric elements generate a dc voltage proportional to the rate of mass flow through the tube. Thus, the meter is relatively insensitive to pressure and temperature changes. After sustained usage of the linear mass flow meter system throughout the test program, a deterioration in the output signal (volts) as a function of the UF₆ mass flow rate was noted. Disassembly and examination of the sensor head and transducer revealed a light grey-green coating; an acetone flush removed part of the coating but a recalibration with argon revealed a change in the meter characteristics. The indicated flow rate remained a linear function of the meter output signal but the slope of the curve was reduced. To rectify this situation, periodic calibrations against a standard calibrated argon flow meter were employed in the remaining test series.

The exhaust from the test chamber, comprised of argon, UF₆, and other volatile uranium compounds, was collected in the UF₆ condenser system located downstream of the test chamber. The condenser system consisted of two 0.5ℓ stainless-steel vessels (connected in parallel) immersed in liquid N₂. All valves throughout the condenser system were welded-bellows-type. A neutralizing trap (NaOH + H₂O) was located downstream of the condenser system to remove any residual uranium or uranium compounds which passed through the flow trap, shown in Fig. 5.
Test Chamber Configurations

Figure 8 is a sketch showing a cross section of the basic test chamber configuration employed in the 1.2 MW rf induction heater tests with pure UF\(_6\) injection. For simplicity, only half the symmetric chamber is shown. This test chamber configuration was selected based on the results of the exploratory rf plasma test series summarized in APPENDIX D. This test chamber configuration incorporates several features, including the ability to change the axial location of the on-axis UF\(_6\) injector, the injection area of the argon vortex injectors, the ability to vary the distribution of exhaust gas flow (axial bypass), and cooling water to the peripheral wall annulus. (Refer to APPENDIX D, Fig. 92 for a sketch illustrating the endwall exhaust gas scheme used on the left endwall assembly (not shown in Fig. 8).) This endwall had provision for removing the exhaust gas through an axial bypass annulus located on the periphery of the endwall. The axial distance between endwalls was 10 cm. Figure 9 contains photographs showing details of this test chamber configuration and a view through the center viewport of the test tank with an argon rf plasma present. The peripheral wall was comprised of a concentric set of water-cooled fused-silica tubes. (Refer to APPENDIX C for additional details on the properties of the as-used fused-silica tubes.) The inner tube was 5.7-cm-ID x 6.1-cm-OD; the outer tube was 6.5-cm-ID x 7.3-cm-OD. The argon vortex was driven from the right endwall by a set of eight equally-spaced stainless-steel vortex injectors located tangent to the periphery of the endwall. In addition to the axial bypass provision in the left endwall, both endwalls had the option for removing varying amounts of the exhaust gas through the on-axis thru-flow ducts (using independent valve controls). Heat exchangers were located downstream of the endwall assemblies to aid in cooling down the exhaust gases. As shown in Fig. 8, the UF\(_6\) injector, located on-axis and concentrically within the right endwall, was fabricated from a 50-cm-long three concentric copper tube assembly and in the majority of tests was located with the injector tip extending into the test chamber. High pressure water (20 atm) heated to approximately 350 K via a steam heat exchanger (see Figs. 4 and 7) flowed at 0.14 l/s between the concentric tubes of the UF\(_6\) injector. This provided cooling relative to the hot plasma environment while still maintaining a high enough temperature in the injector to permit flowing the pressurized gaseous UF\(_6\) without solidification in the UF\(_6\) transfer line/injector (see Fig. 6).

Diagnostic Equipment

Calorimetric Measurements

The total power deposited into the uranium rf plasma was obtained from an overall test chamber energy balance by summing the power lost by radiation, power deposited into the annular coolant of the peripheral wall, power deposited into the endwall assemblies, power convected out the exhaust ducts, as well as, power
deposited into the heat exchanger and UF₆ injector assembly. Measurements were made of all cooling water flow rates using rotameters and/or magnetic-type flow meters. The associated inlet and exit coolant temperatures were monitored with copper-constantan thermocouples located as close to the test region as possible. The power convected out the thru-flow ducts was measured using an exhaust gas heat exchanger installed in each of the exhaust duct lines.

**Radiometric Measurements**

The power radiated from the uranium rf plasma was measured using a specially constructed radiometer and chopper wheel assembly. A block diagram of the radiometer optical system and associated transmission characteristics are shown in Fig. 10. A Reeder RBL-500 thermopile detector with a quartz window was used as the radiometer sensing element. The output of the thermopile was connected to an operational amplifier and displayed on a strip-chart recorder. Internal rf shielding and rf chokes were required to isolate the radiometer electronic system. Radiation within different wavelength bands was measured using the various transmission cut-on/cut-off filters shown in Fig. 10(b). The response of the thermopile with filters was calibrated using a standard Eppley Laboratory source of spectral irradiance. The total power radiated from the plasma and in each wavelength band was calculated assuming isotropic radiation, including allowance for blockage due to the rf work coils.

Continuous observation of the rf plasma discharge during the tests with pure UF₆ injection was accomplished using an overhead projection screen system. Still pictures (using neutral density filters) taken through the various viewports were used for estimating the discharge diameter and shape (see Fig. 9(b)).

**Dye Laser System**

Figure 11 is a schematic of the tunable cw single-frequency dye laser used to provide the very narrow uranium line used in the absorption measurements. A Spectra-Physics Model 170 argon-ion laser (10 W) was used for the pump power and was operated at λ = 514.51 nm. The Spectra-Physics Model 580 dye laser system used is shown in Fig. 12. The unit was used with a methanol and water solution containing Rhodamine 6G dye. Rhodamine 6G absorbs in the wavelength band λ = 480 to 530 nm and provides laser gain from λ = 540 to 630 nm. This system permits synchronizing the three possible tuning mechanisms, cavity length, etalon length, and cavity prism. The unit employs a single high-finesse, low-loss piezo-scanned tunable etalon, automatic scanning electronics, a low fm jitter dye circulation system, and a temperature-controlled oven assembly to aid in maintaining stability (single line operation without mode hopping). For high resolution scans, the cavity length was tuned while the etalon was traced in synchronism with the cavity scan. For large bandwidth scans, the etalon was scanned while the cavity length tracked (see Fig. 11).
cavity prism was tracked in synchronism with the etalon to keep the laser power constant. For the majority of the tests reported herein, approximately 1 W of pump power was used. Typical dye laser output powers (narrow line operation at $\lambda = 591.54$ nm) were 50 to 100 mW. The $\lambda = 591.54$ nm uranium line was selected because it is a relatively strong Uranium I (neutral atom) line and appears well-defined in the spectral emission scans. The lower state for the $\lambda = 591.54$ nm line is the Uranium I ground state. The half-width of the laser line at this wavelength was approximately $\Delta \lambda = 10^{-4}$ nm.

**Optical Diagnostic System Used for Absorption and Emission Chordal Scans of Uranium Plasma**

Figure 13 is a schematic diagram of the optical diagnostic system used for the absorption and emission measurements in the rf plasma tests with pure UF$_6$ injection. Figure 14 is a photograph of the overall 1.2 MW rf plasma test facility and a portion of the dye laser/optical system located on the pneumatic isolation table. The 1.2 by 1.8 m pneumatic table was required to adequately isolate the dye laser system and majority of associated equipment from all vibrations in the 1.2 MW rf induction heater test facility. In addition, rf shielding and various filter systems were adapted to various electrical components to eliminate rf and undesirable electrical feedbacks and ground loops. The 1.2 MW rf master control console is shown at the left of Fig. 14. To the left of the aluminum test tank is the majority of the flow meters and valving associated with the water cooling systems for the test chamber. Directly to the right of the aluminum front dome is the control equipment for the argon gas system and the UF$_6$ transfer and feeder system. The instrument rack to the right contains recorders for monitoring the UF$_6$/rf plasma electrical characteristics, the temperatures of various components of the UF$_6$ transfer and feeder system, and the pressure transducer outputs from the UF$_6$ supply system. Each system was installed and checked out separately to verify isolation from possible stray rf interference effects unique to this type of experiment.

As shown in Fig. 13, a Perkin-Elmer Uranium lamp (hollow cathode type) was used as the uranium line reference standard. Earlier tests verified that the uranium lamp did not have sufficient intensity in the wavelength range of interest ($\Delta \lambda = 400-600$ nm) to be used as the line source in the plasma absorption measurements at a discrete wavelength. A Spectra-Physics confocal Fabry-Perot spectrum analyzer with a free spectral range of 8 GHz ($\approx 10^{-2}$ nm) was used to define and calibrate the tuning wavelength spectrum. A Coherent Radiation power meter was used to permit (together with a beam splitter) continuous monitoring of the dye laser output power at the particular wavelength line selected (normally $\lambda = 591.54$ nm). An Ithaco Dynatrac phase-sensitive-detector and lock-in amplifier (Model 391A with automatic frequency tracking) and a dual set of Princeton Applied Research Laboratory (Model 125) chopper-signal-generator assemblies (capable of multiple frequency operation) were used in the system, as shown in Fig. 13. A pair of fixed front surface mirrors
(5-cm-dia and located within a vernier adjustable Oriel mount) were used to direct the approximately 1.5-mm-dia laser beam into the aluminum test tank (parallel to the major axis of the discharge). The second mirror assembly was located on a large 1-beam to minimize vibrations. A Jodon beam expander (1.5-cm-dia aperture) and collimator was located inside the test tank, as shown in Fig. 13. Another fixed front surface mirror was located in the test tank approximately 6 cm behind the axial midplane of the fused-silica tube test chamber at an angle of 45 deg to the discharge major axis. This mirror was mounted on a cantilever rod assembly which permitted movement to different axial locations along the major axis of the discharge. The centerline of the expanded and collimated laser beam traversed the concentric set of fused-silica tubes, which form the test chamber, 0.75-cm-off-axis, as shown in Fig. 8. The laser beam exited from the aluminum test tank through an aperture and the central viewport shown in Figs. 13 and 14. A 10-cm-dia aerial lens (f/1.8, focal length = 34.3 cm) was located inside the test tank to aid in focussing the laser beam onto the slit of the monochromator and to correct for the beam divergence through the test chamber.

The final optical tracking system used for making the chordal scans of the plasma emission and absorption, as shown in Fig. 13, evolved after several preliminary designs, ray tracing analyses, and bench test experiments. The optical system design had to account for a certain amount of refraction through the test chamber geometry employed. The effect of the concentric fused-silica tubes was twofold. The refractive effects of concentric, right circular cylinders filled alternately with gas, quartz, water, quartz and air were calculated and are easily predictable. The second effect (surface imperfections), however, was not smoothly varying and cannot be compensated for in the lens and optical system design. This effect had to be calibrated out for each test, i.e., once the rotational orientation of the two concentric fused-silica tubes was selected, they were maintained in that orientation until completion of that particular test. A 1.5-cm-off-axis displacement was employed in the chordal scan measurements. This was dictated by the fixed location of the 10-cm-dia central view window in the large aluminum test tank dome. Fortuitously, the 1.5 cm dimension corresponded to the approximate radius of the rf plasma discharge during normal operation with pure UF₆ injection.

The remainder of the optical diagnostic system included a fixed front surface mirror, a 10-cm-dia, 20-cm-focal length lens, a rotating front surface mirror, and a Jarrel Ash 0.25 m (or 0.5 m with f/8.6 optics) monochromator with f/3.5 optics and an EMI 9558 (or an RCA C-31034 with flat response between 300-900 nm) photomultiplier (S-20 response) tube assembly (see Fig. 13). A specially constructed rf shielded signal generator and controller system was used for operating the General Scanning Inc. mirror motor drive. The mirror drive assembly had an independent frequency, amplitude, and off-set control. The system was set-up to image a source of cross-sectional radius 1.5 cm without vignetting within the monochromator system. Since the source and slit exist in conjugate planes at a magnification ratio of 1.57, the 25 µm square slit arrangement employed in the monochromator represented a scanning
aperture 39 \( \mu \text{m} \) square at the plane of the discharge centerline (both emission and absorption). For emission measurements, the dye laser beam was blocked and the chopper assembly (85 Hz) located adjacent to the central viewport of the test tank was used (see Fig. 13). For absorption measurements, the chopper assembly adjacent to the dye laser head was used (650 Hz). Calibration checks were included to verify that the dye laser output beam (\( \lambda = 591.54 \text{ nm} \)) power remained essentially constant for relatively long time periods. The beam splitter and power meter shown in Fig. 13 was used for this on-line determination. The spectrum analyzer was used to verify that the dye laser operated in single mode at the selected wavelength. The uranium lamp was used to select the wavelength of the uranium line used (591.54 nm) and to set the monochromator at the peak of this line. The monochromator, in turn, was used to make the initial setting of the dye laser on this same line. Additional fine tuning was accomplished during the actual UF\(_6\) rf plasma tests by tuning the central frequency control of the dye laser system to maximum absorption.

The optical tracking system was checked out first with only an argon rf plasma present. This permitted a verification of tracking reproducibility and isolation of the instrumentation from extraneous vibration and/or rf interference effects; reasonably reproducible scans were obtained. The time constant normally used with the phase-sensitive-detector was 125 ms. The signal generator and controller for the scanning mirror was set-up to provide a different scanning rate (approximate factor of 2X) between the plasma discharge centerline to the 1.5-cm-off-axis location and the return scan from the off-axis location back to the discharge centerline. Typically, 10s was required for a scan.

Refer to APPENDIX B for an additional discussion of the calibration methods related to the emission and absorption chordal scans using the optical system shown in Figs. 13 and 14.

**Equipment and Systems for Chemically-Analyzing and Characterizing the Residue Deposited on Various Components of the Test Chamber**

To permit a detailed analysis of the samples of residue collected from the various components of the test chamber after rf plasma tests with pure UF\(_6\) injection, the following UTRC instrumentation was employed:

1. Taylor-Hobson profilometer (Talysurf-4) -- permitted quantitative determination of the magnitude of surface coating/etching/erosion that may take place on the surface of the fused-silica tube.

2. Perkin-Elmer IR Spectrophotometer (Model 457) -- permitted identification of compounds using IR spectrophotometric absorption measurements (2.5-40 \( \mu \text{m} \) wavelength range) of reference material standard compounds and small samples of residue removed from test chamber components.
3. Cameca Scanning Electron Microprobe (Model CAMEBAX) -- permitted determination of the elements present in the residue samples and also scanning electron micrographs. Showed topographical and compositional variations and permitted x-ray mapping of the individual elements present.

4. Norelco X-Ray Diffractometer (Mark II) -- permitted identification of compounds present in the residue samples by subjecting them to copper K\(_\alpha\) radiation and comparing the resulting x-ray diffraction patterns with reference standards.

5. Hitachi Electron Microscope using selected area diffraction (SAD) (Model HU-11) -- permitted identification of compounds present in the residue samples by subjecting them to electron bombardment. Also provided indication of relative crystallinity of the material.

6. 3M Ion Scattering Spectrometer (ISS)/Secondary (or sputtered) Ion Mass Spectrometer SIMS (Model 520 B) -- permitted identification of the various elements and compounds present in the residue samples. The unique features of this instrument that distinguish it from the other instruments described above are (a) it was sensitive to just the outer monolayer of the surface, (b) its sensitivity was as high as one part of a monolayer per million, (c) it gave positive identification of the compounds, and (d) it could detect hydrogen and distinguish isotopes of uranium.
DISCUSSION OF TEST RESULTS

Exploratory Tests

Details of the exploratory tests are summarized in APPENDIX D. Basically, the majority of exploratory tests were conducted using the 80 kW rf induction heater with the test chamber at approximately atmospheric pressure and rf discharge power levels on the order of 10 kW. Four different test chamber flow configurations were tested from which the configuration demonstrating the confinement of uranium vapor at the highest pure UF₆ injection rates with minimum wall coating was chosen. The power and pressure levels employed in the exploratory tests were primarily limited by the safety aspects of the thin-walled gas-cooled fused-silica peripheral wall. In these exploratory tests moderate UF₆ injection flow rates were employed, which resulted in light uranium-compound-coatings on the inside surface of the fused-silica tube peripheral wall and endwall assemblies. The rf plasma discharge was reasonably well confined throughout the majority of test conditions. Some discharge oscillations were noted; these oscillations were also quite susceptible to rapid changes in the flow conditions, particularly the introduction of pure UF₆.

General Characteristics of Vortex-Stabilized (Uranium) RF Plasmas

The primary independent variables in the uranium rf plasma tests reported herein were the rf operating frequency, the chamber pressure, the argon mass flow rate, the UF₆ mass flow rate, the dc input power, and the test configuration/flow scheme. The primary dependent variables were the discharge diameter (size and shape), total rf discharge power, power radiated from the plasma discharge, power lost by convection and conduction, and the radial distribution of temperature within the discharge. Several secondary dependent variables would include those that are temperature dependent (i.e., electrical conductivity and thermal conductivity).

The coupling and interactions between the plasma discharge and the high frequency magnetic fields which produced the discharge are most complex. Theories related to rf plasma discharges make numerous simplifying assumptions related to the plasma boundary conditions and conductivity profiles; no one universal theory includes all of the important effects. This is particularly true for convection; the electrical and thermal characteristics of radial-inflow vortex-stabilized rf plasmas strongly depend on this mechanism of heat dissipation. The axial introduction of pure UF₆, as in the tests reported herein, is an additional complication to the flow pattern within the plasma. The shape, size, and stability of the discharge also depends on the effects of convection, in addition to the interaction between the plasma and the fields of the rf work coils.
In the experiments reported herein, argon buffer gas was used to drive the radial-inflow vortex and the UF₆ was injected separately, representative of the gaseous uranium fuel to be contained within the plasma region of the nuclear reactor test chamber. A radial-inflow pattern is generally characterized by an essentially laminar radial stagnation surface across which there is no net inward radial buffer gas flow. The radial position of this surface is normally defined to be the radial location beyond which the density of the uranium fuel is assumed to be essentially zero. This surface can be located as far from the centerline as 90 percent of the total vortex test chamber radius. In actual reactors it is anticipated that the uranium fuel and fission products which diffuse radially outward across the radial stagnation surface will be carried out of the test chamber along with the argon buffer and bypass flow before reaching the peripheral wall. Buffer gas may enter the central uranium fuel region of the vortex by a combination of diffusion across the stagnation surface and from the endwall boundary layer. The gas is removed from the test chamber primarily through the on-axis thru-flow exhaust duct in the endwall; some is also removed through the axial bypass exhaust duct. In an actual full scale reactor, a negative temperature gradient through the buffer gas region toward the peripheral wall insures that a positive density gradient exists through the buffer gas region; this aids in reducing the diffusion of uranium fuel radially outward through the buffer gas. Buoyancy effects must also be considered; however, these effects will be small provided the acceleration due to flow rotation is large relative to the gravitational acceleration. This was accomplished in the uranium rf plasma experiments reported herein by maintaining a moderately high tangential velocity within the plasma region.

To permit a systematic comparison to be made and important trends noted, attempts were made to maintain constant as many of the independent variables as possible during the injection of UF₆; however, changes in the rf power, operating frequency, and associated flow rates were sometimes required to prevent discharge extinguishment and/or plasma oscillations. In general, the introduction of pure UF₆ into the discharge significantly altered the impedance of the plasma which, in turn, determined the plasma size and electrical conductivity. Normally, this was manifested as a significant increase in the radiation emitted from the plasma; correspondingly, a moderate increase in the total power deposited into the plasma due to rf coupling efficiency changes and accompanying parameter changes was also observed. As discussed in APPENDIX D, a significant amount of this radiation increase occurred in the visible and near-UV wavelength bands. In contrast to the earlier exploratory tests conducted at relatively low power and pressure levels, the rf plasma discharge in the 1.2 MW facility tests was considerably more stable and less sensitive to changes in the operating frequency, argon mass flow rate, and the UF₆ mass flow rate. A typical ratio of plasma diameter to peripheral wall diameter was 0.55. Calculations of the plasma diameter decrease expected as a result of the change in operating frequency from the 13.56 MHz (8.5-cm-dia rf work coils) used in the 80 kW exploratory tests compared to the 5.4 MHz (9-cm-dia rf work coils) used in the 1.2 MW tests were in good agreement and confirms the scaling laws that can be applied.
Effect of UF₆ Mass Flow Rate on RF Plasma Absorption Characteristics

Figure 15 is an example of the absorption measurements obtained on-axis at the axial midplane location using part of the optical system shown in Fig. 13. (Refer to Fig. 8 for a sketch of the test chamber configuration.) The 100 percent absorption reference level was obtained by blocking the entrance slit of the monochromator. A 1.25 s damping constant was used in the data recording system and the chopper frequency was 650 Hz for this particular test. Four different UF₆ mass flow rates were employed ranging from 1.3 x 10⁻² g/s to 8.2 x 10⁻² g/s. Note that axial bypass was employed in these tests to aid in reducing uranium compound coating on the peripheral wall. At the maximum UF₆ mass flow rate used, approximately 98 percent of the incident intensity of the 591.54 nm laser line was absorbed in a single pass through the center of the UF₆/argon rf plasma. After operating for approximately 1½ minutes at this condition, the UF₆ injector metering valve was rapidly shut-off. As noted, the laser line intensity signal did not immediately return to the initial value because of outgassing of residual hot UF₆ from the feed lines and injector assembly. Trace amounts of UF₆ were still observed entering the plasma after approximately 5 minutes. After waiting for the residual UF₆ to outgas, the signal approached the initial value, indicating a relatively small amount of wall coating had occurred. Post-test inspection of the inner fused-silica tube verified this condition.

The type of test shown in Fig. 15 demonstrated that controlled, steady-state injection of increasing amounts of UF₆ could be introduced into the rf plasma while simultaneously conducting rf plasma absorption measurements.

Examples of Radiation, Optical Transmission, and Radial Temperature Profile for a Uranium RF Plasma

TABLE I summarizes the range of operating conditions for the rf plasma tests with optical chordal scan measurements conducted in the 1.2 MW rf induction heater with pure UF₆ injection. Figure 8 is a sketch of the test chamber configuration and Fig. 13 shows the instrumentation used. To illustrate the visual effects of injecting pure UF₆ into the rf plasma, Fig. 16 contains photographs for both argon-only and argon plus UF₆ injection tests as viewed through the center viewport and the two side viewport windows of the aluminum test tank. In this case, no additional neutral density filtering was added for the argon plus UF₆ case. Note that a significant increase in the intensity occurred. Figure 17 is the corresponding example of the total discharge power radiated and distribution of the radiation in different wavelength bands obtained from the rf plasma with pure UF₆ injection. TABLE II summarizes the test conditions for the case presented. The measurements were taken with the radiometer system shown in Fig. 10. The introduction of the pure UF₆ directly into the discharge resulted in a significant increase in the total radiation emitted from the plasma (220 to 1300 nm range) as measured with the radiometer system. This increase may be attributed in part to the cumulative effects of an increase in
line and continuum radiation (major effect), an increase in discharge power, an
increase in the coupling efficiency, and a change in plasma size and shape. Addi-
tional radiometric measurements indicated a significant fraction of this radiation
occurs in the visible region of the spectrum (line radiation in the 300 to 720 nm
range).

Chordal scan measurements of the emission from and the absorption by the rf
plasma with pure UF₆ injection using the system shown in Fig. 13 were made at a
single wavelength (λ = 591.5 nm) and several axial locations: the test chamber
axial midplane, adjacent to the right rf work coil, and adjacent to the tip of the
UF₆ injector. The output data indicated the measurements in the two central loca-
tions were very similar. The measurements made adjacent to the injector tip were
nonreproducible; this was attributed to the close proximity to the injector and UF₆
being injected into the rf plasma at this interface, as well as the end effects
(nonrotational symmetry existed in this region). Because of the close similarity
of the output data between the two central scan locations (axial separation of 1 cm),
only the results from the axial midplane location will be included herein. Figure
18 illustrates the shape of the radial profiles for both the emission and absorption
coefficients obtained from the test with the highest UF₆ mass flow rate (mUF₆ = 3.2
x 10⁻² g/s). This test case was designated V and the corresponding test conditions
are illustrated in TABLE II. Five other separate test cases were conducted at
sequentially lower flow rates of UF₆; the lowest corresponding to a UF₆ mass flow
rate of 9 x 10⁻³ g/s (see TABLE I). Note the distinct peaks toward the center of
the plasma discharge and rapid decay of both the volume emission and absorption
coefficients at approximately r/R = 0.25 as a traverse is made toward the edge of
the plasma. In this case the plasma diameter, as shown in the right-hand corner of
Fig. 18, was 2.8 cm as determined from still photographs.

Figure 19 shows an example of the results of the radial variation in plasma
optical transmission (I/Iₒ) and temperature as determined from the emission and
absorption measurements for test case V. The dye laser line used in this and all
subsequent tests to be described was the λ = 591.5 nm line. Recall for this case
the emission and absorption chordal scan measurements were taken at the axial mid-
plane of the discharge. The radial temperature profile as shown was determined using
Kirchhoff's law (see Figs. 13 and 14 for additional details of the optical scanning
system used and APPENDIX B for a summary of Calibration Methods). TABLE II contains
additional details on the test conditions for this particular case, which correspond
to the maximum mass flow rate of UF₆ used in the chordal scan measurements; the UF₆
mass flow rate was 3.2 x 10⁻² g/s. The sketch in the lower portion of Fig. 19 is
a simplified cross section of the test chamber configuration employed and indicates
the location used for the chordal scan measurements. For comparison, an example of
the temperature profile determined from an argon-only plasma test as shown by the
dashed curve in the figure illustrates the off-axis type temperature peak obtained
from an argon plasma (no UF₆ injection) operating under similar test conditions.
The centerline temperature in the argon-only case was approximately 9300 K, with an
off-axis peak temperature of about 11,000 K occurring at approximately midradius.
The introduction of pure UF₆ into the rf plasma resulted in a suppressed temperature
profile at the off-axis position, as shown in Fig. 19, between a radial distance of
approximately 0.2-0.8 cm. An off-axis temperature peak was noted at approximately
two-thirds of the radial distance out toward the edge of the plasma. The off-axis
peaks can be attributed primarily to the mechanism of depositing rf power into an
annular region.

Equilibrium Composition Calculations

To aid in the estimation of the total uranium atom number density distribution
within the plasma discharge, pure UF₆ and/or UF₆/argon equilibrium composition
calculations were made for the current range of test parameters utilizing a computer
code based on the procedure described in Ref. 9. The calculations included the
partial pressure range from 10⁻⁴ to 1 atm and temperatures from 300 to 10,000 K.
The following species were included: UF₆, UF₅, UF₄, UF₃, F, F⁻, F₂, U, U⁺, U²⁺,
U³⁺, and E⁻. Figures 20 through 22 show examples of the equilibrium composition
of UF₆ as a function of temperature. In Figs. 20 and 21 the equilibrium composition
of pure UF₆ is shown as a function of temperature for various partial pressures over
the ranges of particular interest in these experiments. Note the similarity between
the mole fractions of the same species over a relatively wide range of partial
pressures as shown in Fig. 21. To illustrate the rapid increase and decrease of the
mole fractions of various fluoride compounds of uranium, the abscissa in Fig. 20 was
extended to lower temperatures. Very steep slopes are noted particularly in the
2000 K range for a UF₆ partial pressure of 10⁻³ atm. Note that at approximately
7000 K, the concentration of singly-ionized uranium (U⁺) increases; measurements
of the rf plasma characteristics indicate that the rf plasma with argon vortex
buffer gas injection has an average temperature in excess of 7000 K for the type of
operating conditions reported herein (refer to Fig. 19). For all practical purposes,
at pressures of approximately 1 atm, complete thermal decomposition of UF₆ has
occurred at temperatures of about 5000 K, as illustrated in Fig. 22.

Figures 23 through 26 show the calculated variations of uranium atom number
density with injection partial pressures of UF₆ in a UF₆/argon mixture. Included
are the cases for neutral uranium, singly-ionized uranium, doubly-ionized uranium,
and total uranium atom number density; that is, all species contributing to the
partial pressure at a total pressure of 2 atm; these are representative of the
pressure range used in the majority of tests. In these plots the injected partial
pressure of UF₆ was the variable parameter. In all the calculations local thermo-
dynamic equilibrium was assumed and lowering of the ionization potential was not
included. Inclusion of the ionization potential lowering effect would result in
formation of the ion species at a somewhat lower temperature, but the overall effect
is not immediately obvious unless the influence of the argon ions interacting with
the uranium species is also included. For reference, Fig. 27 illustrates the particle
density of an argon plasma showing the argon particle number density as a function of
temperature for the various species at a total pressure of 2 atm.
Determination of 591.54 nm Absorption Line Width

To complement the chordal scan absorption and emission measurements and verify the validity of the results, particularly since this is the first time measurements of this type using a dye laser system with uranium rf plasmas has been reported, separate Uranium I ($\lambda = 591.54$ nm) absorption line width measurements were made.

It was anticipated that operating the rf plasma with pure UF$_6$ injection at the relatively high power and pressure levels may have resulted in significant pressure broadening to the width of the uranium 591.54 nm emission and absorption line. To better estimate the absorption line width, several measurements were made at different pressures and approximately the same test conditions. Calculations of the doppler width for the uranium 591.54 nm line (no pressure broadening) at 1000 K indicated a line width of approximately 0.74 GHz. The doppler effect on the line width varies as the square root of the temperature, therefore at a temperature of approximately 10,000 K the doppler line width would be approximately 2.34 GHz. This compared favorably with the approximately 2.5 GHz measured in the exploratory rf UF$_6$ plasma absorption measurements reported in APPENDIX D. Figure 28 illustrates the results of the 591.54 nm absorption line width measurements. Again using the $\lambda = 591.54$ nm laser beam ($\approx 10^{-4}$ nm line width) for determining the absorption line widths as a function of chamber pressure, the absorption line width at 1/2 maximum intensity is shown in Fig. 28 as a function of the chamber pressure. The equation shown at the top of Fig. 28 was used for the calculations. The circle data points shown on the ordinate axis were the calculated line widths with no pressure broadening. The corresponding temperatures are shown adjacent to the data points. The two triangular data points shown, corresponding to the measurements at 1 and 2 atm, agree favorably with the previous measurements. These results were used as inputs for the additional calculations, described in the following section, required to determine the neutral uranium number density based on the emission and absorption calculations.

Determination of Total Uranium Atom Number Density Radial Profile Within Uranium RF Plasma

Figure 29 shows the effect of temperature on the partition functions of Uranium I and Uranium II (Ref. 10); that is, neutral and singly-ionized species. The governing equation is shown at the top of the figure. $Z_i$ is the dimensionless partition function, $g_{i,n}$ is the statistical weight of the particular energy level, $E_{i,n}$ is the energy level, k is the Boltzmann constant, and T is the temperature. The partition functions as a function of temperature show similar increasing trends for the UI and UII over the temperature range from 2000 to approximately 10,000 K.
The variation of the number density of neutral uranium (U\textsubscript{I}) is shown in Fig. 30 as a function of radial distance from the test chamber centerline; the results are shown for test case V (see TABLE II for summary of test conditions and Fig. 19 for corresponding radial temperature profile). The circle symbols are from the absorption calculations assuming doppler width with no pressure broadening. The triangular symbols are results from the corresponding emission calculations. Having the temperature profile for test case V as a function of radius, as shown in Fig. 19, and the variation of number density of the neutral uranium also as a function of radial distance from the test chamber centerline (Fig. 30), the injected partial pressure of UF\textsubscript{6}, dependent on both the temperature and the number density of the Uranium I atom, was determined. Having this information, one can go back to Fig. 23 and determine the injection partial pressure of UF\textsubscript{6} corresponding to the temperature and calculated number density of neutral uranium atoms. Knowing this injection partial pressure of UF\textsubscript{6}, one can then make use of the data of Figs. 24 and 25 to calculate the corresponding number density of singly-ionized and doubly-ionized uranium atoms.

To check the validity of these calculations, Fig. 31 shows the mole fraction of U\textsubscript{I}, U\textsubscript{II}, and U\textsubscript{III} over the temperature range of interest (6000 to 10,000 K) and a four decade partial pressure range (10\textsuperscript{-4} to 10\textsuperscript{-1} atm). Note that this wide range in partial pressure does not significantly alter the mole fraction of the individual constituents. Within this range, the mole fraction contribution of U\textsubscript{III} was negligible, as shown in the lower right-hand corner of Fig. 31. This information was important in calculating the results shown in Fig. 32. This figure shows the radial variation of total uranium atom number density; that is, the contribution from the neutral uranium atoms, the singly-ionized, and doubly-ionized species for the UF\textsubscript{6} rf plasma test case V. The total uranium atom number density in atoms/cm\textsuperscript{3} is plotted versus the radial distance from the plasma centerline in cm. Refer to TABLE II for additional test conditions. The numbers in parentheses are the corresponding estimated values of the total uranium species partial pressure in atm. For this particular case, the total uranium atom number density reached a maximum of approximately 10\textsuperscript{16} atoms/cm\textsuperscript{3} at the centerline of the plasma. At a radial location approximately 1 cm off the centerline axis, another peak occurred corresponding to an atom number density one order of magnitude less than the centerline; that is, 10\textsuperscript{15} atoms/cm\textsuperscript{3}. This level decayed to approximately 2 \times 10\textsuperscript{14} atoms/cm\textsuperscript{3} at the edge of the plasma.

An estimate was also made of the total confined uranium mass based on these measurements of the neutral uranium species. The calculated value was 0.03 mg of uranium. Figure 33 is an example showing the radial variation of confined total uranium atoms per unit plasma length at the axial midplane location for the UF\textsubscript{6} rf plasma test case V. Refer to Figs. 19 and 32 for the corresponding radial profiles of transmission, temperature, and total uranium atom number density. Shown above the curve are numbers corresponding to the percent of the total confined uranium atoms. These calculations indicated that a large fraction of the total confined uranium atoms existed at the outer portion of the plasma discharge.
These results can be compared to the uranium total number density obtained from the x-ray absorption measurements as discussed in APPENDIX A. Figure 80 of APPENDIX A compares the uranium number density, in atoms/cm³, versus the weight flow rate of UF₆ in g/s for several test cases. To compare optical emission and absorption chordal scan measurement results with the x-ray absorption measurement results at similar test conditions, the test case for a 52.5 kW RF plasma at a chamber pressure of 1.7 atm, a UF₆ mass flow rate of 0.028 g/s, an argon flow rate of 2.7 g/s, and a discharge diameter of approximately 3 cm was used. The two curves shown in Fig. 80 correspond to the two different diagonal path lengths assumed in the x-ray measurements. The flow conditions corresponding to test case V used in the optical chordal scan measurements of the emission and absorption are the corresponding test conditions that come closest to matching this case. The discharge power was 58 kW, chamber pressure equal to 1.95 atm, flow rate of UF₆ equal to 0.032 g/s, and discharge diameter equal to 2.8 cm (at the axial midplane). For these conditions, but with the UF₆ mass flow rate corresponding to 0.032 g/s (Fig. 80), the bounds on the x-ray measurements which determine the total confined uranium mass are from 2.8 x 10¹⁶ atoms/cm³ corresponding to the 23 cm path up to 6.4 x 10¹⁶ atoms/cm³ for the 9.5 cm path length case. The results shown in Fig. 33 for the radial variation of confined total uranium atoms at the axial midplane for the UF₆ RF test case V indicate a total of 7.3 x 10¹⁵ atoms/cm³/unit length. The corresponding total volume based on the equivalent of a cylindrical plasma with the total mass distributed uniformly would yield a total uranium number density of 4.4 x 10¹⁶ atoms/cm³. This total includes the species consisting of neutral ionized uranium, singly-ionized and doubly-ionized uranium atoms; excluded were other uranium-fluoride compounds. This agreement is good and most encouraging from the standpoint of one measurement technique made completely independently agreeing well with a second independent measurement scheme.

Uranium RF Plasma Tests Incorporating Modifications to Test Chamber/Flow Scheme

TABLE III summarizes part of the rf plasma tests conducted in the 1.2 MW rf induction heater with pure UF₆ injection into the rf plasma and incorporating different modifications to both the test chamber and flow control scheme. The objective was to determine what modifications to the test chamber/flow control schemes would further improve the confinement characteristics of the uranium plasma while at the same time aid in minimizing the wall coating by uranium compounds. To permit a more direct comparison, all tests were conducted over a time period of five minutes. A summary of eleven (11) representative tests are shown by numbers 1 through 11 in TABLE III. The range of test conditions are also shown and include: the mass flow rate of the argon, axial bypass exhaust, and UF₆; the electrical parameters related to the rf plasma, the total emitted radiation, the chamber pressure, the discharge diameter at the axial midplane, the corresponding I/I₀ absorption level measured at the axial midplane on-axis location using the dye laser system, and the weight of residue deposited on the inside diameter of the
fused-silica tube based on post-test examination. A Mettler balance calibrated to 1 μg was used for the weight determination in these and all subsequent tests reported herein. The basic configuration used in all tests is shown in Fig. 8. Figure 34 is a photograph showing typical fused-silica tubes after use in this test series. The degree of coating extended from a relatively heavy to a fairly light coating as can be seen in the photograph. Figure 35 contains close-up photographs showing additional wall coating details of four of the fused-silica tubes during post-test inspection (refer to TABLE III for corresponding test conditions and weight of residue deposited on the fused-silica tubes). The majority of the coating occurred in the central region of the fused-silica tubes. Some residue was also observed at both end regions adjacent to the O-ring seal location. A representative example of the IR spectrophotometric absorption measurements taken of some of the residue collected from the inside surface of the fused-silica tube after the plasma tests with pure UF₆ injection is shown in Fig. 36. Refer to TABLE III for the corresponding test conditions. In all cases a thin wafer KBr matrix was used with the Perkin-Elmer IR spectrophotometer to obtain these IR traces as a function of wavelength. In addition to the weight of the residue wall coating measured and the results of the IR absorbance measurements, visual observations of the uranium plasma behavior and stability were included in analyzing the test results. In general, the overall results indicated that using argon vortex injectors that had small inside diameters (0.17-cm-ID) which provided a relatively high injection velocity and a UF₆ injector assembly with a 0.3-cm-ID and protruding approximately 1 cm from the face of the endwall permitted a relatively high confinement of the UF₆ with minimum wall coating.

In the majority of the tests the IR spectrophotometric measurements indicated a combination of uranyl fluoride (UO₂F₂) and uranium oxide (αUO₃) present on the inside surface of the fused-silica tube. In some tests, traces of SiO₂ and silicone grease were noted in the IR transmission scans. As shown in Fig. 36(c) operating the peripheral wall at an elevated temperature by reducing the flow of annular cooling water by an order of magnitude resulted in a noticeable increase in the SiO₂ content of the residue material collected. A heavier wall coating was also observed. It should be pointed out that caution should be applied when interpreting the results and trends obtained from only a dozen or so tests. Many more tests would be required to give a true statistical sampling representation. In another selected test, an extra heavy coating of silicone grease was applied to the O-rings at each end of the fused-silica tube prior to assembly for the hot flow test with pure UF₆ injection. The post-test IR transmission profile is shown at the bottom of Fig. 36.

To aid in the evaluation of all various wall coatings possible, a cataloging of possible compounds to serve as laboratory standards for these and future tests was included; the results are discussed in APPENDIX C. As an example, the peak corresponding to the wavelength of 7.2 μm was originally labeled as an unidentified compound; after completion of the laboratory standards, this was later identified to be αUO₃ and was also confirmed by other analyses.
Uranium RF Plasma Tests With Sustained Operating Times

TABLE IV is a summary of the long run time uranium rf plasma tests. Attempts were made to keep all operating conditions approximately the same for all tests. TABLE IV summarizes the key test parameters including the test conducted for the maximum sustained operating time of 41.5 minutes. This test was terminated due to cracking of the Mycalex (super 500) radiation/electric insulation shields located on the vacuum capacitors in the upper and lower resonator sections of the 1.2 MW rf induction heater test tank (see Fig. 3). The cause was attributed to excessive sustained radiation loading leading to component fracture. Redesign and the adaptation of cooling to this component should permit considerably longer test times to be obtained, if required. Figure 37 is a plot of the weight of residue material deposited on the inside diameter of the fused-silica tubes as determined from the post-test weighing analysis as a function of test time in minutes. This test series indicated that the addition of silicone grease to the O-rings and use of as-received UF₆ resulted in a significant contribution to the residue coating on the fused-silica tubes (refer to TABLE IX of APPENDIX C for a property assay of the as-received UF₆). Part way into the test program it became obvious that the use of silicon O-rings, silicone grease, unfiltered argon from the laboratory bottle farm, and as-received UF₆ resulted in a fairly linear increase in the residue deposited on the fused-silica tubes as a function of test time (see circle symbol data points in Fig. 37). To aid in reducing this residue, the O-rings were coated with Kel-F oil. This particular lubricant, arrived at after trying other materials such as hydrocarbons, fluoro-silicone, and halocarbons, provided the seal necessary between the fused-silica tube and the endwall while eliminating the silica gel present in silicone grease and other compounds for thickening purposes which apparently reacted on the surface and caused additional deposits. The UF₆ was also filtered through a NaF trap to remove possible hydrogen fluoride contamination. The tests conducted with these changes are shown by the triangular symbols in Fig. 37. A reduction in the residue wall coating by approximately a factor of 2 was noted. In the lower left-hand corner of Fig. 37, the range of silicone grease residue initially deposited on the fused-silica tubes is shown on the ordinate axis. This quantity ranged from approximately 5 to 12 mg. This quantity is included as the error bands on the measurements for the different test times since it was impossible to deposit the same weight of silicone grease on all the O-rings prior to a given test series. A change to viton O-rings was also included as indicated by the square symbol in Fig. 37. In this case, since the viton O-ring is somewhat harder and less deformable than the silicone O-ring and the dimensions of the concentric fused-silica tubes are not exact, an improper seal was obtained as observed during the vacuum pump down prior to ignition. Subsequently, it was determined that silicone O-rings were the best choice as used with the Kel-F oil and filtered UF₆. In addition, because of possible moisture present in the argon (up to 500 ppm) a zeolite trap was used to filter the argon prior to introducing it into the test chamber through the vortex injectors. The longest run time test employed all these modifications and is shown by the diamond
symbol in Fig. 37. The resultant 30.4 mg of residue corresponded to the 41.5 minutes of continuous operation with a UF₆ flow rate of 2.2 x 10⁻² g/s. It is anticipated that further improvements to the flow scheme could be made to reduce this minimum wall coating still further. Also included would be the necessary radiation shielding and cooling required over the vacuum capacitors and resonators; this modification would probably permit operation for several hours without shutdown. The additional limiting factor would be the quantity of UF₆ in the boiler assembly.

Figure 38 contains electron photomicrographs and the corresponding x-ray maps at a magnification of 3000X obtained from a sample of residue from the inside surface of the fused-silica tube after the rf plasma test with pure UF₆ injection for a 30 minute duration. The electron microprobe instrumentation described in the Description of Principal Equipment section was used. This particular test employed the viton O-rings, Kel-F oil, and filtered UF₆ (NaF trap). Note in the photograph labeled (b) in Fig. 38 the x-ray map showing silicon as a white area is very obvious against the background. For this particular test, 35.7 mg of residue coating was deposited on the inside surface of the fused-silica tube; this occurred primarily in the central region. Using the IR spectrophotometric analysis, this compound was identified to consist primarily of uranyl fluoride (UO₂F₂), as shown in Fig. 39. In this test series, attempts were made to analyze approximately the same mass of material; the results of the IR transmission measurements shown in Fig. 39 for the UO₂²⁺ peaks at 10.6 μm indicate an increasing absorbance with test time. To illustrate the type of wall coating occurring after sustained long run time tests, Figs. 40 and 41 are photographs of the fused-silica tubes taken during post-test inspection. The corresponding test times are indicated above each case. In all tests, the mass flow rate of UF₆ was maintained constant at 2.2 x 10⁻² g/s.

<table>
<thead>
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<th>Uranium RF Plasma Tests With Maximum Injection of UF₆</th>
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TABLE V summarizes the operating conditions for the rf plasma tests conducted in the 1.2 MW rf induction heater with the maximum pure UF₆ injection flow rate obtained in tests to date. The objective of this test was to determine, under the constraints of the existing test configuration and available flow schemes, the maximum steady-state injection flow rate of UF₆ possible while still maintaining the plasma in a confined steady-state mode of operation. The results indicated that a UF₆ injection flow rate approximately one order of magnitude higher than previously used in other tests was possible (see Fig. 37). This is shown in TABLE V to correspond to 2.1 x 10⁻¹ g/s. For this case the total discharge power was 67 kW at a chamber pressure of 2 atm. Some difficulty was encountered in exactly determining discharge diameter and radiated power since part of the discharge was displaced away from the central region of the test chamber (toward left endwall assembly). Post-test examination of this test resulted in a residue deposition on the inside diameter of the fused-silica tube of 134.7 mg after an operating test time of 1.2 minutes. Figure 42 shows post-test photographs of the
fused-silica tube and the silicone O-rings used in this particular test. Note that the majority of the coating occurred toward the argon vortex injector end of the fused-silica tube. This would indicate that in future tests devoted to injecting increased amounts of UF\(_6\) into the plasma discharge, additional refinements may be required in both the injector scheme for argon as well as the UF\(_6\) injector design. The effect of the relatively high radiation levels accompanying this test are illustrated in the bottom portion of Fig. 42. Silicone O-rings were used with Kel-F oil; it was apparent that erosion occurred on that portion of the O-rings which faced the plasma region, i.e., exposed to the intense visible and near UV radiation. To permit future tests to be conducted at comparable uranium flow rates and long time periods, a different design endwall assembly which would incorporate shielding of the required O-ring surfaces from the intense radiation from the plasma will be necessary. Figure 43 shows photographs of the electron micrographs at two different magnifications taken of the sample residue from the inside surface of the fused-silica tube after the rf plasma test with maximum UF\(_6\) injection.

Figure 44 shows the corresponding photographs of the x-ray maps of the same sample residue. Included are the x-ray maps showing uranium, fluorine, silicon, and oxygen. Again, it can be noted as in prior tests of this type, the dominance of both uranium and silicon. This was also concurred in by the IR spectrophotometric measurements.

Summary of Chemical Analyses of Deposited Residues

To permit a determination of the magnitude of the surface coating/etching/erosion that may have taken place on the surface of the inside diameter of the fused-silica tubes, a Taylor-Hobson (Talysurf k) profilometer, described in the Principal Equipment section, was employed. Figures 45 and 46 show an example of the results obtained from these measurements. After completing the majority of the rf plasma tests with UF\(_6\) injection discussed in the previous section with the accompanying degree of wall coating, the question arises as to the actual surface characteristics of the deposited residue; that is, is there indeed a combination of surface coating with accompanying etching and erosion that may have taken place on the fused-silica tube? The Taylor-Hobson profilometer is the instrument that was used to aid in providing the answer to this question. This particular instrument is a very sensitive surface measuring instrument which accurately traces the profile of surface irregularities with reference to an optical flat. Figure 45 illustrates the typical surface characteristics on the inner portion of the fused-silica tube after exposure to the test conditions of case 11 shown in TABLE III. In this particular test, a UF\(_6\) mass flow rate of 0.05 g/s was used for a test time of 5 minutes. Figure 45(a) is a photograph of a cross section of the tube and the associated coating. The nominal maximum thickness recorded using the profilometer in a series of these measurements was approximately 1 µm. The profilometer trace shown in Fig. 45(b) is from the local area with maximum residue on the inner surface of the fused-silica tube. For this measurement a diamond stylus was traversed
axially across the selected section of the surface of the tube by the motorized
drive unit and the up and down movement of the stylus relative to the optical flat
was electronically recorded on the strip-chart trace shown in Fig. 45(b). The
maximum amplification of this particular instrument is $10^5$. It was calibrated
relative to an NBS optical flat standard prior to the measurements taken on the
fused-silica tube. As can be noted from Fig. 45 and also Fig. 46, which is a trace
obtained using an expanded scale, the measurements indicate that a definite surface
etching with possible combined etching and erosion had occurred in addition to the
local deposition of small quantities of material onto the tube. This analysis
technique, therefore, can complement the other techniques used in identifying the
nature of the deposited residues.

The secondary ion mass spectrometer technique is another example of a powerful
analysis apparatus which was employed in this particular test program. A 3M ion-
scattering spectrometer, details of which are discussed in the Description of
Principal Equipment section, was used. In this technique a primary beam of ions is
directed at the surface being studied at fixed energies (less than 3 kv). Some of
these ions are scattered into an electrostatic energy analyzer mounted at a fixed
angle relative to the incident ion beam. Experimentally one finds that some of the
atoms and compounds sputtered from the surface by the primary beam are ionized
(secondary ions) and these ions are then analyzed in the mass spectrometer. The
sputtered yield and the degree of ionization both depend on the ion being measured
and the properties of the substrate. As a consequence, one needs reference
standards to do quantitative work with the secondary ion mass spectrometer (SIMS).
Figure 47 is an example of the surface chemical analysis of the uranium compound
residue obtained using the SIMS system. Figure 47(a) shows a commercially prepared
pure uranyl fluoride ($\text{UO}_2\text{F}_2$) reference standard. The atomic mass units (AMU)
corresponding to the various elements and compounds are shown on the abscissa (for
example, $238\text{-U}^+$, $254\text{-UO}^+$, $257\text{-UF}$, $270\text{-UO}_2^+$, etc.). Figure 47(b) shows an example of
the SIMS output obtained using a residue sample from a rused-silica tube after an
rf plasma test with pure UF$_6$ injection. This particular sample was prepared from
the water soluble residue which was treated with nitric acid (HNO$_3$) to drive off
the HF and then reheated to form the oxide. In both Figs. 47(a) and (b) the
penetration depth was several hundred angstroms. The results obtained using the
SIMS instrumentation agreed with those obtained using the other analysis techniques
and provides a complementary system for use in future tests.

Figures 48 and 49 show examples of several pertinent IR transmission scans
obtained using the IR Spectrophotometer System. Included are the results obtained
from several small samples of residue removed from different sections of the test
chamber after selected rf plasma tests with pure UF$_6$ injection; Figs. 48(a), (b),
(c) show the standards for the uranyl fluoride, the silicone grease, and the Kel-F
oil as used on the O-ring seals. Figure 49 shows examples of the IR spectropho-
metric absorption measurements taken of samples from the surface of the UF$_6$
injector, endwall, thru-flow exhaust duct, and axial bypass exhaust duct. In all cases, the
predominance of the $UO_2^{++}$ (uranyl cation) was observed. The residue removed from the surface of the endwall contained more of an indication of silicone grease than that removed from other sections. This was anticipated due to the closeness of the O-rings to the endwall and the secondary flow effects that exist in this region.

Chemically-pure standard samples of uranium compounds and other reaction compounds possible in the hot flow rf plasma tests with pure $UF_6$ injection were also analyzed and cataloged using a thin wafer KBr matrix preparation technique. Refer to APPENDIX C for additional discussion. TABLE VI lists the various samples now available within our laboratory with an indication if the compound displays a distinguishable spectrum. In several of the earlier rf plasma tests with pure $UF_6$ injection, the whitish residue found on the fused-silica tube was relatively water soluble. This has since been identified as primarily uranyl fluoride ($UO_2F_2$) and shows up in the IR spectrum as $UO_2^{++}$ (uranyl cation). In some of the tests, an indication of silicone grease was observed to be present on the fused-silica tube and/or endwall surface (see Fig. 49(b)). As discussed previously, changing the O-ring sealant material from silicone grease to Kel-F oil has resulted in reduced contamination due to the silicone products. Because uranyl fluoride ($UO_2F_2$) was the principal constituent found in the residue on the fused-silica tubes in the majority of the rf plasma tests with pure $UF_6$ injection, figures 50 and 51 show electron photomicrographs and photographs of the x-ray maps taken of the standard reference material uranyl fluoride ($UO_2F_2$) as commercially received (separate batches were also prepared at UTRC). Different magnifications were employed ranging from 2400X to 6000X, as shown, and the obvious appearance of the relatively strong concentration of uranium indicated by the white area in Fig. 51 is evident.

To permit positive identification of elemental uranium in the residue deposits found in the exhaust duct (axial bypass portion) by an alternate analysis (compared to the scanning electron microprobe), uranium absorption spectra of the water soluble portion of the residue from the axial bypass exhaust duct is shown in Fig. 52(a). For comparison, Fig. 52(b) shows the standard absorption spectrum of uranium in aqueous solution as reported in Ref. 11. These standard reference data have also been duplicated in recent tests conducted at UTRC. Both the wavelength position and molar extinction coefficient amplitude are important in accurately defining the constituent.

After completion of the above analysis, another sample of the residue was added to water, stirred, and filtered through a 5 μm teflon filter. After being thoroughly mixed and left setting for several hours, no > 5 μm size particles were collected. The original weight of the deposit was 61.8 mg. 61.6 mg was the measured weight of the soluble portion. The weight of U (soluble portion) was 44.2 mg; the weight of F (soluble portion) was 11.4 mg. The corresponding mole ratio is $UF_3.2$. From the above data and assuming that U and F are present as $UO_2F_2$ and $UF_4$, then the sample consists of 22.1 mg of $UO_2F_2$ and 36.8 mg of $UF_4$; the total combined weight would be 58.9 mg. In this calculation, 2.9 mg of $H_2O$ was assumed present to give the correct mass balance. Reference 12 gives the solubility of $UF_4$ as between $1 \times 10^{-4}$ (≈ 31 mg) and $3 \times 10^{-4}$ (≈ 93 mg) mole/l at 25 C.
To illustrate the overall correlation of the various diagnostic techniques used to analyze the sample residue which appeared on the various components in the test chamber, Figs. 53 through 67 are examples highlighting some of the results. The overall results obtained in this final series of tests in the 1.2 MW rf induction heater facility concurred with the results from the early exploratory tests discussed in APPENDIX D. The exception to this is shown in Fig. 53, wherein additional x-ray diffraction patterns obtained from the post-test analysis of residue on the inside of the fused-silica tube after rf plasma tests with pure UF₆ injection indicated crystalline YUO₃ to be present. YUO₃ is a monoclinic form of the oxide of uranium not noted to be present in the earlier tests. As shown in Fig. 53, this was observed to be present in both low and high UF₆ flow rate tests. It appears that YUO₃ becomes more highly crystalline at the higher UF₆ flow rate conditions. Also shown in Fig. 53(c) is the x-ray diffraction pattern of a sample taken from the endwall indicating a highly amorphous degenerate pattern but again with the beginnings of YUO₃ appearing. All other results agreed well with the previous analysis reported in APPENDIX D. Figure 54 shows an example of the electron diffraction analysis conducted on dispersed powder from the UO₂F₂ standard reference. This can be compared with the electron photomicrographs shown in Figs. 50 and 51. Figures 55 through 57 are examples of the analysis conducted using the electron microprobe and electron diffraction techniques applied to the sample residue removed from the central portion of the endwall after an rf plasma test with pure UF₆ injection. A back-scattered electron micrograph is shown in Fig. 55(c), which illustrates the typical topographical variations present. This sample case was near the central portion of the right endwall adjacent to the UF₆ injector. Figure 56(a) through (d) shows the accompanying x-ray maps corresponding to uranium, fluorine, copper, and oxygen, respectively. At a magnification of 300X, the predominance of uranium, as shown by the white area, is again evident. In Fig. 57, the corresponding electron diffraction analysis results are shown obtained from the same endwall sample. Figure 57(a) shows two highly magnified photographs of the residue (to illustrate the crystallinity) and Fig. 57(b) are the corresponding electron diffraction patterns obtained from the same sample. In this case the amorphous structure of the material can be noted in the electron micrographs; the presence of UF₄ and UO₂ is apparent. Due to the close similarity in the line spacings for both UO₂ and U₄O₉, as taken from the American Society of Testing Materials x-ray card file, exact identification between the two could not be made.

Figures 58 through 60 are some examples of electron photomicrographs, x-ray maps, and the corresponding electron diffraction patterns obtained from a sample residue removed from the UF₆ injector after an rf plasma test with pure UF₆ injection. The sample residue was taken from the area near the tip of the UF₆ injector. Figure 58 illustrates (at several different magnifications) the topographical variations present. Comparing Fig. 58 with Fig. 55, the obviously different topographical variations become apparent. Figure 59 shows the corresponding photographs of the x-ray maps of this sample from the UF₆ injector. The presence of uranium, as shown in Fig. 59(a), is again apparent and predominates over the fluorine and oxygen.
However, in this case, the x-ray showing copper (Fig. 59(c)) indicates an apparent presence of a significant amount of copper. Care was taken in preparing these samples not to scrape off any metallic copper from the outside surface of the UF₆ injector. Copper tubing is the prime constituent of the UF₆ injector. Figure 60 shows examples of the electron diffraction patterns obtained from the same sample residue and photographs of the corresponding samples at moderate and high magnification. An amorphous material was present in addition to UF₄, UO₂, and αUO₃, and single crystals of an unknown compound. UO₂ and αUO₃ are difficult to identify due to the overlap in the d-spacings of these compounds and those shown in the lower left portion of Fig. 60 (i.e., U₄O₉ and U₃O₈).

To give an indication of the type of residue obtained from the on-axis thru-flow exhaust duct after a hot flow test with UF₆ injection, Figs. 61 and 62 are examples of the electron photomicrographs obtained and the corresponding x-ray maps. Again, note the different topographical variations occurring when compared with the x-ray maps shown in Figs. 55 and 58 corresponding to residue material obtained from the endwall assembly and UF₆ injector, respectively. The results indicate a pattern similar to that obtained from the endwall residue results, as shown in Fig. 56, where the predominance of uranium set in a trace background of fluorine, oxygen, and copper is apparent. It was expected that the residue samples removed from the axial bypass exhaust duct to be somewhat different than those removed from the on-axis exhaust duct; the reason being attributed to the distinct different in temperatures. The temperature of the thru-flow exhaust duct is considerably higher than that in the axial bypass (approximately a factor of 5-10X). To determine the possible effect of the axial downstream location in the duct itself on the residue characteristics, Figs. 63 through 66 are examples of the electron photomicrographs and the corresponding x-ray maps of residue samples removed from the axial bypass exhaust duct for positions both near and far from the endwall assembly. The difference was approximately 20 cm. A comparison can also be made between the results of the residue samples obtained from the on-axis thru-flow exhaust duct and those obtained from the axial bypass exhaust duct at two different axial locations. The hotter exhaust temperature in the on-axis thru-flow exhaust duct combined with the heat exchangers result in a rather rapid quench effect. This is apparent in the more amorphous structure observed in Fig. 61 corresponding to the sample residue from the on-axis thru-flow exhaust duct. There also is a difference in the morphology structure relative to axial position in the exhaust ducts from where the sample was taken. This can be noted when comparing Figs. 63 and 65.

Figure 67 shows examples of the x-ray diffraction patterns obtained from the post-test analysis of the sample residue obtained from the on-axis thru-flow exhaust duct and the axial bypass exhaust duct using x-ray diffraction analysis techniques. In both cases, the amorphous pattern observed was comprised principally of U₃O₈. For comparison, a UO₂F₂ standard reference sample is indicated at the bottom of Fig. 67.
Upon comparing the results of all the various analysis techniques employed to date, it becomes apparent that a direct one-to-one comparison is not easily accomplished. Part of this is attributed to the statistical nature of sampling and comparing the various samples with the different analysis schemes. Reproducibility of the test conditions from test-to-test is reasonably good; however, the portion of the test components where samples are removed may vary slightly from test-to-test.

In general, the following trends were observed. $\text{UO}_2\text{F}_2$, $\text{UO}_2$, $\text{SiO}_2$, and a trace of $\text{YUO}_3$ were identified as residue constituents on the fused-silica tube peripheral wall. $\text{UF}_4$, $\text{UO}_2$, and $\text{UO}_2\text{F}_2$ were identified as residue constituents on the endwall surfaces. The same constituents were identified as being present on the $\text{UF}_6$ injector; in addition, $\alpha\text{UO}_3$ was also detected. The electron microprobe x-ray maps also showed the distinct presence of Cu in quantities comparable to the U. The exhaust ducts contained traces of $\text{UO}_2\text{F}_2$, $\text{U}_3\text{O}_8$, and $\text{UF}_4$. The electron photomicrographs of the various samples of residue removed from the different components each possessed a different crystalline structure. The analysis techniques developed and applied during this portion of the research program will be applicable to future experiments which include development of techniques for reconstituting the gaseous compounds in the plasma exhaust mixture, minimizing the wall coating, and conditioning the exhaust gas such that it is in a form suitable for reinjection into the plasma (recycled-closed-loop operation).
REFERENCES


REFERENCES (Concluded)


LIST OF SYMBOLS

A  Absorption coefficient, arbitrary units
AMU  Atomic mass unit, dimensionless
c  Speed of light, 3x10^8 m/s
E  Emission coefficient, arbitrary units or x-ray energy, Kev
E_{i,n}  Energy of n^{th} level in ionization species i, cm^{-1}
f  Rf operating frequency, MHz
\Delta f  Doppler line width, nm
\xi_{i,n}  Statistical weight of n^{th} level in ionization species i
I_0  Incident or source intensity, arbitrary units
I/I_0 or I/I_A  Transmission, dimensionless
\log_{10}(I/I_0)  Absorbance, dimensionless
I_{\lambda}/I_{0\lambda}  Internal transmittance, dimensionless
k  Boltzmann constant, 1.38x10^{16} erg/deg K
L  Path length, cm
\ell  Liters
m  Particle mass, g
\dot{m}_{AR}  Argon mass flow rate, g/s
\dot{m}_{UF_6}  UF_6 mass flow rate, g/s
N  Uranium total number density, atoms-cm^{-3}
N_A  Atom number density, atoms-cm^{-3}
N_i  Number density of species i, atoms-cm^{-3}
LIST OF SYMBOLS (Continued)

<table>
<thead>
<tr>
<th>Symbol</th>
<th>Description</th>
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<tbody>
<tr>
<td>( N_{\text{UI}} )</td>
<td>Number density of neutral uranium atoms, ( \text{atoms} \cdot \text{cm}^{-3} )</td>
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<td>( N_{\text{UII}} )</td>
<td>Number density of singly-ionized uranium atoms, ( \text{atoms} \cdot \text{cm}^{-3} )</td>
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<td>Total uranium atoms confined per unit plasma length, ( \text{atoms/cm}^3 \cdot \text{cm}^{-1} )</td>
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<td>( N_x )</td>
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<td>( P )</td>
<td>Pressure, atm, ( \text{mm Hg} ), or torr</td>
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<td>( P_c )</td>
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<td>W</td>
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<td>Partition function for ionization species i, dimensionless</td>
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<td>(\lambda)</td>
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<tr>
<td>(\varepsilon, \alpha, \gamma)</td>
<td>Designation of different crystalline forms of uranium compounds</td>
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APPENDIX A

SUPPORTING X-RAY ABSORPTION MEASUREMENTS OF URANIUM CONFINED IN RF-HEATED PLASMAS WITH PURE UF₆ INJECTION*

This APPENDIX summarizes the exploratory x-ray absorption tests conducted using argon rf plasma discharges seeded with pure UF₆. These tests complemented the tests reported in APPENDIX D and the main portion of this report. The objectives were: (1) to develop an x-ray absorption method for measuring the amount of uranium confined in high-density, rf-heated uranium plasmas; (2) to fabricate equipment to accomplish those measurements; and (3) to integrate this method with rf plasma tests to demonstrate use of this equipment.

To accomplish this the following was included: a mockup test assembly to simulate the system to be used for measuring uranium density in the rf-heated uranium plasma tests was fabricated and tested; argon, UF₆, and argon-UF₆ mixture x-ray absorption measurements to develop and calibrate the system for measuring uranium density in the plasma tests were conducted; a test chamber for rf plasma tests which accommodates the x-ray measurement system was fabricated; the measurement system was installed and calibrated (with room temperature argon) in the 1.2 MW rf-induction heater facility; initial argon and argon-UF₆ mixture absorption measurements were conducted during rf-heated argon-only and argon-pure UF₆ injection plasma tests.

Estimates to determine the amount of x-ray absorption by uranium for a range of x-ray energies indicated that absorption of 3 to 25 KeV x-rays can be used to determine amounts of uranium at densities of interest (3 x 10¹⁶ atoms/cm³ to 3 x 10¹⁸ atoms/cm³).

Detailed calculations were made to determine the amount of x-ray absorption by uranium for x-ray energies of 4.8, 8, and 17.8 KeV. These energies are characteristic of the emission from titanium, copper, and molybdenum x-ray target materials, respectively. The variation of the fraction of x-rays transmitted with uranium number density is shown in Fig. 68 for 10 and 15 cm path lengths. Path lengths of 10 and 15 cm are typical of those used in tests in the 80 kW and 1.2 MW rf-heater facilities, respectively. The results shown in Fig. 68 indicate that x-rays from a copper target may be used to measure the density of uranium atoms, over the range of densities which are of interest in the plasma core reactor experiments. A mockup test assembly was fabricated to simulate the system to be used for measuring uranium density in the rf-heated uranium plasma experiments (the test assembly is shown in Fig. 69).

*Tests were conducted by Richard C. Stoeffler.
Preliminary experiments were conducted using a UTRC (nonportable) x-ray spectrometer. In these tests, UF₆ gas was the source of uranium atoms and was contained in a 2.5 cm-ID by 15 cm-long cylinder with 0.125 mm-thick Mylar windows on each end. The amount of x-ray absorption by the uranium atoms was determined by comparing the x-ray signal transmitted through the chamber containing UF₆ with that transmitted through a physically identical chamber which was evacuated. The intensity of x-rays transmitted through the test chambers were measured using a Norelco scintillation detector employing a thallium activated sodium iodide crystal and a Tennelec Model TC 216 amplifier - pulse height analyzer and counter-timer.

X-ray absorption measurements were made for UF₆ pressures from approximately 1 to 100 mm Hg corresponding to uranium densities of approximately \(3.3 \times 10^{16}\) atoms/cm³ to \(3.3 \times 10^{18}\) atoms/cm³, respectively. The measured fraction of x-rays transmitted are compared with the transmission calculated for UF₆ using Beer's law in Fig. 70. The experimentally determined values of transmission are given by the circular symbols and calculated transmission for UF₆ is given by the solid curve (the absorption by the fluorine was calculated to be approximately 2.5 percent of that by the uranium). The UF₆ pressure was measured using a pressure gage except for the data at the highest pressure. For this data point the pressure was not measured directly but was calculated to be between 76 mm Hg and 140 mm Hg from calculations based on residual pressures after removal of known volumes of UF₆ from the test chamber. The data indicate that agreement between calculated and measured transmission was good and tend to confirm that the characteristic x-rays from a copper target x-ray tube can be used to measure uranium densities from \(3 \times 10^{16}\) atoms/cm³ to \(3 \times 10^{18}\) atoms/cm³.

System for X-ray Absorption Measurements

The system used to make UF₆ and argon x-ray absorption measurements during calibration and rf-heated uranium plasma tests is shown schematically in Fig. 71. The system consists of the x-ray generator, the test chamber for containing the test gases (argon, UF₆, and argon-UF₆ mixtures), and the x-ray detection components. The x-ray generator consists of a DiaNo Corporation CA 8-S/copper x-ray diffraction tube with an XRD-6 x-ray power supply and controller supplied by single-phase 220 V/40 A service through a 7.5 kVA isolation transformer. The emitted x-rays from the target pass through a collimator with a vertically oriented 0.125 mm-wide slit and are reflected at the Bragg angle for 8 KeV (\(\lambda = 0.154\) nm) x-rays from a magnesium oxide (MgO) crystal monochromator before passing through the test chamber. The test chamber consisted of a 5.7 cm-ID fused-silica tube with metal endwalls. The endwalls contained ports for supplying and exhausting test gases and x-ray viewing ports having windows which appear almost totally transparent to 8 KeV x-rays. The distance between the windows was 22.4 cm. The x-rays were detected using a Norelco scintillation
detector (photomultiplier tube with a thallium-activated sodium iodide crystal mounted in a light-tight enclosure at the window end) with a high voltage 0.9 kV regulated dc power supply. A Tennelec TC 216 linear amplifier and single-channel analyzer was used to process the output signal from the scintillation detector and to provide an input signal into a Tennelec TC 545 counter-timer and a TC 590 rate meter. The rate meter output signal was recorded using a strip-chart recorder. In most tests, the x-ray intensity was obtained directly from the rate meter; however, in some tests conducted earlier in the program, the intensity was determined from the output of the counter-timer. The scintillation detector output was also displayed on an oscilloscope. The rate meter and oscilloscope signals were used as visual aids during alignment of the components of the x-ray measurement system.

**Description of Chamber-Crystal-Slit System and Procedure Used in Calibration Tests**

The details of the test chamber and the chamber-crystal-slit arrangement used during calibration tests are shown in Fig. 72(a) and the photograph in Fig. 73. The test chamber consisted of a 5.7-cm-ID fused-silica tube and two copper endwalls. The x-ray beam from the x-ray collimator (having a 0.025-mm-wide vertically-oriented slit) was reflected at the Bragg angle for 8 keV x-rays parallel to the chamber axis through 6.35-mm-dia ports located in each endwall. The ports were sealed using 0.125-mm-thick Mylar windows. X-rays transmitted through the far port are detected through two 0.635-mm-wide slits (vertically-oriented) spaced 1.58-mm apart, using the scintillation detector. During these tests, the crystal was located approximately 3.8 cm from both the exit of the x-ray collimator and the near viewing port window and, the 0.635-mm-wide slots were located approximately 2.54 cm and 12.7 cm from the far viewing port window and detector, respectively (as measured along the beam path). A mechanism for adjusting the width of a horizontally-oriented slit located between the crystal and near viewing window is shown in the photograph of Fig. 73. This slit was not used during the calibration and rf plasma tests.

Calibration tests were made, using this test chamber-crystal-slit system, with pure argon, pure UF₆, and argon-UF₆ mixtures at 300 K in the test chamber. During tests with pure argon or pure UF₆, x-ray absorption was determined by comparing the x-ray intensity, Iₒ, obtained with the chamber evacuated to the x-ray intensity, I, obtained with the chamber at known pressures of argon or UF₆. Absorption measurements were made for argon pressures from 5 mm Hg (1.7 x 10¹⁷ atoms/cm³) to 700 mm Hg (2.4 x 10¹⁹ atoms/cm³) and UF₆ pressures from 5 mm Hg (1.7 x 10¹⁷ atoms/cm³) to 86 mm Hg (2.9 x 10¹⁸ atoms/cm³). The following procedure was used in the calibration tests with UF₆-argon mixtures. Iₒ was measured with the chamber evacuated. The chamber was filled with UF₆ to a known pressure (UF₆ pressure ranged from 5 mm Hg to 52.5 mm Hg). Argon was added to the chamber at partial pressures in steps up to 700 mm Hg. At each step the intensity, I, was measured. The absorption
by UF$_6$ was determined by comparing $I$ for each UF$_6$ and argon partial pressure with
the intensity $I_0$ multiplied by $I/I_0$ for the partial pressure of argon as calculated
from Beer's law. Two techniques were used to make the absorption measurements:
(1) the system was aligned with the crystal positioned to maximize $I_0$ as detected
through either of the two 0.635-mm-wide far slits, and with the crystal position
fixed, the intensity $I$ was measured as the chamber pressure was varied; (2) with the
system aligned as in (1) the crystal was traversed perpendicularly to the chamber
axis so that the x-ray beam scanned the width of the viewing ports and the maximum $I$.

Description of Chamber-Crystal-Slit System
and Procedure Used in RF-Heated Plasma Tests

The details of the test chamber and chamber-crystal-slit arrangement used during
the rf-heated plasma tests are shown in Fig. 72(b) and the photograph in Fig. 74.
The rf-heated plasma test configuration differed slightly from that used during the
 calibration tests. The system was arranged so that the x-ray beam traverses the
plasma core region diagonally (path length equal to 23.0 cm), passing through the
chamber axis where the maximum uranium density is expected to occur. Accordingly,
6.35-mm-wide by 19-mm-long x-ray viewing ports were located in the endwalls, as
shown in Fig. 72(b), to allow passage of the x-ray beam. During these tests 0.105-
mm-thick beryllium windows were used to seal the viewing ports. X-rays transmitted
through the far port were detected by the scintillation detector through a 0.635-mm-
wide vertically-oriented slit mounted on the face of the detector. The crystal was
located approximately 12.7 cm and 4.4 cm from the exit of the x-ray collimator
(with 0.025-mm-wide vertically-oriented slit) and near viewing port window, respec-
tively. The 0.635-mm-wide slit mounted on the face of the detector was located
approximately 4.6 cm from the far viewing port. The crystal position was fixed
during rf-heated plasma tests.

This test chamber-crystal-slit system was calibrated using pure argon and the
procedure described previously for a fixed crystal position. Argon absorption
measurements were made for argon pressures from 50 mm Hg ($1.7 \times 10^{18}$ atoms/cm$^3$) to
1790 mm Hg ($5.8 \times 10^{20}$ atoms/cm$^3$).

The following procedure was used to determine uranium density from x-ray
absorption measurements in an rf-heated uranium-argon plasma using the 1.2 MW rf-
induction heater system. The x-ray intensity, $I_0$, was measured with the test chamber
evacuated. Argon was injected tangentially (through vortex injectors shown in Fig.
72(b) into the test chamber and exhausted to vacuum through an axial thru-flow exhaust
and axial bypass exhaust ducts. The chamber pressure was maintained at 10 mm Hg until
the rf discharge was initiated and then increased to the pressure used for operation
with UF$_6$ injection, approximately 1.7 atm. The variation of x-ray intensity, $I_A$,
with amount of rf power supplied to the rf-heated argon plasma was measured (rf
power was varied from 30 kW to 56 kW). UF$_6$ was injected axially into the test
chamber using the UF₆ transfer system described in the main portion of this report and the variation of x-ray intensity, I, with UF₆ flow rate was measured (UF₆ flow rate was varied from 0.013 g/s to 0.134 g/s). UF₆ density was determined by computing the ratio \( I/I_A = (I/I_o)/(I_A/I_o) \) (for comparable rf power levels) and using Beer's law, \( I/I_o = e^{-\mu N_i L} \) where \( \mu \) is the absorption cross section for uranium in cm²/atoms, \( \mu = 1.12 \times 10^{19} \) cm²/atom for uranium and 8.0 KeV x-rays), \( N_i \) is the number density in atoms/cm³, and \( L \) is the path length in cm. During some tests with a pure argon plasma the variation of \( I_A \) with pressure level in the test chamber was measured and the ratio of \( I_A \) to \( I_o \) was used with Beer's law and the perfect gas law to calculate average argon temperatures.

Results From Calibration Tests With Pure Argon

Calibration data obtained using the calibration system (Figs. 72(a) and 73) and the rf-heated plasma system (Figs. 72(b) and 74) and pure argon at 300 K are presented in Fig. 75. The measured variation of fraction of x-rays transmitted, \( I/I_o \), with variation in argon pressure, \( P_A \), was compared with the theoretical variation calculated using Beer's law and the perfect gas law. Data obtained using the calibration system by traversing the crystal and with the crystal fixed are given by the circular and square symbols, respectively. The intensity ratios obtained for a given argon pressure by traversing the crystal (one for each of the two slits) were in good agreement, generally differing by less than 10 percent. Data obtained using the rf-heated plasma system with the crystal position fixed are given by the triangular symbols. Agreement between experiment and theory is good for intensity ratios up to approximately 10⁻² (argon pressures up to approximately 900 mm Hg). At pressures greater than 900 mm Hg the argon appears (except for one data point) less dense than that predicted using Beer's law. It is possible that the x-ray beam is not monochromatic and that at large values of absorption, \( I/I_o \) less than 10⁻², the intensity of high-energy components (possibly harmonics) in the beam becomes important relative to the intensity of the primary component (absorption decreases with increasing x-ray energy) making the measured argon density appear less than that given by theory. It would be possible to operate at argon pressures greater than 900 mm Hg and intensity ratios greater than 10⁻² by using an x-ray tube having a target such as molybdenum which emits x-rays having energies (17.8 KeV) greater than those emitted from a copper target x-ray tube. However, measurement of uranium densities near \( 10^{16} \) atoms/cm³ would be more difficult (theoretical \( I/I_o = 0.992 \) for 17.8 KeV x-rays compared with 0.974 for 8 KeV x-rays).
Results From Calibration Tests With Pure UF₆

Calibration data obtained using the calibration system (Figs. 72(a) and 73) and pure UF₆ at 300 K are presented in Fig. 76. The measured variation of fraction of x-rays transmitted, I/I₀, with UF₆ pressure, PUF₆, is compared with the theoretical variation. Data obtained using the calibration system by traversing the crystal and with the crystal fixed are given by the circular and square symbols, respectively.

During these tests the UF₆ canister was depleted and it was necessary to replenish it. Data obtained before the UF₆ was replenished are given by the open symbols in Fig. 76 and are in good agreement with theory. During initial tests conducted after the UF₆ was replenished, the system was contaminated (apparently with HF since the quartz test chamber and pressure gage glass were etched) and apparent uranium and fluorine compounds were deposited in the system (white "mist" deposits on inside of quartz tube are evident in Fig. 73). During subsequent calibration tests, it appeared that the injected UF₆ reacted with the contaminants in the system resulting in a reduction of UF₆ density with time and, therefore, an increase in x-ray intensity with time. The data obtained during these tests are denoted by the solid symbols in Fig. 76 and have been corrected for the time-wise drift in x-ray intensity. These data are also in good agreement with theory; however, the discrepancies between experiment and theory are greater than those which occurred before the system was contaminated. In general, the agreement between data and theory is good. However, for intensity ratios, I/I₀, greater than approximately 10⁻² (UF₆ pressures greater than approximately 60 mm Hg) the UF₆ (as did argon) appears less dense than that predicted using Beer's law.

Results From Calibration Tests With Mixtures of Argon and UF₆

Calibration data obtained using the calibration system (Figs. 72(a) and 73) and mixtures of argon and UF₆ are presented in Fig. 77. Data obtained with the crystal stationary (unflagged symbols), the crystal traversed (flagged symbols), and before and after apparent contamination of the system (open and solid symbols, respectively) are presented for UF₆ partial pressures from 5 mm Hg up to 52.5 mm Hg and argon partial pressures from 0 to 700 mm Hg. In general, the data indicate fair agreement with theoretical intensity ratios. These data also indicate that the measured density of UF₆ decreases with increasing argon pressure and that this difference increases with increasing UF₆ pressure. This behavior would be expected, based on results obtained for pure argon and pure UF₆ (see Figs. 75 and 76), when the partial pressures of argon and UF₆ are such that the total fraction of x-rays transmitted is less than about 10⁻². The dashed curve through the data in Fig. 26 is the approximate locus for the total fraction of x-rays transmitted equal to 10⁻². For data located to the right of the curve the total fraction transmitted is less than 10⁻² and to the left greater than 10⁻².
For clarity, only data obtained at one slit location (obtained by traversing the crystal) are presented. At $P_{UF_6} = 15$ mm Hg the values of $I/I_0$ measured at the second slit location were up to 37 percent greater than those presented in the figure, and at $P_{UF_6} = 25$ mm Hg the values of $I/I_0$ measured at the second slit location were as much as 43 percent less than those presented. These data were obtained after contamination of the system and were corrected for the time-wise drift in x-ray intensity. However, the possibility of large errors occurring was greater during these tests because long test times were required to ensure complete mixing of the argon-$UF_6$ gas mixtures.

Results From RF-Heated Plasma Tests With Pure Argon

Data obtained using the rf-heated plasma system (Figs. 72(b) and 74) and pure argon are presented in Fig. 78. The measured variations of intensity ratio, $I/I_0$, with change in argon pressure are compared with theoretical variations. Comparisons are made for calibration data obtained with no plasma (solid symbols) (argon temperature equal to approximately 300 K) and with the plasma present (open symbols for tests in which rf power was measured, power is noted by the numbers near the symbols). Tests were conducted, with the plasma present, with all of the argon exhausted through the thru-flow exhaust (unflagged symbols) and with argon exhausted through both the thru-flow and axial bypass exhausts (flagged symbols). Data were obtained for argon plasma pressures from approximately 1.2 atm to 2.9 atm and rf-heated plasma power levels from approximately 30 kW to 56 kW. These data indicate, although the amount of scatter is appreciable, that $I/I_0$ increases with increasing rf power (increasing temperature and decreasing density) and decreases with increasing pressure (increasing density). The solid curves shown in Fig. 78 were calculated using Beer's law and the perfect gas law for argon at 300 K, 500 K, and 1000 K, 8 KeV x-rays, and a 23.0-cm-long path length. A comparison of the measured data with these curves indicates that the average temperature is approximately 500 K. The dashed curves shown in Fig. 78 were calculated for argon and 9.5 cm of path length at 2000 K, 5000 K, 10,000 K, and 15,000 K and 13.5 cm of path length at 300 K (hot plasma was assumed to occur between the end of the $UF_6$ injection probe (see Fig. 72(b)) and the endwall containing the exhaust duct). The remaining path length between the beryllium windows was assumed to contain 300 K argon. Comparison of the measured data with these curves indicates argon plasma temperatures which are not unrealistic; however, sensitivity is poor at high temperatures. Sensitivity could be increased by decreasing the amount of path length containing cold gas (i.e., mounting the beryllium windows nearer to the plasma). Also, the fraction of x-rays transmitted is very sensitive to temperature assumed for the cold argon. For example, at a $P_A = 1.7$ atm and a plasma temperature of 15,000 K, increasing the temperature of cold argon by 25 percent increases $I/I_0$ by 100 percent.
To average $I/I_0$ for argon at 1.7 atm which is the argon pressure for operation of the test chamber with UF₆ injection, is approximately 0.02. Therefore, UF₆ could be injected at densities up to $2.3 \times 10^{17}$ atoms/cm$^3$ (corresponding to about 7 mm Hg at 300 K) without decreasing the total intensity ratio to a value less than $10^{-2}$ (data presented in Figs. 75 and 76 indicate that at $I/I_0$ less than $10^{-2}$, UF₆ and argon appeared to be less dense than that predicted by theory).

Results From Tests With RF-Heated Uranium Plasmas

X-ray absorption measurements were made in a series of tests to determine uranium density in rf-heated uranium plasmas. During these tests, 3.2 g/s of argon were injected tangentially around the UF₆ which was injected axially at flow rates between 0.013 g/s and 0.134 g/s. The chamber pressure was maintained at 1.7 atm and the rf-power in the plasma increased from 38 kW at a UF₆ flow rate of 0.013 g/s to 75 kW at a flow rate of 0.134 g/s. The flow was exhausted through the thru-flow and axial bypass exhausts.

In some tests the rf-power deposited in the plasma with UF₆ injection was greater than that which could be maintained with a pure argon fixed buffer gas injection rate. To determine uranium density by comparing x-ray intensities obtained with and without UF₆ injection, it was necessary to isolate the effects of changes in rf-power level. The variation of intensity ratio, $I_A/I_0$, for pure argon, with amount of rf-power deposited in the plasma was measured and is shown in Fig. 79 (circular symbols). A straight line approximation is used to represent and extrapolate these data to rf-power levels which occurred during operation with UF₆ injection. The measured variation of intensity ratio, $I/I_0$, for argon-UF₆ mixtures with rf-power is also shown in Fig. 79 (square symbols with UF₆ flow rates in g/s given next to the symbols).

The intensity ratio $I/I_0$ was used with Beer's law for uranium to calculate the uranium number density. The variation of uranium number density with UF₆ flow rate is shown in Fig. 80. The variation is presented for assumed UF₆ path lengths of 23.0 cm and 9.5 cm (circular and square symbols, respectively). Corresponding rf-power levels are noted next to the symbols. These data indicate that the uranium number density increases with increases in UF₆ flow rate and that the rate of increase decreases for UF₆ flow rates greater than approximately 0.08 g/s. Maximum uranium densities of $1.65 \times 10^{17}$ atoms/cm$^3$ (path length = 23.0 cm) and $3.85 \times 10^{17}$ atoms/cm$^3$ (path length = 9.5 cm) were measured for a UF₆ flow rate equal to 0.093 g/s.
In some tests at UF₆ flow rates greater than approximately 0.093 g/s, the measured x-ray intensity decreased with time (for fixed test conditions) indicating that UF₆ or uranium compounds were being deposited on the beryllium windows. Further evidence that UF₆ or uranium compounds had been deposited on the windows was obtained in subsequent tests with pure argon after the UF₆ injection was stopped. X-ray intensity ratios were significantly less than those attained with pure argon prior to UF₆ injection. The data presented in Fig. 79 were obtained from tests in which the x-ray intensity obtained with UF₆ injection did not decrease with time (unflagged symbols) and from tests in which intensities obtained with pure argon subsequent to tests with UF₆ injection were approximately the same as intensities obtained prior to UF₆ injection (flagged symbols).

The x-ray absorption equipment and measurement techniques developed and tested were used to supplement the optical methods (described in main text) for determining the amount and distribution of uranium vapor confined in the uranium plasma within the operating range tested. For future rf uranium plasma tests in which the atom density of confined uranium may exceed levels greater than approximately 10¹⁶ atoms/cm³, the x-ray absorption scheme will be a required measurement technique.
In the case of cylindrically symmetric, optically thin (i.e., where photons emitted from the inner region of the plasma are not absorbed before reaching the outer boundary) plasmas, the relationship between the radial profile of the volume emission coefficient and the profile of the emitted intensity can be expressed in the form of an integral equation. The inverse of this equation can be obtained from the Abel inversion formula and several numerical techniques based on this formula have been developed (Refs. 14 and 15).

The problem of spatially resolving the volume emission coefficient when the source is not optically thin, using the transmission and emitted intensity profiles as input data, has been considered by a number of authors. If the plasma source is a cylindrical column with circular cross section, and the optical properties of the plasma depend only on $r$, the distance from the axis, Freeman and Katz (Ref. 16) and Elder (Ref. 17) have developed numerical methods for the solution. They have shown that the spatial distribution of the absorption coefficient is a prerequisite for the determination of the emission coefficient in an optically thick plasma. In this case, the radiative transfer equation is not an Abel equation, since the radial distribution of the absorption coefficient must be taken into account and solution for the emission coefficient is more difficult. The absorption coefficient can be determined from the attenuation of the intensity of the probing beam (dye laser beam in the case of the experiments reported herein) of radiation traversing the plasma source. The radiation emitted by the probed section of the source must be subtracted from the emerging radiation before the attenuation can be found. A key requirement is that the probing laser beam flux is greater than or equal to the emitted radiant flux. The availability of high power cw tunable single-frequency dye lasers which match and/or exceed the spectral radiance of the uranium plasma discharges of the type discussed herein satisfy this requirement.

Reference 18 describes a method utilizing an iterative procedure to find the radial distribution of the emission coefficient once the radial distribution of the absorption coefficient has been determined. At the pressures and temperatures used in the rf uranium plasma experiments reported herein, the assumption of local thermodynamic equilibrium is justified; thus, the temperature profile can be obtained directly from the emission and absorption coefficients by applying Kirchhoff's law. Kirchhoff's law states that the local ratio of the emission to absorption coefficients must be equal to the Plank function at that particular wavelength and at the local temperature.
The radial distributions of the emission and absorption coefficients were determined, as discussed in the main portion of this report, from two sets of side-on observations of the uranium plasma discharge made along different chords at distances \( r \) from the axis of symmetry. Reference 18 contains details of the formally convergent iteration technique that was used to obtain the spatial resolution of the volume emission and absorption coefficients for the case of the strongly self-absorbing uranium plasma. The employment of the powerful tunable dye laser system (narrow line monochromatic radiation) simplified the transmission profile measurements of the uranium plasma discharge. Alternative schemes such as the double-path method (Ref. 19) depend on the exact superpositioning of the source and reflected image; this would have been extremely difficult due to the physical constraints within the 1.2 MW rf induction heater test tank. An assumption that must be invoked in the application of this experimental technique is that the absorption coefficient must be approximately constant over the wavelength interval equal to the spectral slit width. Other assumptions are that the optical system is such that the dispersive element of the monochromator subtends approximately the same small solid angle from points along the chord through the plasma discharge and that the entrance slit-width of the monochromator is small compared to the plasma radius. Under these conditions, the system was calibrated absolutely by physically replacing the uranium plasma discharge with a calibrated standard source of spectral radiance (G.E. T/24-7) and comparing the two signals.

One area which required additional bench testing was the possible beam steering of the laser beam as it propagated through the test chamber and plasma source. Separate tests combined with a ray tracing analysis verified the degree of refraction present and the optical system was modified to account for this. The surface imperfections present on the surfaces of the fused-silica tubes were not uniform and therefore could not be compensated for in the lens and optical system. This effect was calibrated out for each particular test; i.e., once the rotational orientation of the two concentric fused-silica tubes was selected, they were maintained in that fixed orientation until completion of that particular test.

The phototube and optical system were calibrated using the G.E. T/24-7 lamp of known spectral radiance in place of the plasma discharge. All other components of the test chamber and monochromator/recording instrumentation remained unchanged. The signal at the photomultiplier (EMI-9558) tube operating at 900 V that correlates with the radiance was measured. The spectral radiance of the G.E. T/24-7, EPI#EPUV-1048, operating at 30 amp and at 591.5 nm was 21.3 \( \mu \text{W}\cdot\text{mm}^{-2}\cdot\text{nm}^{-1}\cdot\text{St}^{-1} \). The power incident on the detector was calculated according to the relationship:

\[
P(W) = R_{\lambda}\Omega\cdot A(\text{mm}^2)\cdot\Delta\lambda(\text{nm})\cdot\Omega(\text{St})\cdot\epsilon;
\]

where, \( P(W) \) is the power incident on the detector, \( R_{\lambda}\Omega \) is the spectral radiance at right angles, \( A \) is the area of the tungsten strip focused through the input slit of the monochromator, \( \Delta\lambda \) is the spectral width of the monochromator, \( \Omega \) is the solid angle of the optics, and \( \epsilon \) is the efficiency of the system. Note that \( \Delta\lambda \) is the full width at half maximum as measured with the monochromator using a low pressure mercury lamp as the light source. The Gaussian slit function of the monochromator was replaced with a
rectangular slit of full height and width equal to that of the spectral width of the monochromator. For the particular emission line used (591.54 nm), the power is concentrated in a much narrower line width (4.082 \times 10^{-3} \text{ nm}). The magnification of the overall optical system was 1.57. Thus, a 25 \mu m \times 25 \mu m square on the entrance slit of the monochromator viewed a 39 \mu m \times 39 \mu m square of surface area at the centerline of the plasma. The calibration factor for the phototube was then determined in terms of the power incident on the photomultiplier tube per unit voltage output. Note that the same optical system (see Fig. 13) was used for both the rf plasma tests and the source calibration tests; the solid angle of the optics and the efficiency were unchanged. This permitted determination of the relationship between the spectral radiance for the rf uranium plasma and the output voltage of the photomultiplier tube.
APPENDIX C
SUPPORTING CHEMICAL ANALYSES—REFERENCE STANDARDS—PROPERTY DATA ON FUSED SILICA AND AS-RECEIVED UF₆

One of the key components in the test chamber used throughout this test program was the fused-silica peripheral wall. The tubes used were purchased from U. S. Fused Quartz Corporation; this company was selected over several other competitors primarily due to price, availability, and quality control of the dimensional tolerances. TABLE VII lists the physical, thermal, electrical, and optical properties of the fused-silica tubes used in the experiments reported herein.

As additional improvements were made to the test chamber configuration and flow scheme, which in turn further reduced the residue material deposited on the various components, the purity level of the components themselves (in particular the fused-silica tube peripheral wall) became increasingly important. To provide an estimate of the purity of the fused-silica tubes used in the rf plasma experiments with pure UF₆ injection, spectrochemical data were obtained from U. S. Fused Quartz Corporation to permit a comparison with the analyses conducted at UTRC. TABLE VIII summarizes the results. Because of the possibility that the batch of fused silica used in the preparation of the as-received 5.7-cm-ID x 6.1-cm-OD fused-silica tubes may have been different than the reference standard fused silica, a separate analysis was also included. This is shown in the last two columns of TABLE VIII. The overall results indicate good agreement; actually the UTRC analytical results are more favorable for the case of the Al₂O₃ impurity constituent than those reported by U. S. Fused Quartz Corporation.

As part of the overall analysis of the fused-silica tubes, several comparisons were made to a reference standard relative to the degree of residual thermal stress observed to be present in the fused-silica tubes after tests using the rf plasma with pure UF₆ injection. Figure 81 illustrates the varying degree of thermal stress present which ranged from negligible to relatively high. In several of the exploratory tests with the rf plasma and pure UF₆ injection which were accompanied by a moderate degree of residue coating on the peripheral walls, post-test cracking of the tubes was noted. In all cases, this was attributed to the relatively high degree of residual thermal stress present in the central portion of the tube as observed using polarized light as shown in Fig. 81(b). The later tests in the series, wherein relatively small amounts of wall coating occurred, little or no evidence of residual thermal stress was noted and no post-test cracks occurred (see Fig. 81(d)).

As in the case of the fused-silica tube impurities, another possible contributing factor to the formation of the different types of compounds found in the post-test analysis of the residue material was the impurity level of the UF₆. Consequently,
an analysis was performed and an assay made on the as-received UF$_6$. TABLE IX summarizes the results. The impurity level of the various elements are indicated per million parts of total uranium. Note that the minimum weight percent of the UF$_6$ in the material was 99.98. The UF$_6$ was purchased through Allied Chemical Corporation in 2.2 kg batches.

To provide additional information on the possible influence of moisture, UF$_6$ contamination, O-ring sealant material, and temperature-time history on the etching/corrosion aspects of the fused-silica, a series of laboratory-scale tests were conducted. 350 cc vessels fabricated from the same batch of fused silica as used in the actual tests were subjected to different types of controlled tests. Part of the results are shown in the photograph of Fig. 82. Refer to TABLE X for the corresponding test conditions. The vessels were evacuated to $10^{-4}$ mm Hg prior to being filled with the small quantities of UF$_6$, as shown in Fig. 82. For test case I, shown in Fig. 82, 0.9 g of as-received UF$_6$ was transferred into the vessel. Immediately upon filling, a white snowflake-like mist appeared on the wall. After several minutes at room temperature, there was a partial transition to a yellowish/light green compound formation in the central region together with apparent etching at the end regions. Uniform application of heat (330 K for 1 hr) resulted in no noticeable change to the compound in the central region; sublimation of the white crystals was observed. Slow cooling followed by a room temperature soak for 72 hours resulted in a redeposition of the white crystals in the central region and a trace formation of a yellowish/green/brown deposit near the end region (adjacent to the stopcock used with the silicone grease). Evacuating the contents of the vessel after the long soak period left the white mist-like etching and the yellowish/green compounds; the white crystals disappeared. Post-test analysis using the IR spectrophotometer indicated the yellowish/green compound to be composed primarily of silicone grease, UO$_2$F$_2$, and H$_2$O. Analysis of the white mist-like etching portion revealed the compound to be primarily UO$_2$F$_2$, H$_2$O, and SiO$_2$; thereby supporting the observation that local etching had indeed occurred. The second test (see Fig. 82 and TABLE X) was similar to test I; however, Kel-F oil was used on the stopcock and the UF$_6$ was filtered by passing it through NaF anhydrous powder to remove the HF. A similar temperature time history was again employed in this test. The results indicated a very small amount of "whitish mist" (much less than the prior test) and no yellowish/green compound formation or coloration. The third test (see Fig. 82 III and TABLE X) used filtered UF$_6$, the standard silicone grease on the stopcock but included a vessel bake-out procedure prior to filling with 1.2 g of UF$_6$. After exposure to the same temperature-time history as the prior two tests, the post-test examination revealed the fused-silica tube to be relatively clear with some slight (pale green) coloration in the vicinity of the silicone grease interface. The final test (IV) used filtered UF$_6$, Kel-F oil on the stopcock, and included the vessel prebake-out procedure prior to filling with 0.9 g of UF$_6$. Exposure to the same temperature-time history as the prior three tests indicated the tube to be relatively clear with negligible discoloration in the vicinity of the stopcock. The overall test results indicated that noticeable etching occurred when as-received UF$_6$ was transferred into the vessels.
containing silicone grease on the transfer line stopcock and employing no vessel,
prebake-out procedure. The use of filtered UF₆ and Kel-F oil resulted in much less
etching, discoloration, and compound formation. Inclusion of a prebake-out proce-
dure to the vessels prior to filling with filtered UF₆ again helped to reduce the
etching/discholoration; however, this procedure was not practical in the rf plasma
tests due to physical constraints.

To assist in analyzing the wall deposition samples, Figs. 83 through 86 contain
examples of the compound standards used in the IR spectrophotometric absorption
measurements. Refer to TABLE III for a complete summary of all the material samples
used in the IR spectrophotometric analysis. A detailed cataloging of the possible
uranium compounds that may form with the associated diffraction pattern lines and
physical characteristics was also conducted and is shown in TABLE XI.

Due to the unavailability of experimental data on the corrosion aspects of hot,
pressurized UF₆, information was accumulated throughout this test program which will
also be applicable to future tests. Figure 87 shows an example of the rate of
corrosion in microns per hour as a function of temperature for different materials
exposed to relatively low pressure UF₆. The preferred use of Monel and nickel can
be seen when compared to the other materials. An example of the type of corrosion
observed during the test program reported herein is shown in Fig. 88. A small
0.005-cm-thick 316 stainless steel burst disc was used in the UF₆ transfer system,
as shown in Fig. 5. Photographs (a) and (b) of Fig. 88 show two different magnifica-
tions of the pressure side of the as-received disc. The photographs labeled (c) and
(d) in Fig. 88 are the corresponding areas after prolonged exposure to hot,
pressurized UF₆. The disc ruptured due to intergranular fracture induced by the
corrosion effect of the UF₆. Considerably more data will be required over a wide
range of operating conditions to fully document the possible corrosive effects that
long time exposure to hot, pressurized UF₆ can have on various materials. In the
tests reported herein, careful post-test inspection of the different components
provided a qualitative indication of the degree of corrosion taking place.
APPENDIX D

EXPLORATORY RF URANIUM HEXAFLUORIDE (UF₆)
SEEDED ARGON DISCHARGE EXPERIMENTS*

This APPENDIX summarizes the initial exploratory tests conducted at UTRC using argon rf plasma discharges seeded with pure UF₆ with application to future uranium plasma core reactor simulation experiments. The objectives were: (1) to investigate techniques for fluid-mechanical confinement of uranium plasmas with minimum deposition of uranium or uranium compounds on the peripheral wall of the test chamber; (2) to initiate the development and testing of materials and handling techniques suitable for use with high-temperature, high-pressure gaseous UF₆; and (3) to initiate the development of diagnostic instrumentation and measurement techniques to characterize the uranium plasma and deposited residue material.

Description of Equipment and Test Procedure

The majority of the experiments were conducted using a 80 kW rf induction heater system. Several initial follow-on test series were also conducted using a 1.2 MW rf induction heater system.

For the sake of continuity, the initial experiments conducted using the 1.2 MW rf induction heater will be discussed in this APPENDIX. A description of the facility can be found in the main portion of this report.

Figure 89 is a schematic diagram of the 80 kW rf induction heater system. A photograph of an assembled exploratory test configuration installed under the 2½ turn, 7.5-cm-dia, water-cooled rf work coil (0.7 μH) of the 80 kW facility is shown in Fig. 90. The easily modified work coil is connected to the output of the power amplifier by means of a tunable π-coupling network (Fig. 89). The initial system was modified to operate at 13.56 MHz and low-speed motor drives were installed on the plate and load tuning capacitors to aid in efficiently coupling rf power into plasmas having a relatively wide range of sizes and impedances (primarily due to the introduction of pure UF₆).

Figure 91 contains schematic diagrams of the various test chamber flow configurations employed in the exploratory tests conducted in the 80 kW rf facility. Different configurations were tested to permit selection of the flow geometry with the best confinement characteristics. A gas-cooled 5.7-cm-ID x 6.1-cm-OD fused-silica tube formed the peripheral boundary of the test chamber. A symmetrically-

*Part of the results from this exploratory research effort have been reported in Ref. 7.
arranged set of water-cooled endwalls spaced 10 cm apart formed the axial boundary of the test chamber. Argon was injected through a set of vortex injectors equally-spaced around the periphery of one or both endwalls to provide the confining flow. As shown in Fig. 9(d), some tests were conducted with the argon gas injected tangentially through hypo-sized injectors (ultrasonically-drilled) located within the fused-silica peripheral wall itself. The exhaust gases were removed through one or both endwalls using thru-flow ducts on the centerline and/or off-axis annular exhaust ducts.

To permit steady-state injection of pure UF₆ into the plasma, several types of concentric-tube, water-cooled copper injectors were fabricated and located concentrically within the on-axis thru-flow duct. UF₆ was selected as the form of uranium bearing compound for injection into the plasma because it could be supplied in a gaseous form. Earlier tests in previous research programs had indicated that injection of uranium in the form of small particulates was a more difficult technology. However, UF₆ is very reactive chemically and must be heated to be sure that it remains in the gaseous state and does not condense on the injector walls prior to entering the plasma test chamber. Therefore, special cleaning procedures, operating procedures, and heating and feeding techniques had to be employed. These included the use of steam augmentation and electrical heater assemblies throughout the UF₆ injector and feed systems to eliminate the possible condensation and subsequent plugging of the UF₆ feeder lines. As shown in Figs. 9(a) and 9(d), the UF₆ injector could be extended into the test chamber/plasma region to eliminate some of the end effects. The various test chamber flow geometries and combinations thereof, permitted a wide variation in the types of flow conditions obtainable with UF₆ injection. Based on the exploratory test results, the type of test chamber flow configuration shown in cross section in Fig. 92 was selected for transitional tests in the 1.2 MW rf induction heater system. This geometry has several attractive features (e.g., ability to vary the distribution of exhaust gas flow (axial bypass); ease of change in the injection area of the argon vortex injectors; and, ease of change in the location of the on-axis UF₆ injector).

As in the 80 kW rf tests, the axial length between endwalls was 10 cm. Because of the higher power, higher pressure, and associated radiation levels involved, a concentric set of water-cooled fused-silica tubes (in contrast to the single fused-silica tube peripheral wall shown in Fig. 92) were used as the peripheral wall. The inner tube was 5.7-cm-ID x 6.1-cm-OD; the outer tube was 6.5-cm-ID x 7.3-cm-OD. The water-cooled copper endwalls incorporated provisions for driving the vortex from one (or symmetrically from both -- not shown in Fig. 92) endwall. The other endwall had provision for removing the exhaust gas through an axial bypass on the periphery of the endwall, as shown in Fig. 92. Both endwalls have the option for removing varying amounts of the exhaust gas through the on-axis thru-flow ducts. The UF₆ injector, located on-axis and concentrically within one endwall, was fabricated from a 50-cm-long three concentric copper tube assembly. In the majority of tests, the injector
tip protruded into the test chamber. High pressure water (20 atm) heated to approximately 350 K via a steam heat exchanger flowed at 0.14 l/s between the concentric tubes of the UF₆ injector. This provided cooling relative to the hot plasma environment while still maintaining a high enough temperature in the injector to permit flow of the pressurized gaseous UF₆ without solidification and subsequent plugging in the UF₆ transfer line.

The total power deposited into the plasma was obtained from an overall test chamber heat balance by summing the power lost by radiation, power deposited into the annular coolant of the peripheral wall, power deposited into the endwall assemblies, power convected out the exhaust ducts, as well as, power deposited into the effluent gas heat exchanger and UF₆ injector assemblies.

The power radiated from the plasma was measured using a radiometer and chopper wheel assembly. Radiation within different wavelength bands was measured using various filters. The response of the thermopile with filters was calibrated using a standard source of spectral irradiance. The total power radiated from the plasma and in each wavelength band was calculated assuming isotropic radiation including allowance for blockage due to the rf work coils. The physical size and shape of the plasma was determined from photographs taken using various neutral density filters.

Figure 93 is a schematic of the diagnostic systems used in the exploratory rf plasma tests. A Jarrel-Ash 0.25-m Ebert monochromator and an EMI 9558 (S-20 response) photomultiplier detector was used to obtain spectral emission data between 300-700 nm. Twenty-five μm-wide entrance and exit slits were employed. These measurements were taken on-axis at the midplane of the test chamber. The scanning rate was 100 nm/min and the data were recorded on a strip-chart recorder; measurements were obtained for both argon only and argon plus UF₆ plasmas.

The optical measurements also included side-on absorption measurements using a cw single-frequency, tunable dye laser system. The feasibility of this technique was investigated in these exploratory tests as a possible means for determining the number density and spatial distribution of uranium vapor contained within the discharge boundary in future UF₆ rf plasma tests containing uranium vapor of heavy concentrations. Refer to the main portion of this report for a detailed description of the dye laser system. This technique is also compared with an x-ray absorption method for measuring the amount of uranium confined in the rf-heated uranium plasmas (results discussed in APPENDIX A).

In these exploratory tests, the laser beam (≈1.5-mm-dia) traversed the test chamber on the major axis at a distance 1 cm away from the tip of the UF₆ injector; the UF₆ injector extended 1 cm into the test chamber. This position was selected since prior rf plasma tests (argon only) included chordal scans at this location from which temperature profiles were determined.
UF₆ rf plasma exploratory tests conducted in the 1.2 MW induction heater facility did not include the dye laser system, but the argon-ion laser system operating at 514.5 nm was used for additional side-on absorption measurements taken on-axis at the axial midplane of the test chamber. The test setup was similar to that shown in Fig. 93.

To permit a preliminary analysis of the quantity and composition of the wall deposition incurred after several selected UF₆ rf plasma tests, samples of the wall residue were collected and analyzed by means of electron diffraction, x-ray diffraction, electron microprobe, and IR spectrophotometric techniques.

In general, the exploratory tests (80 kW and 1.2 MW) were first conducted with only argon injected into the test chamber. After sufficient time to establish equilibrium (also for the thermocouple outputs used in the calorimetric measurements to reach steady-state levels), pure UF₆ was injected for various time periods (typically, several minutes). Normally, a series of UF₆ tests were conducted with the same fused-silica tube prior to shutdown for post-test examination.

Discussion of Results

TABLE XII is a summary of the exploratory tests conducted using the 80 kW rf induction heater, including a brief description of the test chamber configuration and flow control scheme, range of test conditions, number of tests conducted, and pertinent comments applicable to each. A direct one-to-one comparison between each of the various configurations was difficult because of the different operating characteristics associated with each test. Also, due to time and cost constraints, each configuration by no means represents the optimum in design and sizing of the various components.

Based on the overall test results, the test chamber flow configuration shown in Fig. 91(a) was selected as the one best-suited for use in the initial rf plasma tests employing the 1.2 MW rf induction heater system. With this configuration, a relative maximum mass flow rate of pure UF₆ injected directly into the argon plasma was achieved with corresponding light wall coating, thus offering potentially the best confinement characteristics. In addition, this test chamber flow configuration possesses significant flexibility in the control of the flow field and exhaust gas distribution as described previously.

To illustrate the effect of the pure UF₆ injection on the plasma discharge, Fig. 94 shows the operating conditions and results of corresponding radiation measurements for a typical exploratory test. In the majority of tests, attempts were made to maintain constant as many of the independent variables as possible during the injection of UF₆. However, changes in the rf power and/or tuning and associated
flow rates were sometimes required to prevent discharge extinguishment or plasma oscillations. In general, the introduction of pure UF₆ into the discharge significantly altered the impedance of the plasma which, in turn, determined the plasma size and electrical conductivity. Figure 95 is a photograph taken in the exploratory test series of a typical rf plasma with pure UF₆ injection. The introduction of the UF₆ was manifested principally as a significant increase in radiation emitted from the plasma; correspondingly, a moderate increase in the total power deposited into the plasma was also observed. The table and bar graph of Fig. 94 illustrates both these effects. Note that a significant amount of the increase in radiation occurred in the visible and near-UV wavelength bands. At the relatively low discharge power and pressure levels of these exploratory tests, the discharge was quite sensitive to changes in both the argon mass flow rate and the UF₆ mass flow rate. Occasionally, when the UF₆ injection mass flow rate exceeded a certain level, corresponding to a given set of test conditions, distortion occurred (plasma unsteadiness) in the central region of the plasma; this was usually followed by extinguishment of the discharge.

Periodically throughout the exploratory rf plasma tests, spectral emission measurements throughout the wavelength band from 300-700 nm were taken on-axis at the axial midplane using a 0.25-m monochromator system. Figure 96 illustrates some results obtained for the wavelength band between 400 to 460 nm. Many of the strong argon, uranium, and fluorine lines present in the wavelength range from 300-700 nm have been identified, cataloged, and compared with those documented in the literature.

To demonstrate the feasibility and practicality of using a cw single-frequency tunable dye laser system for making uranium plasma absorption measurements, several tests were conducted using the dye laser system illustrated in Fig. 93. Significant effort had to be devoted to properly shielding the entire dye laser and associated diagnostic equipment from the rf fields. As shown in Fig. 93, the dye laser beam traversed the test chamber on the major axis at a distance of 1 cm away from the tip of the UF₆ injector. Based on prior spectral emission chordal scans taken under similar test conditions (argon only), the temperature profiles determined (based on both absolute line and continuum radiation) indicated centerline temperatures of approximately 8000 K exist with a slight off-axis peak at a radius ratio of about 0.5.

Figure 97 shows an example of the absorption measurements obtained from the actual strip-chart recorder output in the exploratory rf plasma experiments with pure UF₆ injection. The 591.54 nm uranium line was selected as it is a relatively strong uranium I line and appeared well-defined in the spectral emission scans. The lower state for the 591.54 nm line is the uranium I ground state. The half-width of the laser line at the 591.54 nm wavelength was approximately 10⁻⁴ nm. To obtain the measurements shown in Fig. 97, the scanning generator of the dye laser system was activated to an automatic continuous scan mode as shown by the output data in
the left portion of Fig. 97. Only argon was present in the rf plasma discharge during these initial scans. The 8 GHz range (free spectral range of the confocal Fabry-Perot spectrum analyzer) translates to approximately $10^{-2}$ nm on the wavelength scale. Many such scans at different operating test conditions were completed with only several (at fixed test conditions) shown in Fig. 97 for simplicity. The test conditions for the argon-only case were similar to those shown in the table in Fig. 94. The zero reference line (zero transmission) is shown at the top of Fig. 97. As noted, no absorption was detected for any of the argon-only test conditions. When pure UF$_6$ was injected into the discharge, sufficient time was allowed for all conditions to come to equilibrium ($\approx 10$ s); additional scans were then completed. Results from tests at two different UF$_6$ mass flow rates are shown at the right of Fig. 97. The first case corresponds to a UF$_6$ mass flow rate of approximately 0.02 g/s. The measurements indicate an absorption of approximately 25 percent (corresponding to $I/I_0 = 0.75$). Doubling the mass flow rate of UF$_6$ to approximately 0.04 g/s increased the relative absorption to about 55 percent ($I/I_0 = 0.45$) for the second case. Based on an assumed 50-50 occupancy (ground state/excited state), a temperature of 8000 K, an optical path length of 2 cm (relatively small core due to close proximity of the UF$_6$ injector), and including a factor for ionization reduction, the ground state neutral uranium UI atom number density based on the absorption measurements were estimated to be approximately $8 \times 10^{12}$ atoms/cm$^3$ and $2 \times 10^{13}$ atoms/cm$^3$, respectively, for the two cases. This compares with approximately $10^{14}$ atoms/cm$^3$ based on temperature and pressure calculations. These results are encouraging and demonstrated that a dye laser system combined with optical scanning instrumentation may be employed in future rf plasma uranium confinement tests to permit chordal scans of the spatial absorption distribution; from this and other measurements the total number density and spatial distribution of uranium vapor contained within the discharge boundary may be determined.

Periodically throughout the exploratory test series, portions of the fused-silica peripheral tubes were examined for thermal stress and wall deposition. Figure 98 is a photograph of two of the tubes used in the exploratory tests with pure UF$_6$ injection. The analysis indicated thermal stress was present in the central region of the fused-silica tube, generally following the outline of the rf work coil. This was as expected due to the limited air jet cooling supplied to the fused-silica tube and the close proximity of the rf plasma to the wall during the majority of tests. The fused-silica tube numbered 8 in Fig. 98 is representative of the type of wall coating obtained after about two minutes of operation in the relatively high UF$_6$ mass flow rate range.

TABLE XIII is a summary of the exploratory tests conducted in the 1.2 MW rf induction heater using the basic test chamber flow configuration shown in Fig. 92. In these tests, the higher power, higher pressure argon rf plasma discharge employed in the 1.2 MW rf induction heater tests was less susceptible to perturbations due to the injection of pure UF$_6$. Thus, a greater mass flow rate of UF$_6$ could be injected.
while still maintaining a well-confined, stable discharge. Occasionally, under certain extreme combinations of test conditions, indications of plasma unsteadiness were observed to occur.

The maximum mass flow rate of pure UF$_6$ employed was approximately 0.1 g/s. This corresponded to a chamber pressure of 1.7 atm, argon plasma power level of about 70 kW, and argon buffer gas mass flow rate of 3.2 g/s. The test at maximum UF$_6$ flow rate extended over a time interval of ten minutes. The residue in the central portion of the fused-silica tube for this particular test was approximately 25 mg.

During the latter part of the exploratory tests using the 1.2 MW rf induction heater, ten tubes were selected for analysis of wall deposits by several techniques, including electron diffraction, x-ray diffraction, electron microprobe, and IR spectrophotometry. TABLE XIV is a summary of the results and shows the types of compounds deposited on the peripheral wall. Figure 99 is a photograph showing four of the ten tubes that were analyzed. Only one complete test was conducted prior to the removal of these tubes from the test section. Note that approximately an order of magnitude reduction in the deposition of uranium compounds was achieved in these tests. It should be pointed out that a relatively uniform deposition of approximately 19 mg is difficult to detect visually. The SiO$_2$ detected using the IR spectrophotometer, was believed to be from the fused-silica tube itself and partly due to the silicone grease used in the O-rings for sealing the fused-silica tube to the endwall assembly. The agreement between the different analysis techniques is reasonable considering the statistical nature of sampling the residue and partial exposure to the atmosphere in the preparation of the small samples. In addition to the results shown in TABLE XIV for the fused-silica peripheral wall tube, trace amounts of UF$_4$ were found to be present on the surface of the endwalls, UF$_6$ injector, and within the exhaust thru-flow duct. Figures 100 through 104 show examples of the results obtained from the various analysis techniques employed in these exploratory tests. Figure 100 illustrates the type of electron diffraction patterns obtained. For the particular sample shown, the primary compound was UO$_2$ with a trace amount of UF$_4$. The tabular data to the right of the actual diffraction pattern photograph gives additional details on the compounds characteristics. Photomicrographs of the residue wall coating (800X magnification) corresponding to the three principal color samples analyzed are shown in Fig. 101. The distinctly different crystalline structure of each is clearly evident in the photographs. Figure 102 contains four photographs showing the different x-ray diffraction patterns obtained from post-test analysis of the fused-silica tube residue. In all cases, the samples were subjected to copper K$_\alpha$ radiation in a Debye camera. In addition to the three color powders obtained (black, rust, green), a black chip sample was also included for comparison. The distinctly different x-ray diffraction patterns from each sample is evident from the photographs. Figure 103 contains three photographs showing the distribution of U, F, and O from samples of the black powder residue wall coating from a post-test x-ray analysis. The magnification was approximately 350X. Figure 104
is an example of the recorder output trace obtained from the IR spectrophotometry absorption measurements of a post-test analysis of the residue wall coating. At the bottom of the trace is noted the particular compounds associated with the peaks.

Figure 105 shows an example of some of the absorption measurements obtained in the 1.2 MW rf plasma exploratory experiments with pure UF₆ injection. Refer to Fig. 93 for the basic diagnostic setup. In these tests, an argon-ion laser beam of approximately 300 mW power and operating at a wavelength of 514.5 nm was used. The 514.5 nm line was selected because of its relatively high output power, and because a cataloged singly-ionized uranium line also corresponds to the 514.5 nm wavelength. Figure 105 shows the change in transmission (I/I₀) which occurred with various changes in the UF₆ mass flow rate. A semi-log plot was used to give an indication of the possible exponential dependence of the transmission on the UF₆ mass flow rate. In this case the UF₆ mass flow rate would be related to the concentration. The product of absorption coefficient, concentration, and optical path length forms the exponent in the relationship with transmission. Post-test calibration indicated the transmission returned to approximately the initial value, thus confirming the observation of minimum wall coating. Figure 106 is a photograph showing a typical rf plasma with pure UF₆ injection within the 1.2 MW rf induction heater.

These initial exploratory test results indicate promising techniques have been investigated for fluid-mechanical confinement of uranium in argon-confined high-temperature, high-pressure, rf-heated plasmas with pure UF₆ injection. Included has been the initial development of the associated handling and feeder techniques for steady-state injection of pure UF₆ into the rf plasma discharge. Various diagnostic techniques have also been initiated and applied to determine some of the uranium plasma characteristics and composition of the uranium compound wall deposition.

Based on these exploratory test results, continuing tests to further increase the quantity of uranium confined within the rf-heated argon plasma, while simultaneously minimizing deposition of the uranium compounds on the peripheral walls of the plasma test chamber combined with the associated diagnostics, is recommended; the results of these tests are described in the main portion of this report.
**TABLE I**

SUMMARY OF RANGE OF OPERATING CONDITIONS FOR RF PLASMA TESTS WITH CHORDAL SCAN MEASUREMENTS CONDUCTED IN 1.2 MW RF INDUCTION HEATER WITH PURE UF$_6$ INJECTION

See Fig. 8 for Sketch of Test Chamber Configuration
See Fig. 13 for Schematic of Diagnostic System Used for Chordal Scan Measurements
See Figs. 16 Through 19 for Examples of Measurement Results

<table>
<thead>
<tr>
<th>Parameter</th>
<th>Range</th>
</tr>
</thead>
<tbody>
<tr>
<td>Argon Injection Mass Flow Rate</td>
<td>2.45-2.58 g/s</td>
</tr>
<tr>
<td>Argon Injection Velocity</td>
<td>19.4-21.6 m/s</td>
</tr>
<tr>
<td>Percent Axial Bypass Flow</td>
<td>35-48</td>
</tr>
<tr>
<td>UF$_6$ Injection Mass Flow Rate</td>
<td>9x10$^{-3}$-3.2x10$^{-2}$ g/s</td>
</tr>
<tr>
<td>UF$_6$ Injection Velocity</td>
<td>0.2-0.7 m/s</td>
</tr>
<tr>
<td>Mass Ratio</td>
<td>0.004-0.012</td>
</tr>
<tr>
<td>Chamber Pressure</td>
<td>1.7-1.95 atm</td>
</tr>
<tr>
<td>RF Discharge Power</td>
<td>47-58 kW</td>
</tr>
<tr>
<td>RF Operating Frequency</td>
<td>54190-54270 MHz</td>
</tr>
<tr>
<td>Power Radiated (220-1300 nm)</td>
<td>15.1-19.5 kW</td>
</tr>
<tr>
<td>Fraction of Total Discharge Power Radiated</td>
<td>0.29-0.34</td>
</tr>
<tr>
<td>Discharge Diameter at Axial Midplane</td>
<td>2.6-2.8 cm</td>
</tr>
<tr>
<td>Test Time</td>
<td>2 min</td>
</tr>
<tr>
<td>Residue Deposition</td>
<td>4.3-8.1 mg</td>
</tr>
</tbody>
</table>
TABLE II

SUMMARY OF OPERATING CONDITIONS FOR CHORDAL SCAN MEASUREMENTS OF
TEST V CONDUCTED IN 1.2 MW RF INDUCTION HEATER WITH
RF PLASMA AND PURE UF$_6$ INJECTION

See Fig. 8 for Sketch of Test Chamber Configuration
See Fig. 7 for Schematic of Diagnostic System Used for Chordal Scan Measurements

<table>
<thead>
<tr>
<th>Parameter</th>
<th>Value</th>
</tr>
</thead>
<tbody>
<tr>
<td>Argon Injection Mass Flow Rate</td>
<td>2.58 g/s</td>
</tr>
<tr>
<td>Argon Injection Velocity</td>
<td>21.6 m/s</td>
</tr>
<tr>
<td>Percent Axial Bypass Flow</td>
<td>48</td>
</tr>
<tr>
<td>UF$_6$ Injection Mass Flow Rate</td>
<td>3.2x10^-2 g/s</td>
</tr>
<tr>
<td>UF$_6$ Injection Velocity</td>
<td>0.7 m/s</td>
</tr>
<tr>
<td>Mass Ratio</td>
<td>0.012</td>
</tr>
<tr>
<td>Chamber Pressure</td>
<td>1.95 atm</td>
</tr>
<tr>
<td>RF Discharge Power</td>
<td>58 kW</td>
</tr>
<tr>
<td>RF Operating Frequency</td>
<td>5.4210 MHz</td>
</tr>
<tr>
<td>Power Radiated (220-1300 nm)</td>
<td>19.5 kW</td>
</tr>
<tr>
<td>Fraction of Total Discharge Power Radiated</td>
<td>0.34</td>
</tr>
<tr>
<td>Discharge Diameter at Axial Midplane</td>
<td>2.8 cm</td>
</tr>
<tr>
<td>Test Time</td>
<td>2 min</td>
</tr>
<tr>
<td>Residue Deposition</td>
<td>8.1 mg</td>
</tr>
<tr>
<td>Test No</td>
<td>Configuration and Flow Control Scheme</td>
</tr>
<tr>
<td>--------</td>
<td>-------------------------------------</td>
</tr>
<tr>
<td>1</td>
<td>See Fig. 8 for general configuration. UF₆ injector tip located 2 cm from endwall</td>
</tr>
<tr>
<td>2</td>
<td>UF₆ injector tip located 2 cm from endwall - 0.24 cm ID argon vortex injectors</td>
</tr>
<tr>
<td>3</td>
<td>UF₆ injector - 10 cm axial distance between endwalls</td>
</tr>
<tr>
<td>4</td>
<td>An axial cooling water flow rate reduced 10x from 1 1/2 g to 1 1/4 g</td>
</tr>
<tr>
<td>5</td>
<td>Argon vortex injectors - 0.17 cm ID, UF₆ injector tip located 2 cm from endwall</td>
</tr>
<tr>
<td>6</td>
<td>Argon vortex injectors - 0.17 cm ID, UF₆ injector tip located 1 cm from endwall</td>
</tr>
<tr>
<td>7</td>
<td>Argon vortex injectors - 0.17 cm ID, UF₆ injector tip located flush with endwall</td>
</tr>
</tbody>
</table>
TABLE IV
SUMMARY OF LONG RUN TIME TESTS CONDUCTED IN
1.2 MW RF INDUCTION HEATER WITH
RF PLASMA AND PURE UF$_6$ INJECTION

(Attempts were made to keep all operating conditions approximately the same for all
tests. See Figs. 34 and 35 for photographs of fused-silica tubes after tests.)

<table>
<thead>
<tr>
<th>Parameter</th>
<th>Value</th>
</tr>
</thead>
<tbody>
<tr>
<td>Argon Injection Mass Flow Rate</td>
<td>2.63 g/s</td>
</tr>
<tr>
<td>Argon Injection Velocity</td>
<td>42.9 m/s</td>
</tr>
<tr>
<td>Percent Axial Bypass Flow</td>
<td>19</td>
</tr>
<tr>
<td>UF$_6$ Injection Mass Flow Rate</td>
<td>2.2x10^-2 g/s</td>
</tr>
<tr>
<td>UF$_6$ Injection Velocity</td>
<td>0.6 m/s</td>
</tr>
<tr>
<td>Mass Ratio</td>
<td>0.008</td>
</tr>
<tr>
<td>Chamber Pressure</td>
<td>1.75 atm</td>
</tr>
<tr>
<td>RF Discharge Power</td>
<td>444 kW</td>
</tr>
<tr>
<td>RF Operating Frequency</td>
<td>5.4304 MHz</td>
</tr>
<tr>
<td>Power Radiated (220-1300 nm)</td>
<td>13.7 kW</td>
</tr>
<tr>
<td>Fraction of Total Discharge Power Radiated</td>
<td>0.31</td>
</tr>
<tr>
<td>Discharge Diameter at Axial Midplane</td>
<td>3.1 cm</td>
</tr>
<tr>
<td>Range of Test Time</td>
<td>5-41.5 Min*</td>
</tr>
<tr>
<td>Range of Residue Deposition</td>
<td>12.7-35.7 mg</td>
</tr>
</tbody>
</table>

*41.5 minute test was terminated due to cracking of Mycalex (Super 500) radiation/electric insulation shield located on vacuum capacitors in resonator section. Cause attributed to excessive sustained radiation loading.
<table>
<thead>
<tr>
<th>Parameter</th>
<th>Value</th>
</tr>
</thead>
<tbody>
<tr>
<td>Argon Injection Mass Flow Rate</td>
<td>2.45 g/s</td>
</tr>
<tr>
<td>Argon Injection Velocity</td>
<td>40 m/s</td>
</tr>
<tr>
<td>Percent Axial Bypass Flow</td>
<td>0.37</td>
</tr>
<tr>
<td>UF$_6$ Injection Mass Flow Rate</td>
<td>0.21 g/s</td>
</tr>
<tr>
<td>UF$_6$ Injection Velocity</td>
<td>2.7 m/s</td>
</tr>
<tr>
<td>Mass Ratio</td>
<td>0.09</td>
</tr>
<tr>
<td>Chamber Pressure</td>
<td>2 atm</td>
</tr>
<tr>
<td>RF Discharge Power</td>
<td>67 kW</td>
</tr>
<tr>
<td>RF Operating Frequency</td>
<td>5.4200 MHz</td>
</tr>
<tr>
<td>Power Radiated (220-1300 nm)</td>
<td>21.8 kW*</td>
</tr>
<tr>
<td>Fraction of Total Discharge Power Radiated</td>
<td>0.325*</td>
</tr>
<tr>
<td>Discharge Diameter at Axial Midplane</td>
<td>3.3 cm*</td>
</tr>
<tr>
<td>Test Time</td>
<td>1.2 Min</td>
</tr>
<tr>
<td>Residue Deposition</td>
<td>134.7 mg</td>
</tr>
</tbody>
</table>

*Exact determination difficult since discharge was displaced away from central location of test chamber.
### TABLE VI
SUMMARY OF MATERIAL SAMPLES USED IN IR SPECTROPHOTOMETRIC ANALYSIS

<table>
<thead>
<tr>
<th>Sample</th>
<th>Available Within UTRC</th>
<th>IR Spectrum Completed</th>
<th>Displays Distinguishable Spectrum</th>
</tr>
</thead>
<tbody>
<tr>
<td>KBr</td>
<td>Yes</td>
<td>Yes</td>
<td>Yes</td>
</tr>
<tr>
<td>Silicone Grease</td>
<td>Yes</td>
<td>Yes</td>
<td>No (Thin Film Technique Could be Used)</td>
</tr>
<tr>
<td>SiO$_2$·xH$_2$O</td>
<td>Yes</td>
<td>Yes</td>
<td>No</td>
</tr>
<tr>
<td>Kel-F oil</td>
<td>Yes</td>
<td>Yes</td>
<td>No</td>
</tr>
<tr>
<td>Silicon O-ring</td>
<td>Yes</td>
<td>Yes</td>
<td>No</td>
</tr>
<tr>
<td>Decomposition Products</td>
<td></td>
<td></td>
<td>No</td>
</tr>
<tr>
<td>U</td>
<td>Yes</td>
<td>No</td>
<td>No (Thin Film Technique Could be Used)</td>
</tr>
<tr>
<td>UO</td>
<td>No</td>
<td>No</td>
<td>No</td>
</tr>
<tr>
<td>UO$_2$</td>
<td>Yes</td>
<td>Yes</td>
<td>Yes</td>
</tr>
<tr>
<td>UO$_3$-amorphous</td>
<td>Yes</td>
<td>Yes</td>
<td>Yes</td>
</tr>
<tr>
<td>$\alpha$UO$_3$-hexagonal</td>
<td>Yes</td>
<td>Yes</td>
<td>Yes</td>
</tr>
<tr>
<td>$\epsilon$UO$_3$-monoclinic</td>
<td>Yes</td>
<td>Yes</td>
<td>Yes</td>
</tr>
<tr>
<td>$\gamma$UO$_3$-monoclinic</td>
<td>Yes</td>
<td>Yes</td>
<td>Yes</td>
</tr>
<tr>
<td>UO$_4$ (Laboratory Prepared)</td>
<td>Yes</td>
<td>Yes</td>
<td>Yes</td>
</tr>
<tr>
<td>U$_3$O$_8$</td>
<td>Yes</td>
<td>Yes</td>
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<tr>
<td>U$_4$O$_9$</td>
<td>No</td>
<td>No</td>
<td>Yes</td>
</tr>
<tr>
<td>Cu</td>
<td>Yes</td>
<td>No</td>
<td>No (Thin Film Technique Could be Used)</td>
</tr>
<tr>
<td>CuF$_2$</td>
<td>Yes</td>
<td>Yes</td>
<td>Yes</td>
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<td>UF$_4$</td>
<td>Yes</td>
<td>Yes</td>
<td>No</td>
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<tr>
<td>UF$_5$</td>
<td>No</td>
<td>No</td>
<td>No</td>
</tr>
<tr>
<td>$\mathrm{U}_2$F$_9$</td>
<td>No</td>
<td>No</td>
<td>No</td>
</tr>
<tr>
<td>UO$_2$Cl(UO$_2^+$)</td>
<td>Yes</td>
<td>Yes</td>
<td>Yes</td>
</tr>
<tr>
<td>UO$_2$F$_2$(UO$_2^{++}$)</td>
<td>Yes</td>
<td>Yes</td>
<td>Yes</td>
</tr>
</tbody>
</table>

Notes:
- UO$_2$F$_2$(UO$_2^{++}$) refers to trace quantities only.
- Difficulty in Determining Crystalline Structure.
<table>
<thead>
<tr>
<th>Sample</th>
<th>Available Within UTRC</th>
<th>IR Spectrum Completed</th>
<th>Displays Distinguishable Spectrum</th>
</tr>
</thead>
<tbody>
<tr>
<td>UCl₃</td>
<td>Yes</td>
<td>No</td>
<td>-</td>
</tr>
<tr>
<td>(UF₃ unavailable but similar in charac.)</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>UC</td>
<td>Yes</td>
<td>Yes</td>
<td>No</td>
</tr>
<tr>
<td>UC₂</td>
<td>Yes</td>
<td>Yes</td>
<td>No</td>
</tr>
<tr>
<td>UN</td>
<td>Yes</td>
<td>Yes</td>
<td>No</td>
</tr>
<tr>
<td>U₂N₃</td>
<td>Yes</td>
<td>Yes</td>
<td>No</td>
</tr>
<tr>
<td>U₃N₄</td>
<td>Yes</td>
<td>Yes</td>
<td>No</td>
</tr>
<tr>
<td>USi₂</td>
<td>Yes</td>
<td>Yes</td>
<td>No</td>
</tr>
<tr>
<td>Property</td>
<td>Value</td>
<td></td>
<td></td>
</tr>
<tr>
<td>----------------------------------------------</td>
<td>--------------------------------------------</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Density</td>
<td>2.2 g/cc</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Hardness</td>
<td>6 Mohs'</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Thermal coefficient of expansion*</td>
<td>$5.5 \times 10^{-7} , \text{C}^{-1} (20 , \text{C}-1000 , \text{C})$</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Thermal conductivity</td>
<td>$3.2 \times 10^{-3} , \text{cal/cm}^2/\text{s/C/cm}$</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Specific heat</td>
<td>0.175 cal/g C</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Thermal diffusivity</td>
<td>$8.5 \times 10^{-3} , \text{cm}^2/\text{s}$</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Tensile strength</td>
<td>$4.8 \times 10^2 , \text{atm}$</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Compressive strength</td>
<td>$10^4 , \text{atm}$</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Young's modulus at 20 C</td>
<td>$7.2 \times 10^5 , \text{atm}$</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Bulk modulus at 20 C</td>
<td>$3.8 \times 10^5 , \text{atm}$</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Shear modulus at 20 C</td>
<td>$3.1 \times 10^5 , \text{atm}$</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Poisson's ratio</td>
<td>0.14</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Dielectric strength</td>
<td>$410 , \text{V/mil at 50 C/MHz}$</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Dielectric loss factor</td>
<td>$&lt; 4 \times 10^{-4} , \text{at 20 C/MHz}$</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Dielectric constant</td>
<td>3.8 at 20 C/MHz</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Strain point</td>
<td>1070 C appx.</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Annealing point</td>
<td>1140 C appx.</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Softening point</td>
<td>1670 C appx.</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Fusing point</td>
<td>1750 C appx.</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Index of refraction</td>
<td>1.45845</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Optical transmission</td>
<td>See Fig. 10</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Resistance to corrosion</td>
<td>Not affected by most pure molten metals or by any acid except hydrofluoric at all temperatures and phosphoric above 400 C</td>
<td></td>
<td></td>
</tr>
</tbody>
</table>

*Low coefficient of expansion makes fused-silica tubes highly resistant to most severe thermal shock.*
TABLE VIII
SUMMARY OF SPECTROCHEMICAL ANALYSIS OF FUSED SILICA
AS USED IN RF PLASMA TESTS WITH PURE UF₆ INJECTION
Analysis Conducted Prior to Hot Flow Tests

<table>
<thead>
<tr>
<th>Impurity Constituent</th>
<th>Concentration - ppm</th>
<th>Mass Spectrometer Data Supplied by U.S. Fused Quartz Corp.</th>
<th>Analytical Results Obtained at UTRC Using Small Sample Provided by U.S. Fused Quartz Corp.</th>
<th>Analytical Results Obtained at UTRC Using Actual 57-mm-ID x 61-mm-OD Tube of Test Chamber</th>
</tr>
</thead>
<tbody>
<tr>
<td>Fe₂O₃</td>
<td>5</td>
<td>&lt; 4</td>
<td>&lt; 3</td>
<td>&lt; 3</td>
</tr>
<tr>
<td>CaO</td>
<td>12</td>
<td>&lt; 50</td>
<td>&lt; 30</td>
<td>&lt; 30</td>
</tr>
<tr>
<td>Na₂O</td>
<td>4</td>
<td>6</td>
<td>4</td>
<td>4</td>
</tr>
<tr>
<td>B₂O₃</td>
<td>-</td>
<td>8</td>
<td>3</td>
<td>3</td>
</tr>
<tr>
<td>Al₂O₃</td>
<td>&lt; 50</td>
<td>11</td>
<td>9</td>
<td>9</td>
</tr>
<tr>
<td>MgO</td>
<td>2</td>
<td>&lt; 2</td>
<td>&lt; 3</td>
<td>&lt; 3</td>
</tr>
<tr>
<td>PbO</td>
<td>-</td>
<td>20</td>
<td>6</td>
<td>6</td>
</tr>
<tr>
<td>NiO</td>
<td>-</td>
<td>0.05</td>
<td>0.4</td>
<td>0.4</td>
</tr>
<tr>
<td>CuO</td>
<td>-</td>
<td>&lt; 0.2</td>
<td>0.3</td>
<td>0.3</td>
</tr>
<tr>
<td>Li₂O</td>
<td>1</td>
<td>3.6</td>
<td>2.4</td>
<td>2.4</td>
</tr>
<tr>
<td>TiO₂</td>
<td>2</td>
<td>&lt; 0.5</td>
<td>&lt; 0.5</td>
<td>&lt; 0.5</td>
</tr>
<tr>
<td>K₂O</td>
<td>4</td>
<td>&lt; 1.2</td>
<td>&lt; 1.2</td>
<td>&lt; 1.2</td>
</tr>
<tr>
<td>As</td>
<td>0.08</td>
<td>&lt; 10</td>
<td>&lt; 10</td>
<td>&lt; 10</td>
</tr>
<tr>
<td>P</td>
<td>nondetectable</td>
<td>&lt; 10</td>
<td>&lt; 10</td>
<td>&lt; 10</td>
</tr>
<tr>
<td>Zr₂O₃</td>
<td>3</td>
<td>&lt; 1</td>
<td>&lt; 1</td>
<td>&lt; 1</td>
</tr>
<tr>
<td>Ca</td>
<td>0.2</td>
<td>-</td>
<td>-</td>
<td>-</td>
</tr>
<tr>
<td>B</td>
<td>0.5</td>
<td>-</td>
<td>-</td>
<td>-</td>
</tr>
</tbody>
</table>
TABLE IX

PROPERTIES AND ASSAY OF AS - RECEIVED UF₆
(This Analysis Was Performed on Samples Removed in
The Liquid and Homogeneous State)

Vapor pressure of vessel at 96 C       4 atm abs.
Minimum weight percent of UF₆ in material 99.98
Maximum mole percent hydrocarbons, chlorocarbons, and
partially substituted halohydrocarbons Nil
Number of parts of elements indicated per million
parts of total uranium
  Antimony < 0.7
  Bromine < 5.0
  Chlorine < 5.0
  Niobium < 0.1
  Phosphorus < 12.0
  Ruthenium < 0.7
  Silicon < 3.0
  Tantalum < 0.7
  Titanium 0.6

Total number of parts of elements forming nonvolatile fluorides,
Having a vapor pressure of one atm or less at 300 C,
per million parts of total uranium < 83

Number of parts of elements or isotopes indicated per million
parts of U-235
  Chromium < 1200
  Molybdenum < 21
  Tungsten < 104
  Vanadium 42
  U-233 < 500
  U-232 < 0.110

Thermal neutron absorption of total impurity elements as
equivalent parts of boron per million parts of total uranium < 1.7

Total of gamma activity due to fission products and U-237 as
percent of gamma activity of aged natural uranium < 20

Beta activity due to fission products as percent of Beta
activity of aged natural uranium < 10

Alpha activity from all transuranic elements in disintegrations
per minute per gram of total uranium < 1500
TABLE X

SUMMARY OF TEST CONDITIONS FOR SMALL-SCALE FUSED-SILICA VESSELS
(350 cc) USED WITH GRAM QUANTITIES OF UF₆ IN LABORATORY TESTS
See Fig. 82 for Post-Test Photographs of Vessels

<table>
<thead>
<tr>
<th>Test Case</th>
<th>Prefill Evacuation</th>
<th>Gms UF₆ Transferred</th>
<th>UF₆ Pretreatment</th>
<th>Vessel Pre-Bakeout</th>
<th>Stop-Cock Sealant</th>
<th>Heating Temperature for 1 Hour</th>
<th>Post-Heating Room Temp. Soak Time</th>
</tr>
</thead>
<tbody>
<tr>
<td>I</td>
<td>10⁻⁴ mm Hg</td>
<td>0.9</td>
<td>as-received</td>
<td>No</td>
<td>Silicone grease</td>
<td>330 K</td>
<td>72 hrs.</td>
</tr>
<tr>
<td>II</td>
<td>10⁻⁴ mm Hg</td>
<td>0.9</td>
<td>filtered</td>
<td>No</td>
<td>Kel-F oil</td>
<td>330 K</td>
<td>72 hrs.</td>
</tr>
<tr>
<td>III</td>
<td>10⁻⁴ mm Hg</td>
<td>1.2</td>
<td>filtered</td>
<td>Yes</td>
<td>Silicone grease</td>
<td>330 K</td>
<td>72 hrs.</td>
</tr>
<tr>
<td>IV</td>
<td>10⁻⁴ mm Hg</td>
<td>0.9</td>
<td>filtered</td>
<td>Yes</td>
<td>Kel-F oil</td>
<td>330 K</td>
<td>72 hrs.</td>
</tr>
</tbody>
</table>
### TABLE XI

**CATALOGED LIST OF (EIGHT) STRONGEST LINES OF POSSIBLE REACTANTS/COMPOUNDS AND ASSOCIATED LINE SPACINGS**

Data Taken From American Society of Testing Materials X-ray Card File

<table>
<thead>
<tr>
<th>Compound</th>
<th>ASTM X-ray Card File No.</th>
<th>d-spacing, Å</th>
</tr>
</thead>
<tbody>
<tr>
<td>U</td>
<td>11-628</td>
<td>2.93</td>
</tr>
<tr>
<td>UO</td>
<td>17-659</td>
<td>2.83</td>
</tr>
<tr>
<td>UO&lt;sub&gt;2&lt;/sub&gt;</td>
<td>5-0550</td>
<td>3.157</td>
</tr>
<tr>
<td>αUO&lt;sub&gt;3&lt;/sub&gt;</td>
<td>12-43</td>
<td>4.17</td>
</tr>
<tr>
<td>UO&lt;sub&gt;3&lt;/sub&gt;</td>
<td>15-201</td>
<td>4.98</td>
</tr>
<tr>
<td>αU&lt;sub&gt;3&lt;/sub&gt;O&lt;sub&gt;8&lt;/sub&gt;</td>
<td>8-244</td>
<td>4.10</td>
</tr>
<tr>
<td>U&lt;sub&gt;3&lt;/sub&gt;O&lt;sub&gt;8&lt;/sub&gt;</td>
<td>23-1460</td>
<td>4.15</td>
</tr>
<tr>
<td>U&lt;sub&gt;4&lt;/sub&gt;O&lt;sub&gt;9&lt;/sub&gt;</td>
<td>20-1344</td>
<td>3.14</td>
</tr>
<tr>
<td>UF&lt;sub&gt;3&lt;/sub&gt;</td>
<td>9-339</td>
<td>3.67</td>
</tr>
<tr>
<td>UF&lt;sub&gt;4&lt;/sub&gt;</td>
<td>12-701</td>
<td>7.52</td>
</tr>
<tr>
<td>UF&lt;sub&gt;5&lt;/sub&gt;</td>
<td>4-447</td>
<td>5.66</td>
</tr>
<tr>
<td>UF&lt;sub&gt;6&lt;/sub&gt;</td>
<td>9-166</td>
<td>5.20</td>
</tr>
<tr>
<td>U&lt;sub&gt;2&lt;/sub&gt;F&lt;sub&gt;2&lt;/sub&gt;</td>
<td>4-860</td>
<td>4.15</td>
</tr>
<tr>
<td>UO&lt;sub&gt;2&lt;/sub&gt;F&lt;sub&gt;2&lt;/sub&gt;</td>
<td>4-833</td>
<td>5.22</td>
</tr>
<tr>
<td>*UO&lt;sub&gt;2&lt;/sub&gt;F&lt;sub&gt;2&lt;/sub&gt;</td>
<td>4-230</td>
<td>5.18</td>
</tr>
<tr>
<td>UC</td>
<td>9-214</td>
<td>2.87</td>
</tr>
<tr>
<td>UC&lt;sub&gt;2&lt;/sub&gt;</td>
<td>6-372</td>
<td>3.04</td>
</tr>
<tr>
<td>UC&lt;sub&gt;3&lt;/sub&gt;C&lt;sub&gt;3&lt;/sub&gt;</td>
<td>6-709</td>
<td>3.29</td>
</tr>
<tr>
<td>UN</td>
<td>11-315</td>
<td>2.81</td>
</tr>
<tr>
<td>UN&lt;sub&gt;2&lt;/sub&gt;</td>
<td>10-93</td>
<td>3.02</td>
</tr>
<tr>
<td>U&lt;sub&gt;2&lt;/sub&gt;N&lt;sub&gt;3&lt;/sub&gt;</td>
<td>15-426</td>
<td>4.34</td>
</tr>
<tr>
<td>CU</td>
<td>4-0836</td>
<td>2.08</td>
</tr>
</tbody>
</table>

* α - Hexagonal
* * - Rhombohedral
### TABLE XII

**SUMMARY OF EXPLORATORY TESTS CONDUCTED IN 80-KW RF INDUCTION HEATER USING ARGON BUFFER GAS AND PURE UF6 INJECTION**

Test Chamber 5.7-cm-ID x 10-cm-long

on-axis UF6 injection (flush to 3 cm into chamber)

<table>
<thead>
<tr>
<th>Test Chamber Configuration and Flow Control Scheme</th>
<th>Range of Test Conditions (all tests conducted at operating frequency of 13.56 MHz)</th>
<th>No. of Tests</th>
<th>Comments</th>
</tr>
</thead>
<tbody>
<tr>
<td>Single endwall driven vortex injection Combination of on-axis thru-flow (both ends) and single axial bypass exhaust * See Fig. 91(a).</td>
<td>Argon mass flow rate 0.15-1.5 g/s UF6 mass flow rate 0.005-0.06 g/s*** Chamber pressure 1-1.2 atm Axial bypass flow 0-100% On-axis thru-flow 0-100% RF discharge power 2-15 kW Discharge diameter 3.8-5.5 cm</td>
<td>16</td>
<td>Relatively high UF6 flow rates obtained with light coating on central region of peripheral wall Well confined, stable discharge over wide range of test conditions.</td>
</tr>
<tr>
<td>Coaxial flow endwall argon injection, bluff body stabilization. Combination of on-axis thru-flow (both ends) and single axial bypass exhaust. See Fig. 91(b).</td>
<td>Argon mass flow rate 0.010-2.1 g/s UF6 mass flow rate 0.005-0.03 g/s*** Chamber pressure 1 atm Axial bypass flow 0-100% On-axis thru-flow 0-100% RF discharge power 2-11 kW Discharge diameter 4.5-5.5 cm</td>
<td>8</td>
<td>Central region and extremities of peripheral wall became heavily coated in all tests. Ellipsoidally-shaped discharge extending close to peripheral wall Discharge sensitive to changes in argon/UF6 mass flow rate Difficult to tune rf load during UF6 injection.</td>
</tr>
<tr>
<td>Symmetrical endwall driven vortex injection. No on-axis thru-flow. Symmetrical large radius exhaust annulus. See Fig. 91(c).</td>
<td>Argon mass flow rate 0.20-1.5 g/s UF6 mass flow rate 0.005-0.035 g/s*** Chamber pressure 1 atm RF discharge power 2-15 kW Discharge diameter 4.5-5.5 cm</td>
<td>10</td>
<td>Central region became moderately coated in all tests. Discharge sensitive to changes in argon/UF6 mass flow rate Heating load required during UF6 injection to eliminate extinguishment. Occasional discharge oscillation noted.</td>
</tr>
<tr>
<td>Peripheral wall driven vortex injection** (endwall augmentation used in some tests). See Fig. 91(d).</td>
<td>Argon mass flow rate 0.06-0.2 g/s UF6 mass flow rate 0.005-0.03 g/s*** Chamber pressure 1 atm Axial bypass flow 0-100% On-axis thru-flow 0-100% RF discharge power 2-8 kW Discharge diameter 4.5-5.5 cm</td>
<td>5</td>
<td>Entire peripheral wall became heavily coated Apparent turbulence noted along discharge boundary. Flow control limited due to fixed vortex injector area. Excessive heating of peripheral wall occurred.</td>
</tr>
</tbody>
</table>

*TTest configuration and flow control scheme selected for follow-on tests in 1.2 MW RF induction heater system.
**The peripheral wall injection flow control scheme was used with both the first and third test chamber configurations.
***Estimate based on UF6 canister weighing before and after test
<table>
<thead>
<tr>
<th>Test Chamber Configuration and Flow Control Scheme</th>
<th>Range of Test Conditions</th>
</tr>
</thead>
<tbody>
<tr>
<td>Dual Endwall Driven Vortex Injection On-Axis Thru-Flow (Both Endwalls) No Axial Bypass</td>
<td>Argon Mass Flow Rate 1.8 - 3.4 g/s On-Axis Thru-Flow Through 0 - 25 % One Endwall RF Discharge Power 20 - 60 kW Range of RF Operating Frequency 5.4700 - 5.5000 MHz Discharge Diameter 2.5 - 3.1 cm Chamber Pressure 2 - 12 atm UF₆ Mass Flow Rate 0.008 - 0.13 g/s Test Time 0.17 - 10 min</td>
</tr>
<tr>
<td>Single Endwall Driven Vortex Injection On-Axis Thru-Flow (One Endwall Only Opposite Vortex Drive) Single Axial Bypass (Endwall Opposite Vortex Drive)</td>
<td>Argon Mass Flow Rate 2.2 - 3.85 g/s Axial Bypass Flow 0 - 52 % RF Discharge Power 30 - 85 kW Range of RF Operating Frequency 5.4778 - 5.4878 MHz Discharge Diameter 2.3 - 3.3 cm Chamber Pressure 2 - 5 atm UF₆ Mass Flow Rate 0.013 - 0.131 g/s Test Time 0.25 - 10 min</td>
</tr>
</tbody>
</table>
TABLE XIV

SUMMARY OF ANALYSIS OF RESIDUE SAMPLES TAKEN FROM INSIDE OF FUSED-SILICA TUBES
AFTER RF PLASMA EXPLORATORY TESTS WITH PURE UF₆ INJECTION

Total of 10 Tubes Analyzed
See Fig. 99 for Photograph Showing Examples of Wall Coating

<table>
<thead>
<tr>
<th>Analysis Technique</th>
<th>Compound or Element Present in Residue Sample</th>
</tr>
</thead>
<tbody>
<tr>
<td></td>
<td>Green Color Sample</td>
</tr>
<tr>
<td>Electron Diffraction</td>
<td>UF₄</td>
</tr>
<tr>
<td>X-Ray Diffraction</td>
<td>UF₄</td>
</tr>
<tr>
<td>IR Spectrophotometry</td>
<td>UO₂, UO₂F₂, SiO₂</td>
</tr>
</tbody>
</table>
DETAILS OF PLASMA CORE REACTOR UNIT CELL

- ARGON BUFFER
- GAS INJECTOR
- ARGON BUFFER GAS
- MODERATOR
- INTERNALLY COOLED TRANSPARENT WALL
- WORKING FLUID CHANNELS CONTAINING PARTICLES, GRAPHITE FINS OR OPAQUE GASES
- REFLECTIVE LINER
- LINER COOLANT CHANNEL
- FUEL REGION
PHOTOGRAPH OF TEST CHAMBER CONFIGURATION INSTALLED
IN 1.2 MW RF INDUCTION HEATER

FRONT ALUMINUM DOME WITH VIEW PORTS REMOVED FOR CLARITY
TEST SECTION AXIAL DISTANCE – 10 CM

RF WORK COILS

COPPER ENDWALL ASSEMBLY AND ASSOCIATED WATER COOLING AND GAS LINES

CAPACITIVE TYPE VOLTAGE PROBE

0.76 M
DISTANCE BETWEEN ALUMINUM END FLANGES
SCHEMATIC OF 1.2 MW RF INDUCTION HEATER GAS AND COOLING WATER FLOW SYSTEMS

LEGEND
- PRESSURE GAGE
- FLOWMETER
- HEAT EXCHANGER
- RELIEF VALVE
- PRESSURE REGULATOR
- SHUT-OFF OR FLOW CONTROL VALVE
- FILTER
- COOLING WATER FLOWS
- ANNULAR
- END-WALLS
- UF₆ INJECTOR
SCHEMATIC DIAGRAM OF UF₆ TRANSFER SYSTEM

DESIGN POINT FLOW RATE = 5 G/S

UF₆ CONDENSER SYSTEM

0.5 l COLLECTION VESSELS

LN₂

RF PLASMA TEST CHAMBER

LINEAR MASS FLOW METER

UF₆ GAS

VACUUM PUMP

OIL BAFFLE TRAP

NaOH + H₂O

TRAP

TO VENT

ARGON PURGE GAS
OR VACUUM SYSTEM

TO TRAP

2 l UF₆ BOILER

GAS

LIQUID

HEAT EXCHANGER FOR N₂ SUPPLY

HEAT EXCHANGER FOR EVAPORATING UF₆

FLOW METER

ELECTRICAL RESISTANCE HEATER AND INSULATION

POWERSTAT

N₂

HEAT EXCHANGER

PRESSURE REGULATOR

KEY

X SHUTOFF VALVE WELDED BELLOWS
T THERMOCOUPLE
R PRESSURE RELIEF VALVE (BURST DISC)
O METERING VALVE

\[\text{ELECTRICAL RESISTANCE HEATER TAPE}\]
VAPOR PRESSURE CURVE FOR UF₆

TEMPERATURE, T - DEG K

PRESSURE, P - MMHG

50,000

40,000

30,000

20,000

10,000

5,000

2,000

1,000

500

200

100

50

20

10

250 300 350 400 450 500

SOLID UF₆

LIQUID UF₆

TRIPLE POINT 334.02K 1137.5 MMHG

SUBLIMATION POINT 326.4 K 760 MMHG

UF₆ VAPOR
PHOTOGRAPHS SHOWING DETAILS OF TEST CHAMBER CONFIGURATION FOR UF₆ RF PLASMA TESTS

(a) CLOSEUP VIEW OF 10-CM AXIAL LENGTH TEST CHAMBER – ALUMINUM FRONT COVER REMOVED

RF TRANSMISSION LINE

VOXETX INJECTORS (8 PER END WALL)

AXIAL THRU FLOW DUCT

RF WORK COILS

[Image of a closeup view with labeled components]

(b) VIEW THROUGH CENTER VIEW PORT WITH ARGON RF PLASMA PRESENT (NO UF₆ INJECTION)

[Image of a view through the center view port]

CHAMBER PRESSURE = 1 ATM  DISCHARGE POWER = 20 KW
DISCHARGE DIAMETER = 3.1 CM
PHOTOGRAPH OF DYE LASER SHOWING DETAILS OF INTERNAL COMPONENTS

- DYECELL ASSEMBLY
- PIEZO-CONTROLLED ETALON ASSEMBLY
- CHLORPH ASSEMBLY
- ADJUSTABLE MIRROR
SCHEMATIC OF OPTICAL DIAGNOSTIC SYSTEM USED FOR ABSORPTION AND EMISSION MEASUREMENTS IN RF PLASMA TESTS WITH PURE UF₆ INJECTION

SEE FIG. 14 FOR PHOTOGRAPH OF SYSTEM
SEE FIG. 8 FOR SKETCH OF TEST CHAMBER AND LASER BEAM LOCATION

ARGON ION PUMP LASER
DYE LASER
SIGNAL PROCESSOR
U LAMP
MOVABLE MIRRORS
ROTATING MIRROR
SIGNAL GENERATOR AND CONTROLLER SYSTEM FOR SCANNING MIRROR
ROTBATABLE MIRROR
POWER METER
FROCED SURFACE MIRROR
CHOPPER USED FOR ABSORPTION SCANS
ITHACO PHASE SENSITIVE DETECTOR AND LOCK-IN AMPLIFIER
REF. SIGNAL
STRIP CHART RECORDER
LASSER BEAM BLOCKED HERE DURING EMISSION SCANS

UF₆ INJECTOR
PLASMA
ADJ. MIRROR SUPPORT
FIXED FRONT SURFACE MIRROR
BEAM EXPANDER AND COLLIMATOR
FIXED FRONT SURFACE MIRROR
SLOT IN TEST TANK

TEST CHAMBER

R12-85-1

FIG. 13
EXAMPLE OF ABSORPTION MEASUREMENTS OBTAINED IN 1.2 MW RF PLASMA–DYE LASER TESTS

\[ P_c = 2 \text{ ATM} \quad Q_T = 55 \text{ KW} \quad T = 9500^\circ \text{K} \]

URANIUM DYE LASER LINE = 591.54 NM LOCATED ON CENTERLINE AT AXIAL MID–PLANE
DYE LASER BEAM DIAMETER = 1.5 MM \hspace{1cm} PLASMA DISCHARGE DIAMETER = 3 CM
SEE FIG. 8 FOR SKETCH OF TEST CHAMBER CONFIGURATION

\[ \dot{m}_{\text{UF}_6} = 0.013 \text{ G/S} \quad \frac{\dot{m}_{\text{UF}_6}}{\dot{m}_{\text{AR}}} = 0.77 \]

ARGON RF PLASMA ONLY
NO UF\(_6\) INJECTION
\[ \dot{m}_{\text{AR}} = 3.2 \text{ G/S} \]

100% ABSORPTION REF. LEVEL

RELATIVE ABSORPTION

UF\(_6\) INJECTOR VALVE ON
AXIAL BYPASS 1.14 G/S

UF\(_6\) INJECTOR VALVE OFF

0.082 G/S

0.063 G/S

0.028 G/S

0.02

0.20

0.55

TIME, \( t \) – MIN

TRACE AMOUNTS OF UF\(_6\) STILL VISIBLE ENTERING THE PLASMA

1 MIN
PHOTOGRAPHS OF RF PLASMA TEST WITH PURE UF₆ INJECTION

TEST CASE V
SEE TABLE II FOR ADDITIONAL TEST CONDITIONS

VIEW THROUGH LEFT WINDOW

a) ARGON ONLY

VIEW THROUGH CENTER WINDOW

b) ARGON + UF₆

VIEW THROUGH RIGHT WINDOW
EXAMPLE OF TOTAL DISCHARGE POWER, POWER RADIATED AND ITS DISTRIBUTION IN DIFFERENT WAVELENGTH BANDS FROM RF PLASMA TESTS WITH PURE UF₆ INJECTION CONDUCTED IN 1.2 MW RF INDUCTION HEATER

SEE TABLE II FOR TEST CONDITIONS—TEST CASE III
MEASUREMENTS TAKEN WITH RADIOMETER SYSTEM SHOWN IN FIG. 10
EXAMPLE OF RADIAL PROFILES OF EMISSION AND ABSORPTION COEFFICIENT FOR RF PLASMA TEST WITH PURE UF₆ INJECTION

TEST CASE V
SEE TABLE II FOR ADDITIONAL TEST CONDITIONS
EXAMPLE OF RESULTS OF RADIAL VARIATION IN TEMPERATURE AND TRANSMISSION OBTAINED WITH PURE UF₆ INJECTION INTO RF ARGON PLASMA

DYE LASER LINE USED: 591.54 NM
EMISSION AND ABSORPTION CHORDAL SCAN MEASUREMENTS TAKEN AT AXIAL MID-PLANE OF DISCHARGE
RADIAL TEMPERATURE PROFILE DETERMINED USING KIRCHHOFF'S LAW
SEE FIG. 13 FOR SCHEMATIC OF OPTICAL TRACKING SYSTEM USED
SEE TABLE II FOR ADDITIONAL TEST CONDITIONS

TEST CASE V
\[ \dot{m}_{UF_6} = 3.2 \times 10^{-2} \text{ G/S} \]

TEMPERATURE PROFILE DETERMINED FROM INTENSITY OF ARGON 415.8 NM LINE — SIMILAR TEST CONDITIONS — NO UF₆ INJECTION

5.7-CM-ID FUSED SILICA TUBE
ARGON VORTEX INJECTORS
5.7-CM-ID FUSED SILICA TUBE
UF₆ INJECTOR
RF PLASMA
ON-AXIS EXHAUST
AXIAL BY PASS
EDGE OF PLASMA

RADIAL DISTANCE FROM PLASMA CENTERLINE, \( r \) — CM
EQUILIBRUM COMPOSITION OF UF₆ AT A PARTIAL PRESSURE OF 0.001 ATM
EQUILIBRIUM COMPOSITION OF UF₆ AT SEVERAL PARTIAL PRESSURES

FIG. 21

(a) $P_p = 1.0$ ATM

(b) $P_p = 0.1$ ATM

(c) $P_p = 0.01$ ATM

(d) $P_p = 0.0001$ ATM
THERMAL DECOMPOSITION OF UF$_6$ AS A FUNCTION OF TEMPERATURE

MOLE FRACTION URANIUM, $X_U$

$P = 0.01$ ATM

0.01  0.1  1.0  COMPLETE DECOMPOSITION

TEMPERATURE, T - DEG K
VARIATION OF NEUTRAL URANIUM ATOM NUMBER DENSITY WITH UF₆ PARTIAL PRESSURE IN A UF₆/Ar MIXTURE

ASSUMPTIONS: LOCAL THERMODYNAMIC EQUILIBRIUM
LOWERING OF IONIZATION POTENTIAL NOT INCLUDED

\[ \sum P_{\text{ALL SPECIES}} = P_{\text{TOTAL}} = 2 \text{ ATM} \]

INJECTION PARTIAL PRESSURE OF UF₆, \( P_{\text{UF₆}} \) - ATM

NUMBER DENSITY OF NEUTRAL URANIUM_ATOMS, \( N_{\text{U}^0} \) - ATOMS/CM³
VARIATION OF SINGLY IONIZED URANIUM ATOM NUMBER DENSITY WITH UF$_6$ PARTIAL PRESSURE IN A UF$_6$/Ar MIXTURE

ASSUMPTIONS: LOCAL THERMODYNAMIC EQUILIBRIUM
LOWERING OF IONIZATION POTENTIAL NOT INCLUDED

\[ \sum_{\text{ALL SPECIES}} P_{\text{TOTAL}} = 2 \text{ atm} \]

EQUILIBRIUM TEMPERATURE, T – DEG K
10000
11000
9000
12000

NUMBER DENSITY OF SINGLY IONIZED URANIUM ATOMS, N$_{\text{U}^{+1}}$ – ATOMS CM$^{-3}$

INJECTION PARTIAL PRESSURE OF UF$_6$, $P_{\text{UF}_6}$ – ATM

10$^{-4}$ 10$^{-3}$ 10$^{-2}$ 10$^{-1}$
VARIATION OF DOUBLY IONIZED URANIUM ATOM NUMBER DENSITY WITH UF₆ PARTIALLY PRESSURE IN A UF₆/Ar MIXTURE

ASSUMPTIONS: LOCAL THERMODYNAMIC EQUILIBRIUM
LOWERIGN OF IONIZATION POTENTIAL NOT INCLUDED
VARIATION OF TOTAL URANIUM ATOM NUMBER DENSITY WITH UF$_6$ PARTIAL PRESSURE IN A UF$_6$/Ar MIXTURE

ASSUMPTIONS: LOCAL THERMODYNAMIC EQUILIBRIUM
LOWER OF IONIZATION POTENTIAL NOT INCLUDED

\[ N_{UT} = N_{UT}^+ + N_{UT}^{II} + N_{UT}^{III} \]

\[ \Sigma P_{ALL SPECIES} = P_{TOTAL} = 2 \text{ ATM} \]

EQUILIBRIUM TEMPERATURE, T - DEG K 6000, 7000, 8000, 9000, 10000, 11000, 12000

TOTAL NUMBER DENSITY OF URANIUM ATOM AND IONS, N$_{UT}$ - ATOMS/CM$^3$

INJECTION PARTIAL PRESSURE OF UF$_6$ $P_{UF_6}$ - ATM
ARGON EQUILIBRIUM COMPOSITION DATA

PRESSURE = 2 ATM
(REF. 13)
RESULTS OF MEASUREMENTS OF 591.54 NM LASER BEAM ABSORPTION LINE WIDTHS AS A FUNCTION OF CHAMBER PRESSURE FOR RF PLASMA TEST WITH PURE UF₆ INJECTION

\[ \Delta f_{\text{Doppler}} = \left( \frac{2kT}{mc^2 \log_e 2} \right)^{1/2} \]

CONVERSION 8 GHz = 10⁻² NM

○ CALCULATED LINE WIDTHS

△ MEASURED LINE WIDTHS

CHAMBER PRESSURE, \( P_c \) - ATM

NO PRESSURE BROADENING

591.54 NM ABSORPTION LINE WIDTH AT 1/2 MAXIMUM INTENSITY, \( \Delta \lambda_u \) - GHz

10000 = TEMPERATURE, T - DEG K
9000
8000
7000
6000
5000
4000
3000
2000
1000
300

0 1 2 3 4 5

0 1 2 3 4 5
EFFECT of TEMPERATURE ON THE PARTITION FUNCTIONS OF URANIUM (\(U^1\) and \(U^2\))

\[
Z_i = \sum_n s_{i,n} e^{-E_{i,n}/kT}
\]

PARTITION FUNCTION, \(Z_i\) - DIMENSIONLESS

TEMPERATURE, \(T\) - DEG K
VARIATION OF NUMBER DENSITY OF NEUTRAL URANIUM (UI) AS A FUNCTION OF RADIAL DISTANCE FROM TEST CHAMBER CENTERLINE

TEST CASE

○ FROM ABSORPTION CALCULATIONS ASSUMING DOPPLER WIDTH (NO PRESSURE BROADENING)

△ FROM EMISSION CALCULATIONS

DISTANCE FROM TEST CHAMBER CENTERLINE, r - CM

NEUTRAL URANIUM NUMBER DENSITY, n_U - ATOMS/CM^3 x 10^-15
EQUILIBRIUM COMPOSITION OF UF₆ OVER TEMPERATURE RANGE 6000–10,000 K AND PARTIAL PRESSURE RANGE 10⁻¹0 – 10⁻¹ ATM

MOLE FRACTION X

TEMPERATURE, T–DEG. K

P (ATM)

1.0

0.1

0.001

0.0001
RADIAL VARIATION OF TOTAL URANIUM ATOM (U\textsubscript{I}, U\textsubscript{II}, U\textsubscript{III}) NUMBER DENSITY FOR UF\textsubscript{6} RF PLASMA TEST CASE V

SEE TABLE II FOR ADDITIONAL TEST CONDITIONS

ESTIMATED CONFINED URANIUM MASS BASED ON MEASUREMENTS OF NEUTRAL URANIUM SPECIES = 0.03 MG

NUMBERS IN PARENTHESES ARE CORRESPONDING ESTIMATED VALUES OF TOTAL URANIUM SPECIES PARTIAL PRESSURE IN ATM

EXTRAPOLATED TO EDGE OF PLASMA

EDGE OF PLASMA

ESTIMATED CONFINED URANIUM MASS BASED ON MEASUREMENTS OF NEUTRAL URANIUM SPECIES = 0.03 MG

NUMBERS IN PARENTHESES ARE CORRESPONDING ESTIMATED VALUES OF TOTAL URANIUM SPECIES PARTIAL PRESSURE IN ATM
EXAMPLE OF RADIAL VARIATION OF CONFINED TOTAL URANIUM ATOMS AT AXIAL MIDPLANE FOR UF₆ RF PLASMA TEST CASE V

SEE TABLE II FOR ADDITIONAL DETAILS
SEE FIGS. 19 AND 32 FOR CORRESPONDING RADIAL PROFILES
OF TRANSMISSION, TEMPERATURE AND TOTAL URANIUM ATOM NUMBER DENSITY
PHOTOGRAPH OF FUSED SILICA TUBES USED IN RF PLASMA TESTS WITH PURE UF₆ INJECTION AND INCORPORATING MODIFICATIONS TO TEST CHAMBER FLOW SCHEME
PHOTOGRAPHS OF FUSED SILICA TUBES USED IN RF PLASMA TESTS WITH PURE UF$_6$ INJECTION AND INCORPORATING MODIFICATIONS TO TEST CHAMBER/FLOW SCHEME

SEE TABLE III FOR CORRESPONDING TEST CONDITIONS
EXAMPLES OF IR SPECTROPHOTOMETRIC ABSORPTION MEASUREMENTS TAKEN OF RESIDUE ON INNER SURFACE OF FUSED TUBE AFTER RF PLASMA TEST WITH PURE UF₆ INJECTION

SEE TABLE II FOR RANGE OF TEST CONDITIONS
THIN WAFFER KBr MATRIX USED WITH PERKIN ELEMER MODEL 457

WAVELENGTH, \( \lambda \) – MICRONS

<table>
<thead>
<tr>
<th>Wavenumber (cm⁻¹)</th>
<th>Absorbance – (log₁₀T₀)</th>
</tr>
</thead>
<tbody>
<tr>
<td>4000</td>
<td>0</td>
</tr>
<tr>
<td>3500</td>
<td>0.1</td>
</tr>
<tr>
<td>3000</td>
<td>0.5</td>
</tr>
<tr>
<td>2500</td>
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<td>2000</td>
<td>4.0</td>
</tr>
<tr>
<td>1800</td>
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<td>1600</td>
<td>8.0</td>
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<tr>
<td>1400</td>
<td>10.0</td>
</tr>
<tr>
<td>1200</td>
<td>12.0</td>
</tr>
<tr>
<td>1000</td>
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<td>800</td>
<td>16.0</td>
</tr>
<tr>
<td>600</td>
<td>18.0</td>
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<tr>
<td>400</td>
<td>20.0</td>
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WAVELENGTH, \( \lambda \) – MICRONS

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<th>Wavenumber (cm⁻¹)</th>
<th>Absorbance – (log₁₀T₀)</th>
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<tbody>
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</tr>
<tr>
<td>3.0</td>
<td>0.1</td>
</tr>
<tr>
<td>4.0</td>
<td>0.5</td>
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<td>18.0</td>
</tr>
<tr>
<td>30.0</td>
<td>20.0</td>
</tr>
<tr>
<td>40.0</td>
<td>22.0</td>
</tr>
</tbody>
</table>

WAVELENGTH, \( \lambda \) – MICRONS

<table>
<thead>
<tr>
<th>Wavenumber (cm⁻¹)</th>
<th>Absorbance – (log₁₀T₀)</th>
</tr>
</thead>
<tbody>
<tr>
<td>2.5</td>
<td>0</td>
</tr>
<tr>
<td>3.0</td>
<td>0.1</td>
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<td>4.0</td>
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<tr>
<td>7.0</td>
<td>6.0</td>
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<td>8.0</td>
<td>8.0</td>
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<td>9.0</td>
<td>10.0</td>
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<tr>
<td>10.0</td>
<td>12.0</td>
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<tr>
<td>20.0</td>
<td>18.0</td>
</tr>
<tr>
<td>30.0</td>
<td>20.0</td>
</tr>
<tr>
<td>40.0</td>
<td>22.0</td>
</tr>
</tbody>
</table>
RESIDUE DEPOSITION ON FUSED SILICA TUBES AFTER LONG RUN TIME TESTS WITH RF PLASMA AND PURE UF₆ INJECTION

SEE TABLE IV FOR ADDITIONAL TEST CONDITIONS

SEE FIGS. 40 AND 41 FOR PHOTOGRAPHS OF FUSED SILICA TUBES FROM SELECTED TESTS

- RESIDUE IDENTIFIED AS PRIMARILY UO₂F₂ (WHITE POWDER)
- WATER SOLUBLE (99% DISSOLVABLE)
- REMAINDER COMPLETELY REMOVED WITH HOT CONCENTRATED HCl

○ SILICONE O-RINGS, SILICONE GREASE, AS RECEIVED UF₆*  
△ SILICONE O-RINGS, KEL-F OIL, FILTERED UF₆(NaF)  
□ VITON O-RINGS, KEL-F OIL, FILTERED UF₆(NaF)  
◊ SILICONE O-RINGS, KEL-F OIL, FILTERED UF₆(NaF), FILTERED ARGON (ZEOLITE TRAP)

LONGEST TEST TIME = 41.5 MIN  
30.4 MG RESIDUE  
\[ m_{UF₆} = 2.2 \times 10^{-2} \, \text{g/s} \]  
TEST TERMINATED DUE TO CRACKING OF MYCALEX RADIATION/ELECTRICAL INSULATION SHIELD LOCATED ON VACUUM CAPACITORS IN RESONATOR SECTIONS

0 5 10 15 20 25 30 35 40 45
TEST TIME, t - MIN

0 10 20 30 40 50 60
WEIGHT OF RESIDUE MATERIAL ON FUSED SILICA TUBES, W - MG

RANGE OF SILICONE GREASE RESIDUE  
INITIALLY DEPOSITED ON FUSED SILICA TUBES

* REFER TO TABLE IX FOR PROPERTIES AND ASSAY OF AS-RECEIVED UF₆
ELECTRON PHOTOMICROGRAPHS AND X-RAY MAPS OF A SAMPLE RESIDUE FROM INSIDE SURFACE OF FUSED SILICA TUBE AFTER RF PLASMA TEST WITH PURE UF₆ INJECTION FOR 30 MINUTE DURATION

a) ELECTRON PHOTOMICROGRAPH

b) X-RAY SHOWING SILICON (WHITE AREA)

MAG: 3000x

MAG: 3000x

c) X-RAY SHOWING URANIUM

MAG: 3000x
EXAMPLES OF IR SPECTROPHOTOMETRIC ABSORPTION MEASUREMENTS OBTAINED WITH LONG RUN TIME RF PLASMA TESTS WITH PURE UF$_6$ INJECTION

RESIDUE REMOVED FROM FUSED SILICA TUBE
THIN WAFER KBr MATRIX USED WITH PERKIN ELMER MODEL 457

WAVELENGTH, $\lambda$ - MICRONS

a) TEST TIME - 5 MIN

b) TEST TIME - 10 MIN

c) TEST TIME - 20 MIN

d) TEST TIME - 41.5 MIN

ABSORBANCE - (LOG$_{10}T_0$)

WAVENUMBER - CM$^{-1}$
PHOTOGRAPHS OF FUSED SILICA TUBES AFTER LONG RUN TIME
RF PLASMA TESTS WITH PURE UF6 INJECTION

SEE TABLE III FOR ADDITIONAL DETAILS

a) TEST TIME—5 MIN
\[ \dot{m}_{UF6} = 2.2 \times 10^{-2} \text{ g/s} \]

b) TEST TIME—10 MIN
\[ \dot{m}_{UF6} = 2.2 \times 10^{-2} \text{ g/s} \]

17.2 MG RESIDUE

12.7 MG RESIDUE
PHOTOGRAPHS OF FUSED SILICA TUBES AFTER LONG RUN TIME RF PLASMA TESTS WITH PURE UF₆ INJECTION

a) TEST TIME – 20 MIN
\[ \dot{\text{UF}}_6 = 2.2 \times 10^{-2} \text{ G/S} \]

b) TEST TIME – 30 MIN
\[ \dot{\text{UF}}_6 = 2.2 \times 10^{-2} \text{ G/S} \]

Cc) TEST TIME – 41.5 MIN
\[ \dot{\text{UF}}_6 = 2.2 \times 10^{-2} \text{ G/S} \]

SEE TABLE IV FOR ADDITIONAL DETAILS ARGON VORTEX INJECTOR END AT TOP

30.4 MG RESIDUE (INCLUDING APPROXIMATELY 0.1 MG OF SILICONE GREASE INITIALLY DEPOSITED ON TUBES FOR PROVIDING O-RING SEAL)

35.7 MG RESIDUE

20.9 MG RESIDUE
PHOTOGRAPHS OF FUSED SILICA TUBE AND SILICONE O–RINGS AFTER RF PLASMA TEST WITH MAXIMUM INJECTION OF PURE UF₆

SEE TABLE for additional details

a) TEST TIME – 1.2 MIN \( \dot{m}_{\text{UF}_6} = 0.21 \text{ G/S} \)
134.7 MG RESIDUE
ARGON VORTEX INJECTOR END AT TOP

b) SILICONE O–RINGS AS USED WITH KEL–F OIL
NOTE EROSION ON PORTION THAT FACED PLASMA REGION
ELECTRON PHOTOMICROGRAPHS OF A SAMPLE RESIDUE FROM INSIDE SURFACE OF FUSED SILICA TUBE AFTER RF PLASMA TEST WITH MAXIMUM PURE UF₆ INJECTION
PHOTOGRAPHS OF X-RAY MAPS OF A SAMPLE RESIDUE FROM INSIDE SURFACE OF FUSED SILICA TUBE AFTER RF PLASMA TEST WITH MAXIMUM PURE UF₆ INJECTION

a) X-RAY SHOWING URANIUM (WHITE AREA)
b) X-RAY SHOWING FLUORINE
c) X-RAY SHOWING SILICON
d) X-RAY SHOWING OXYGEN
SURFACE CHARACTERISTICS OF RESIDUE DEPOSITED ON I.D. OF FUSED SILICA TUBE AFTER HOT FLOW TEST WITH UF$_6$ INJECTION

TEST CASE 11
REFER TO TABLE III

a) PHOTOGRAPH OF CROSS-SECTION SHOWING TUBE AND COATING

[Image of a photograph showing a cross-section of a tube with a residue coating, labeled "RESIDUE" and "FUSED SILICA" with a magnification of 500X and a scale of $10^{-4}$ cm = 1μ.]

b) PROFILOMETER TRACE (TALYSURF 4) OF RESIDUE ON TUBE
SEE FIG. 46 FOR EXPANDED SCALE TRACE

[Image of a profilometer trace with a vertical magnification of $20 \times 10^3$X and an axial traverse, labeled "RESIDUE" and "RANK." Accuracy is noted as "PRINTED IN U.S.A."
PROFILOMETER TRACE (TALYSURF 4) OF RESIDUE DEPOSITED ON I.D. OF FUSED SILICA TUBE
AFTER RF PLASMA TEST WITH UF₆ INJECTION

TEST CASE 11
REFER TO TABLE III

VERTICAL
MAG: 10 x 10³ x

AXIAL TRAVERSE
HORIZONTAL MAG: 20x

EDGE OF RESIDUE

2.3 x 10⁻⁴ CM = 2.3 µ

START OF TRACE

MID-TRACE

LOCAL ETCHING

MID-TRACE

END OF TRACE

FIG. 46
EXAMPLE OF SURFACE CHEMICAL ANALYSIS OF URANIUM COMPOUND RESIDUE USING SECONDARY ION MASS SPECTROMETER

238-U 254-UO 257-UF 270-UO₂ 273-UOF 276-UF₂ 286-UO₃

a) UO₂F₂ STANDARD REFERENCE

b) RESIDUE SAMPLE FROM FUSED SILICA TUBE AFTER RF TEST WITH PURE UF₆ INJECTION
WATER SOLUBLE RESIDUE TREATED WITH NITRIC ACID (HNO₃) TO DRIVE OFF HF AND HEATED TO FORM OXIDE
EXAMPLES OF IR SPECTROPHOTOMETRIC ABSORPTION MEASUREMENTS
THIN WAFER KBr MATRIX USED WITH PERKIN ELMER MODEL 457

WAVELENGTH, $\lambda$ - MICRONS

a) $\text{UO}_2\text{F}_2$ - STANDARD

b) SILICONE GREASE USED ON O-RINGS - STANDARD

c) KEL-F OIL USED ON O-RINGS

D) O-RING DECOMPOSITION PRODUCTS - RESIDUE ON FUSED SILICA TUBE NEAR O-RING AFTER HOT FLOW TEST

WAVENUMBER - CM$^{-1}$
EXAMPLES OF IR SPECTROPHOTOMETRIC ABSORPTION MEASUREMENTS
THIN WAFER KBr MATRIX USED WITH PERKIN ELMER MODEL 457

WAVELENGTH, \( \lambda \) – MICRONS

a) RESIDUE REMOVED FROM UF6 INJECTOR

b) RESIDUE REMOVED FROM END WALL

SILICONE GREASE

c) RESIDUE REMOVED FROM THRU-FLOW EXHAUST

d) RESIDUE REMOVED FROM AXIAL BYPASS EXHAUST

WAVENUMBER–CM\(^{-1}\)
ELECTRON PHOTOMICROGRAPHS OF UO₂-F₂ STANDARD REFERENCE MATERIAL

FIG. 50

MAG: 6000x

MAG: 2400x

MAG: 3000x
PHOTOGRAPHS OF X-RAY MAPS OF UO₂F₂ STANDARD REFERENCE MATERIAL

a) X-RAY SHOWING URANIUM (WHITE AREA)

b) X-RAY SHOWING FLUORINE

MAG: 2400x

MAG: 2400x

c) X-RAY SHOWING OXYGEN

MAG: 2400x
EXAMPLES OF URANIUM ABSORPTION SPECTRA IN WATER SOLUBLE RESIDUE

a) URANIUM SAMPLE FROM WATER SOLUBLE PORTION OF RESIDUE FROM AXIAL BYPASS EXHAUST DUCT

b) STANDARD ABSORPTION SPECTRUM OF URANIUM IN AQUEOUS SOLUTION
EXAMPLE OF X-RAY DIFFRACTION PATTERNS OBTAINED FROM POST TEST ANALYSIS OF RESIDUE FROM INSIDE SURFACE OF FUSED SILICA TUBE AND ENDWALL AFTER RF PLASMA TEST WITH PURE UF$_6$ INJECTION

NO PRIOR PREPARATION OF SAMPLES
ALL SAMPLES SUBJECTED TO CuK$_\alpha$ RADIATION IN A NORELCO DIFRACTOMETER

a) HIGH $m$$_{UF_6}$ CASE
HIGHLY CRYSTALLINE
\( \gamma \) UO$_3$

b) LOW $m$$_{UF_6}$ CASE
PARTIALLY CRYSTALLINE
\( \gamma \) UO$_3$

c) END WALL
HIGHLY AMORPHOUS
DEGENERATE PATTERN
BEGINNINGS OF \( \gamma \) UO$_3$

FIG. 53
EXAMPLE OF ELECTRON DIFFRACTION ANALYSIS OF DISPERSED POWDER FROM UO₂F₂ STANDARD REFERENCE

a) PHOTOGRAPHS OF UO₂F₂ STANDARD REFERENCE

MAG: 3200 X

MAG: 26,500 X

b) PHOTOGRAPH OF ELECTRON DIFFRACTION PATTERN OBTAINED FROM ABOVE SAMPLE
ELECTRON PHOTOMICROGRAPHS OF A SAMPLE RESIDUE FROM ENDWALL AFTER RF PLASMA TEST WITH PURE UF₆ INJECTION

SAMPLE NEAR CENTRAL PORTION

a)

MAG: 3000x

b)

MAG: 6000x

c)*

MAG: 300x

*BACKSCATTERED ELECTRON MICROGRAPH SHOWING TYPICAL TOPOGRAPHICAL VARIATIONS
PHOTOGRAPHS OF X-RAY MAPS OF A SAMPLE RESIDUE FROM END WALL AFTER RF PLASMA TEST WITH PURE UF₆ INJECTION

a) X-RAY SHOWING URANIUM (WHITE AREA)
b) X-RAY SHOWING FLUORINE
c) X-RAY SHOWING COPPER
d) X-RAY SHOWING OXYGEN
EXAMPLE OF ELECTRON DIFFRACTION ANALYSIS OF DISPERSED RESIDUE REMOVED FROM END WALL AFTER RF PLASMA TEST WITH PURE UF$_6$ INJECTION

a) PHOTOGRAPHS OF RESIDUE

![AMORPHOUS MATERIAL](image1.jpg)

MAG: 3200X

AMORPHOUS

MAG: 26,500X

b) PHOTOGRAPHS OF ELECTRON DIFFRACTION PATTERNS OBTAINED FROM ABOVE SAMPLE

![AMORPHOUS MATERIAL](image2.jpg)

![UF$_4$ + UO$_2$*](image3.jpg)

*U$_4$O$_9$ ALSO POSSIBLE
ELECTRON PHOTOMICROGRAPHS OF A SAMPLE RESIDUE FROM UF₆ INJECTOR AFTER RE-PLASMA TEST WITH PURE UF₆ INJECTION.

SAMPLE NEAR TIP OF UF₆ INJECTOR.

*BACK-SCATTERED ELECTRON MICROGRAPH SHOWING TYPICAL TOPOGRAPHICAL VARIATIONS.*
PHOTOGRAPHS OF X-RAY MAPS OF A SAMPLE RESIDUE FROM UF₆ INJECTOR AFTER RF PLASMA TEST WITH PURE UF₆ INJECTION

a) X-RAY SHOWING URANIUM (WHITE AREA)

b) X-RAY SHOWING FLUORINE

MAG: 300x

MAG: 300x

c) X-RAY SHOWING COPPER

d) X-RAY SHOWING OXYGEN

MAG: 300x

MAG: 300x
EXAMPLE OF ELECTRON DIFFRACTION ANALYSIS OF DISPERSED RESIDUE REMOVED FROM UF₆ INJECTOR AFTER RF PLASMA TEST WITH PURE UF₆ INJECTION

a) PHOTOGRAPHS OF RESIDUE

MAG: 3200X

b) PHOTOGRAPHS OF ELECTRON DIFFRACTION PATTERNS OBTAINED FROM ABOVE SAMPLES

AMORPHOUS MATERIAL

UF₄ + UO₂*

UO₂* + αUO₃**

UNKNOWN SINGLE CRYSTALS

*U₄O₉ ALSO POSSIBLE
**U₃O₈ ALSO POSSIBLE
ELECTRON PHOTOMICROGRAPHS OF A SAMPLE RESIDUE FROM ON-AXIS THRU-FLOW EXHAUST DUCT AFTER RF PLASMA TEST WITH PURE UF₆ INJECTION

FIG. 61

BACKSCATTERED ELECTRON MICROGRAPH SHOWING TYPICAL TOPOGRAPHICAL VARIATIONS

MAG: 6000x

MAG: 3000x

MAG: 300x

b)

c)
PHOTOGRAPHS OF X-RAY MAPS OF A SAMPLE RESIDUE FROM ON-AXIS THRU-FLOW EXHAUST DUCT AFTER RF PLASMA TEST WITH PURE UF₆ INJECTION

a) X-RAY SHOWING URANIUM (WHITE AREA)

b) X-RAY SHOWING FLUORINE

MAG: 300X

MAG: 300X

c) X-RAY SHOWING COPPER

d) X-RAY SHOWING OXYGEN

MAG: 300X

MAG: 300X
ELECTRON PHOTOMICROGRAPHS OF A SAMPLE RESIDUE FROM AXIAL BY-PASS EXHAUST DUCT AFTER RF PLASMA TEST WITH PURE UF₆ INJECTION

POSITION NEAR TO END WALL ASSEMBLY

* BACKSPATTERED ELECTRON MICROGRAPH SHOWING TYPICAL TOPOGRAPHICAL VARIATIONS
PHOTOGRAVHS OF X-RAY MAPS OF A SAMPLE RESIDUE FROM AXIAL BY-PASS EXHAUST DUCT AFTER RF PLASMA TEST WITH PURE UF₆ INJECTION

FIG. 64

a) X-RAY SHOWING FLUORINE

b) X-RAY SHOWING OXYGEN

c) X-RAY SHOWING COPPER

d) X-RAY SHOWING URANIUM (WHITE AREA)

POSITION NEAR END WALL ASSEMBLY
ELECTRON PHOTOMICROGRAPHS OF A SAMPLE RESIDUE FROM AXIAL BY-PASS EXHAUST DUCT AFTER RE PLASMA TEST WITH PURE UF6 INJECTION POSITION FAR FROM ENDWALL ASSEMBLY

* BACKSCATTERED ELECTRON MICROGRAPH SHOWING TYPICAL TOPOGRAPHICAL VARIATIONS
PHOTOGRAPHS OF X-RAY MAPS OF A SAMPLE RESIDUE FROM AXIAL BY-PASS EXHAUST DUCT AFTER RF PLASMA TEST WITH PURE UF₆ INJECTION
EXAMPLE OF X-RAY DIFFRACTION PATTERNS OBTAINED FROM POST TEST ANALYSIS OF RESIDUE FROM EXHAUST DUCTS AFTER RF PLASMA TEST WITH PURE UF₆ INJECTION AND OF STANDARD REFERENCE SAMPLE

NO PRIOR PREPARATION OF SAMPLES
ALL SAMPLES SUBJECTED TO CuKα RADIATION IN A NORELCO DIFFRACTOMETER

a) ON-AXIS THRU-FLOW EXHAUST DUCT

b) AXIAL BYPASS EXHAUST DUCT

c) UO₂F₂ STANDARD REFERENCE SAMPLE

AMORPHOUS PATTERN
U₃O₈

αUO₂F₂·5H₂O
VARIATION OF X-RAY TRANSMISSION WITH URANIUM ATOM NUMBER DENSITY

\[ \frac{I}{I_0} = e^{-\mu NL} \]

PATH LENGTH,
\[ L \text{ - CM} \]
- 10
- 15

FRACTION OF X-RAYS TRANSMITTED, \( \frac{I}{I_0} \)

TARGET MATERIAL
- TITANIUM TARGET
  - E = 4.8 KEV
  - \( \mu \text{ - CM}^2/\text{ATOM} \)
    - \( 4.3 \times 10^{-19} \)
    - \( 1.2 \times 10^{-19} \)
    - \( 3.5 \times 10^{-20} \)

- COPPER TARGET
  - E = 8 KEV

- MOLYBDENUM TARGET
  - E = 17.8 KEV

URANIUM NUMBER DENSITY, \( N \text{ - ATOMS/CM}^3 \)

\( 10^{15} \), \( 2 \), \( 5 \), \( 10^{16} \), \( 2 \), \( 5 \), \( 10^{17} \), \( 2 \), \( 5 \), \( 10^{18} \), \( 2 \), \( 5 \), \( 10^{19} \), \( 2 \), \( 5 \), \( 10^{20} \)
SYSTEM FOR PRELIMINARY X-RAY ABSORPTION MEASUREMENT TESTS

SCINTILLATION DETECTOR

TEST CHAMBER CONTAINING UF₆

0.125 MM-THICK MYLAR WINDOW

8 KEV X-RAYS (λ = 0.154 NM)

2θ = 42.9°

MgO CRYSTAL MONOCHROMATOR

COPPER TARGET X-RAY DIFFRACTION TUBE

COUNTER-TIMER

LINEAR AMPLIFIER AND SINGLE CHANNEL ANALYZER

COUNT/S

SIGNAL CABLE
MEASURED VARIATION OF TRANSMISSION OF 8 KEV X-RAYS WITH UF₆ PRESSURE

PATH LENGTH = 15 CM
TEMPERATURE = 300 K
SEE FIG. 69 FOR TEST CONFIGURATION DETAILS

CURVE CALCULATED USING BEER'S LAW FOR UF₆ AND λ = 8 KEV X-RAYS
TEST CHAMBERS FOR UF$_6$ AND ARGON X-RAY ABSORPTION MEASUREMENTS

a) CALIBRATION TEST CHAMBER

b) RF-HEAT TED PLASMA TEST CHAMBER
PHOTOGRAPH OF SYSTEM FOR UF₆ X-RAY ABSORPTION MEASUREMENTS IN RF-HEATED PLASMA TESTS
MEASURED VARIATION OF TRANSMISSION OF 8 KEV X-RAYS WITH ARGON PRESSURE

TEMPERATURE = 300 K

<table>
<thead>
<tr>
<th>SYMBOL</th>
<th>CONFIGURATION</th>
<th>CRYSTAL TRAVERSED?</th>
<th>PATH LENGTH, L - CM</th>
</tr>
</thead>
<tbody>
<tr>
<td>O</td>
<td>CALIBRATION</td>
<td>YES</td>
<td>22.4</td>
</tr>
<tr>
<td>□</td>
<td>CALIBRATION</td>
<td>NO</td>
<td>22.4</td>
</tr>
<tr>
<td>△</td>
<td>RF TEST</td>
<td>NO</td>
<td>23.0</td>
</tr>
</tbody>
</table>

CURVE CALCULATED USING BEER'S LAW FOR ARGON AND λ = 8 KEV X-RAYS.
MEASURED VARIATION OF TRANSMISSION OF 8 KEV X-RAYS WITH UF₆ PRESSURE
CALIBRATION TEST CONFIGURATION  \( \text{PATH LENGTH} = 22.4 \text{ CM} \)
TEMPERATURE = 300 K

<table>
<thead>
<tr>
<th>SYMBOL</th>
<th>CRYSTAL TRAVERSED</th>
</tr>
</thead>
<tbody>
<tr>
<td>○</td>
<td>YES</td>
</tr>
<tr>
<td>□</td>
<td>NO</td>
</tr>
</tbody>
</table>

CURVE CALCULATED USING BEER'S LAW FOR URANIUM AND \( \lambda = 8 \text{ KEV X-RAYS} \)
MEASURED VARIATION OF TRANSMISSION OF 8 KEV X-RAYS WITH UF₆ PRESSURE FOR SEVERAL ARGON PRESSURES

CALIBRATION TEST CONFIGURATION

PATH LENGTH = 22.4 CM
TEMPERATURE = 300 K

LOCUS FOR TOTAL FRACTION OF X-RAYS TRANSMITTED EQUAL TO 10⁻²

CURVE CALCULATED USING BEERS LAW FOR URANIUM AND λ = 8 KEV X-RAYS

<table>
<thead>
<tr>
<th>SYMBOL</th>
<th>ARGON PRESSURE, MMHg</th>
</tr>
</thead>
<tbody>
<tr>
<td>○</td>
<td>0</td>
</tr>
<tr>
<td>□</td>
<td>50</td>
</tr>
<tr>
<td>△</td>
<td>150</td>
</tr>
<tr>
<td>◆</td>
<td>300</td>
</tr>
<tr>
<td>○</td>
<td>500</td>
</tr>
<tr>
<td>▽</td>
<td>700</td>
</tr>
</tbody>
</table>
MEASURED VARIATION OF TRANSMISSION OF 8 KEV X-RAYS WITH ARGON PRESSURE
FROM RF-HEATED PLASMA TESTS

RF TEST CONFIGURATION

<table>
<thead>
<tr>
<th>SYMBOL</th>
<th>PLASMA, PRESENT?</th>
</tr>
</thead>
<tbody>
<tr>
<td>•</td>
<td>NO</td>
</tr>
<tr>
<td>O</td>
<td>YES</td>
</tr>
</tbody>
</table>

NOTE: FLAGGED AND UNFLAGGED SYMBOLS DENOTE AXIAL BYPASS EXHAUST USED AND NOT USED, RESPECTIVELY

PATH LENGTH = 13.5CM AT 375K
PLUS 9.5CM AT 150,000K

N_A = 9.95 x 10^{18} \frac{P}{T} \text{ ATOM} \text{ CM}^{-3}

USING BEERS LAW
FOR ARGON, 8 KEV
X-RAYS AND PATH
LENGTH = 23.0CM AT
T DEG K

RF POWER = 50KW 44 44 34 34 34
15 10,000K 5000K 2000K

PATH LENGTH = 13.5CM
AT 300 K PLUS
95 CM AT T=

ARGON PRESSURE, P = MMHG
VARIATION OF FRACTION OF X-RAYS TRANSMITTED FOR ARGON AND UF₆-ARGON MIXTURES WITH RF POWER

<table>
<thead>
<tr>
<th>SYMBOL</th>
<th>PLASMA GAS</th>
</tr>
</thead>
<tbody>
<tr>
<td>○</td>
<td>ARGON</td>
</tr>
<tr>
<td>□</td>
<td>UF₆ + ARGON</td>
</tr>
</tbody>
</table>

SEE TEXT FOR EXPLANATION OF FLAGGED SYMBOLS
VARIATION OF MEASURED URANIUM DENSITY WITH UF₆ FLOW RATE

<table>
<thead>
<tr>
<th>SYMBOL</th>
<th>PATH LENGTH, CM</th>
</tr>
</thead>
<tbody>
<tr>
<td>O</td>
<td>23.0</td>
</tr>
<tr>
<td>□</td>
<td>9.5</td>
</tr>
</tbody>
</table>

RF-POWER = 60 KW
PATH LENGTH = 9.5 CM
23.0 CM
52.5

URANIUM NUMBER DENSITY, N - ATOM/CM³

UF₆ FLOW RATE, m₄UF₆ - G/S
PHOTOGRAPHS SHOWING THERMAL STRESS PRESENT IN FUSED SILICA TUBES AFTER SELECTED RF PLASMA TESTS WITH PURE UF₆ INJECTION

POLARIZED LIGHT USED

a) REFERENCE STANDARD

b) RELATIVELY HIGH THERMAL STRESS

c) RELATIVELY LOW THERMAL STRESS

d) NEGLIGIBLE THERMAL STRESS
PHOTOGRAPHS OF SMALL-SCALE FUSED SILICA VESSELS (350 CC) USED WITH GRAM QUANTITIES OF UF6 IN LABORATORY TESTS

SEE TABLE VI FOR CORRESPONDING TEST CONDITIONS

a) TEST I
b) TEST II
d) TEST IV
c) TEST III
EXAMPLES OF IR SPECTROPHOTOMETRIC ABSORPTION MEASUREMENT STANDARDS
THIN WAFER KBr MATRIX USED WITH PERKIN ELMER MODEL 457

A) UO₂ STANDARD

B) UO₄·H₂O - STANDARD

C) UF₄ - STANDARD

D) H₂O - STANDARD
EXAMPLES OF IR SPECTROPHOTOMETRIC ABSORPTION MEASUREMENTS
THIN WAFER KBr MATRIX USED WITH PERKIN ELMER MODEL 457

WAVELENGTH, \( \lambda \) - MICRONS

a) \( \text{UO}_3 \) AMORPHOUS

b) \( \alpha \text{UO}_3 \) - HEXAGONAL

c) \( \gamma \text{UO}_3 \) - MONOCLINIC

d) \( \epsilon \text{UO}_3 \) - MONOCLINIC

ABSORBANCE - (LOG IO/I0)

WAVENUMBER - CM\(^{-1}\)
EXAMPLES OF IR SPECTROPHOTOMETRIC ABSORPTION MEASUREMENTS

THIN WAFFER KBr MATRIX USED WITH PERKIN ELMER MODEL 457

FIG. 85

WAVELENGTH, \( \lambda \) — MICRONS

a) KBr BLANK

b) CuF\(_2\)

\( \text{H}_2\text{O} \)

\( \text{CuF}_2 \)

c) U\(_3\)O\(_8\)

\( \text{H}_2\text{O} \)

d) SiO\(_2\)H\(_2\)O

PERCENT TRANSMITTANCE

WAVENUMBER — CM\(^{-1}\)
EXAMPLES OF IR SPECTROPHOTOMETRIC ABSORPTION MEASUREMENT STANDARDS

THIN WAFER KBr MATRIX USED PERKIN AND ELMER MODEL 457

WAVELENGTH $\lambda$ - MICRONS

a) $\text{UOF}_2$ - STANDARD

b) $\text{H}_2\text{UO}_4$ - STANDARD

WAVENUMBER - CM$^{-1}$
RATE OF CORROSION FOR DIFFERENT MATERIALS BETWEEN 650K AND 1300K EXPOSED TO UF₆ AT 0.32 ATMOSPHERES

(REF. 20)
PHOTOGRAPHS SHOWING CORROSIVE EFFECTS OF HOT, PRESSURIZED UF₆ ON 316 STAINLESS STEEL BURST DISCS

THICKNESS: 0.005 CM
PRESSURE SIDE VIEWED IN ALL CASES

a) AS RECEIVED STANDARD
MAG: 10x

b) AS RECEIVED STANDARD
MAG: 1000x

c) FAILED PORTION OF BURST DISC
MAG: 10x

d) DETAILS OF INTERGRANULAR FRACTURE IN ADJACENT REGION
MAG: 1000x
SKETCH OF TEST CHAMBERS EMPLOYED IN 80 KW EXPLORATORY RF PLASMA TESTS WITH PURE UF₆ INJECTION

a) END WALL INJECTION WITH ON-AXIS THRU-FLOW EXHAUST AND PROVISION FOR AXIAL BYPASS

b) END WALL INJECTION WITH BLUFF BODY STABILIZATION AND ON-AXIS THRU-FLOW EXHAUST

c) END WALL INJECTION WITH OFF-AXIAL ANNULAR EXHAUST

d) PERIPHERAL WALL INJECTION
SKETCH OF CROSS-SECTION OF TEST CHAMBER EMPLOYED IN 80 KW AND (TRANSITIONAL) 1.2 MW RF INDUCTION HEATER EXPLORATORY TESTS

FIG. 92

TEST CHAMBER L/D RATIO = 1.75
OPERATING FREQUENCY = 13,56 MHz
INDUCTANCE OF RF WORK COIL = 0.7x10^-6 HENRY
SCHEMATIC OF DIAGNOSTIC SYSTEMS USED IN EXPLORATORY RF PLASMA TESTS

[Diagram of diagnostic systems used in exploratory RF plasma tests.]
TYPICAL OPERATING CONDITIONS AND RESULTS OF CORRESPONDING RADIATION MEASUREMENTS IN EXPLORATORY RF PLASMA TESTS WITH PURE UF$_6$ INJECTION

SEE FIG. 91(a) FOR SKETCH OF TEST CHAMBER FLOW CONFIGURATION
TESTS CONDUCTED IN 80 KW RF INDUCTION HEATER

<table>
<thead>
<tr>
<th>CONDITION</th>
<th>ARGON ONLY</th>
<th>ARGON + PURE UF$_6$ INJECTION</th>
</tr>
</thead>
<tbody>
<tr>
<td>ARGN INJECTION FLOW RATE</td>
<td>0.16 G/S</td>
<td>0.16 G/S</td>
</tr>
<tr>
<td>ARGN INJECTION VELOCITY</td>
<td>57 M/S</td>
<td>57 M/S</td>
</tr>
<tr>
<td>UF$_6$ INJECTION FLOW RATE</td>
<td></td>
<td>0.04 G/S</td>
</tr>
<tr>
<td>UF$_6$ INJECTION VELOCITY</td>
<td></td>
<td>5 M/S</td>
</tr>
<tr>
<td>MASS RATIO, UF$_6$/Ar</td>
<td></td>
<td>0.25</td>
</tr>
<tr>
<td>POWER IN DISCHARGE</td>
<td>4.0 KW</td>
<td>7.5 KW</td>
</tr>
<tr>
<td>POWER RADIATED (220–2600 NM)</td>
<td>0.41 KW</td>
<td>1.7 KW</td>
</tr>
<tr>
<td>FRACTION OF TOTAL DISCHARGE</td>
<td>0.10</td>
<td>0.23</td>
</tr>
<tr>
<td>POWER RADIATED</td>
<td></td>
<td></td>
</tr>
<tr>
<td>TEST TIME</td>
<td>5 MIN</td>
<td>4 MIN</td>
</tr>
<tr>
<td>PERCENT AXIAL BY–PASS FLOW</td>
<td>95%</td>
<td>95%</td>
</tr>
<tr>
<td>CHAMBER PRESSURE</td>
<td>1 ATM</td>
<td>1 ATM</td>
</tr>
<tr>
<td>OPERATING FREQUENCY</td>
<td>13.56 MHz</td>
<td>13.56 MHz</td>
</tr>
</tbody>
</table>

NUMBERS IN PARENTHESES EXPRESSED AS PERCENT OF $Q_R$

WAVELENGTH BAND, $\Delta \lambda$ – NM
PHOTOGRAPHS OF EXPLORATORY RF PLASMA TEST CONFIGURATION

b) ARGON + UF₆

a) ARGON ONLY
RESULTS OF SPECTRAL EMISSION MEASUREMENTS FROM EXPLORATORY TESTS WITH PURE UF₆ INJECTION

MEASUREMENTS TAKEN ON – AXIS
AT AXIAL MIDPLANE SEE FIG. 91(a) FOR
TEST CONFIGURATION
SEE FIG. 94 FOR TEST CONDITIONS

ARGON + UF₆

ARGON ONLY
ZERO INTENSITY REF.

WAVELENGTH, \( \lambda \cdot \text{NM} \)

INTENSITY, \( I_o \) - ARBITRARY UNITS
EXAMPLE OF ABSORPTION MEASUREMENTS OBTAINED IN EXPLORATORY RF PLASMA TESTS

SEE FIG. 93 FOR TEST CONFIGURATION AND DIAGNOSTIC EQUIPMENT

\[ P_C = 1 \text{ ATM} \quad \text{Q}_T = 5 \text{ KW} \quad T = 8000 \text{ K} \quad L = 2 \text{ CM} \]

ZERO REF. – NO TRANSMISSION

RELATIVE ABSORPTION

ARGON ONLY

ARGON + UF\textsubscript{6} (591.5 NM)

15 S

8 GHz

(10^{-2} \text{ NM})

\frac{I}{I_0} = 0.75

\frac{I}{I_0} = 0.45

2.5 GHz
PHOTOGRAPH OF FUSED SILICA TUBES USED IN 80 KW RF PLASMA EXPLORATORY TESTS WITH PURE UF6 INJECTION

FOR CONFIGURATION SEE FIG. 91(c)

FOR CONFIGURATION SEE FIG. 91(a)
PHOTOGRAPH OF FUSED SILICA TUBES USED IN 1.2 MW RF PLASMA EXPLORATORY TESTS WITH PURE UF₆ INJECTION

SEE FIG. 8 FOR DETAILS OF TEST CONFIGURATION
PHOTOMICROGRAPHS OF RESIDUE WALL COATING FROM 1.2 MW RF PLASMA TESTS WITH PURE UF₆ INJECTION
EXAMPLE OF X-RAY DIFFRACTION PATTERNS OBTAINED FROM POST TEST ANALYSIS OF RESIDUE WALL COATING

ALL SAMPLES SUBJECT TO COPPER kα RADIATION IN A DEBYE CAMERA

BLACK CHIP – α UO₃, U₃O₈

BLACK POWDER – α UO₃, U₃O₈

RUST POWDER – UO₂, U₄O₉

GREEN POWDER – UF₄
PHOTOGRAPH OF X-RAY DISTRIBUTION FOR U, F, AND O ON SAMPLE OF RESIDUE WALL COATING FROM POST TEST ANALYSIS

MAGNIFICATION: 350X

a) URANIUM

b) FLUORINE

c) OXYGEN
EXAMPLE OF IR SPECTROPHOTOMETRY ABSORPTION MEASUREMENTS OBTAINED FROM POST TEST ANALYSIS OF RESIDUE WALL COATING

INSTRUMENT USED: PERKIN ELMER MODEL 467 USED IN CONJUNCTION WITH 3X-BEAM CONDENSER AND SPECULAR REFLECTANCE ACCESSORY
PREPARATION: THIN WAFFER KBr MATRIX
EXAMPLE OF ABSORPTION MEASUREMENTS OBTAINED IN 1.2 MW RF PLASMA TEST WITH PURE UF$_6$ INJECTION

SEE FIG. 8 FOR SKETCH OF TEST CONFIGURATION USED IN TESTS
(LASER BEAM TRAVERSED ON-AXIS AT AXIAL MID-PLANE)
SEE FIG. 93 FOR SCHEMATIC OF DIAGNOSTIC SYSTEM
(DYE LASER HEAD NOT USED IN THESE TESTS)

ARGON ION LASER
514.5 NM LINE
300 MW OUTPUT POWER

RANGE OF TEST CONDITIONS
35 \( \leq \dot{Q}_T \leq 55 \) KW
5.4758 \( \leq f \leq 5.4778 \) MHz
2 \( \leq \rho_C \leq 2.5 \) ATM
1.9 \( \leq \dot{m}_{AR} \leq 2.7 \) G/S
0.5 \( \leq t \leq 2 \) MIN

TRANSMISSION, \( I/I_0 \), - DIMENSIONLESS

UF$_6$ MASS FLOW RATE, \( \dot{m}_{UF_6} \) - G/S
PHOTOGRAPH OF RF ARGON PLASMA IN 1.2 MW RF INDUCTION HEATER TEST CHAMBER WITH PURE UF$_6$ INJECTION

$P_c = 2.4$ ATM  $Q_T = 52$ KW  $f = 5.4778$ MHz  $d = 2.9$ CM

$m_{AR} = 2.2$ G/S  $m_{UF_6} = 0.09$ G/S

-10 CM-